NANOMECHANICAL PROPERTIES, THERMAL STABILITY, AND CORROSION RESISTANCE OF ALUMINIUM AND NITROGEN DOPED DIAMOND-LIKE CARBON FILM

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ประภาพร ศิลาวงศ์ : สมบัติเชิงกลระดับนาโน เสถียรภาพทางความร้อน และความต้านทานการกัดกร่อนของชั้นเคลือบคล้ายเพชรด้วยการเจืออะลูมิเนียมและไนโตรเจน (NANOMECHANICAL PROPERTIES, THERMAL STABILITY, AND CORROSION RESISTANCE OF ALUMINIUM AND NITROGEN DOPED DIAMOND-LIKE CARBON FILM) อาจารย์ที่ปรึกษา : รองศาสตราจารย์ ดร.พรวสา วงศ์ปัญญา, 162 หน้า.

คำสำคัญ: FCVA/AL-N CO-DOPED DLC/ NEXAFS/XPS /สมบัติเชิงกลระดับนาโน/ความแข็งแรงในการยึดเกาะ/เสถียรภาพทางความร้อน/ความต้านทานการกัดกร่อน

ในทางวิศวกรรมมักใช้เหล็กกล้าอัลลอยด์ต่ำ AISI4140 เนื่องจากมีคุณสมบัติทางกลที่โดดเด่น รวมทั้งมีความต้านทานแรงดึงสูง ทนต่อความล้า ความแกร่ง และทนต่อแรงกระแทก แต่มีความต้านทานการสึกหรอต่ำ จึงจำเป็นต้องมีการปรับปรุงพื้นผิวเพื่อให้สอดคล้องกับการใช้งานสำหรับในสภาพแวดล้อมที่มีการกัดกร่อนและการทำงานที่อุณหภูมิสูง ฟิล์มคาร์บอนคล้ายเพชร (Diamond-like carbond, DLC) ช่วยเพิ่มความแข็ง โมดูลัสความยืดหยุ่น การยึดเกาะ ความทนทานต่อการเสียดสี ทนความร้อน และทนต่อการกัดกร่อน สำหรับการศึกษานี้ฟิล์ม DLC ได้ถูกผลิตขึ้นโดยเทคนิคการเคลือบฟิลเตอร์คาร์โธดิกอาร์ก (Filtered cathodic vacuum arc, FCVA) เทคนิคนี้สามารถสร้างชั้นฟิล์มคาร์บอนอสัณฐานเตตระฮีดรัลที่ปราศจากไฮโดรเจน (hydrogen-free tetrahedral amorphous carbon, ta-C) ที่มีอัตราส่วนพันธะคาร์บอน sp^3/sp^2 สูง ในทางกลับกันฟิล์ม ta-C มีความเค้นภายในอย่างมาก ซึ่งทำให้ชั้นฟิล์มยึดเกาะกับพื้นผิวโลหะได้ไม่ดี ด้วยเหตุนี้จึงเพิ่มความแข็งแรงในการยึดเกาะขึ้นโดยการเจือธาตุผสมลงในฟิล์ม DLC เพื่อลดความเค้นภายในชั้นฟิล์ม ในงานวิจัยนี้ฟิล์ม DLC ที่พัฒนาขึ้นนั้น ถูกเจือด้วยอะลูมิเนียม (Al) และไนโตรเจน (N) และสังเคราะห์ฟิล์มโดยใช้เทคนิค FCVA เพื่อเคลือบชั้นฟิล์ม ta-C, ta-C:N, ta-C:Al และฟิล์ม ta-C:Al:N ตามลำดับ ลงบนผิวเหล็ก AISI 4140 โครงสร้างและองค์ประกอบทางเคมีของฟิล์ม DLC ที่ถูกสังเคราะห์ขึ้นได้รับการตรวจสอบโดยใช้รามานสเปกโตรสโกปี (Raman spectroscopy), เอ็กซ์เรย์โฟโต้อิเล็กตรอนสเปกโตสโกปี (X-ray photoelectron spectroscopy, XPS) และการดูดกลืนรังสีเอกซ์โครงสร้างใกล้ขอบ (Near Edge X-Ray Absorption Fine Structures, NEXAFS) จากนั้น จึงตรวจวัดคุณสมบัติทางกลและแรงยึดเกาะของฟิล์ม พฤติกรรมการเกิดออกซิเดชันของฟิล์ม DLC ถูกวิเคราะห์โดยใช้เทคนิค NEXAFS ที่ให้ความร้อนในแหล่งกำเนิด ตามด้วยพฤติกรรมการกัดกร่อนของฟิล์มทั้งหมด ชิ้นงานถูกประเมินโดยใช้โพเทนชิโอสแตตในสารละลายของโซเดียมคลอไรด์ 3.5 โดยน้ำหนัก สุดท้ายตรวจสอบบริเวณที่กัดกร่อนและผลิตภัณฑ์การกัดกร่อนจากการทดสอบการกัดกร่อนโดยใช้กล้องจุลทรรศน์อิเล็กตรอนแบบส่องกราดเอ็กซ์เรย์ (X-ray photoemission electron microscopy, XPEEM) และ NEXAFS ตามลำดับ และศึกษาผลิตภัณฑ์การกัดกร่อนโดยใช้เทคนิค XPS ผลการวิจัยพบว่าชั้นฟิล์ม DLC ที่เจือด้วย Al และ N ที่มีโครงสร้าง sp^3

C-N และ Al_2O_3 มีคุณสมบัติทางกลที่คล้ายคลึงกับของ DLC ที่ไม่เจือธาตุผสม (ความแข็ง = 49.04 ± 1.33 GPa, โมดูลัสยืดหยุ่น (E) = 251.09 ± 6.57GPa, ค่าเปอร์เซ็นต์การคืนรูป (%ER) = 58.43 ± 1.73) และยังมีการยึดเกาะของฟิล์มที่ดีขึ้น (ความต้านทานรอยขีดข่วน, CPRs = 12187.06 mN^2), ความคงตัวทางความร้อน (ทนต่ออุณหภูมิได้ถึง 600 °C) และความต้านทานการกัดกร่อนโดยการเพิ่มค่า E_{corr} จาก -443.31 ถึง -382.93 mV (เมื่อเปรียบเทียบกับ DLC บริสุทธิ์) ด้วยเหตุนี้ชิ้นงานทดสอบ ta-C:Al:N จึงเหมาะสำหรับใช้งานที่ต้องการความต้านทานการกัดกร่อนและทนความร้อน

มหาวิทยาลัยเทคโนโลยีสุรนารี

สาขาวิชาวิศวกรรมวัสดุ

ปีการศึกษา 2564

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PRAPHAPHON SILAWONG : NANOMECHANICAL PROPERTIES, THERMAL STABILITY, AND CORROSION RESISTANCE OF ALUMINIUM AND NITROGEN DOPED DIAMOND-LIKE CARBON FILM. THESIS ADVISOR : ASSOC. PROF. PORNWASA WONGPANYA, Dr.–Ing., 162 PP.

Keyword: FCVA/Al–N Co–Doped DLC/NEXAFS/XPS/Nanomechanical/Adhesion Strength/ Thermal Stability/Corrosion Resistance

In engineering, AISI4140 low alloy steel is commonly utilized. It has outstanding mechanical qualities, including high tensile strength, fatigue resistance, toughness, and impact resistance, but low wear resistance. Surface enhancement is required for corrosive environments and operations at high temperatures to satisfy its application. Diamond–like carbon (DLC) film enhances hardness, modulus of elasticity, adhesion, abrasion resistance, heat resistance, and corrosion resistance. As a result, DLC films were produced by filtered cathodic vacuum arc (FCVA) for this investigation. This technique is capable of fabricating a hydrogen-free tetrahedral amorphous carbon (ta–C) film layer with a high sp^3/sp^2 carbon bond ratio. On the other hand, the ta–C film has a significant internal stress, which contributes to the coating's poor adherence to the metal surface. As a consequence, the adhesion strength is enhanced by the incorporation of doping elements into the DLC film to relieve internal stress. In this work, the developed DLC film was doped with aluminum (Al) and nitrogen (N) and synthesized by using the FCVA technique to coat AISI 4140 steel and produce ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films, respectively. The structure and chemical composition of the produced DLC films were investigated using Raman spectroscopy, X–ray photoelectron spectroscopy (XPS), and near edge X–ray absorption fine structures (NEXAFS). Following that, the mechanical characteristics and adhesive strengths of the films were determined. The oxidation behavior of the DLC films was determined using in situ heating NEXAFS, followed by the corrosion behavior of the whole film. They were evaluated using a potentiostat in a solution of 3.5 wt% sodium chloride (NaCl). Finally, the corroded regions and corrosion products from the corrosion test were evaluated using X–ray photoemission electron microscopy (XPEEM) and

NEXAFS, respectively, and the corrosion products were studied using XPS. The results indicated that Al and N–doped DLC film (ta–C:Al:N) with sp^3 C–N and Al_2O_3 structures had similar mechanical properties to that of non–doped DLC (ta–C) (hardness = 49.04 ± 1.33 GPa, elastic modulus (E) = 251.09 ± 6.57GPa, elastic recovery (%ER) = 58.43 ± 1.73), and also had improved film adhesion (scratch propagation resistance, CPRs = 12187.06 mN^2), thermal stability (temperature resistance up to 600°C), and corrosion resistance by raising the E_{corr} value from –443.31 to –382.93 mV (in comparison to pure DLC). As a result, ta–C:Al:N specimens are suitable for use in applications requiring corrosion resistance and thermal resistance.

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School of Materials Engineering

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LIST OF ABBREVIATIONS

a-C	=	Amorphous carbon
a-C:H	=	Hydrogenated amorphous carbon
BE	=	Binding energy
CR	=	Corrosion rate
E	=	Elastic modulus
E_{corr}	=	Corrosion potential
%ER	=	Elastic recovery
FCVA	=	Filtered cathodic vacuum arc
FOV	=	Field of view
FWHM	=	Full width at half-maximum
H/E	=	Plastic index parameter
HOPG	=	Highly oriented pyrolytic graphite
$h\nu$	=	Photon energy
i_{corr}	=	Corrosion current density
I_D/I_G ratio	=	The intensity ratio of the D and G bands
KE	=	Kinetic energy
kV	=	Kilo voltage
L_a	=	Cluster size of the sp^2 sites
L_c	=	Critical load
NEXAFS	=	Near edge X-ray absorption fine structure
OCP	=	Open circuit potential
P	=	Porosity
P_i	=	Protection efficiency
R_p	=	Polarization resistance
ta-C	=	Tetrahedral amorphous carbon
ta-C:H	=	Tetrahedral hydrogenated amorphous carbon
UHV	=	Ultra high vacuum

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LIST OF ABBREVIATIONS (Continued)

V_{bias}	=	Negative direct current bias voltage
X-PEEM	=	X-ray photoemission electron microscopy
XPS	=	X-ray photoelectron spectroscopy
XRR	=	X-ray reflectivity
θ_c	=	Critical angle
ρ	=	Density
σ	=	Compressive internal stress or Residual internal stress

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CHAPTER 1
INTRODUCTION

1.1 Rationale of the study

AISI 4140 steel is a low–alloy steel widely used in engineering applications. The main feature of AISI 4140 is that it contains low compositions of chromium (Cr) and molybdenum (Mo), which results in high hardness and fabrication ability. It has excellent mechanical properties (i.e., tensile strength and abrasion wear resistance) that can be enhanced by heat treatment processes such as quenching and tempering, and surface treatment (i.e., carburizing) for suitable application. AISI 4140 is used in automotive parts (i.e., gear, transmission, crankshaft, piston, and piston ring) operating in environments of humidity, lubrication, temperature, and friction a consequence of corrosion and degradation of materials. Surface technologies, such as the carbonitriding and nitriding processes, have been used widely to prevent the steel surface from oxidation and corrosion (Grill, 1999; Mahmud *et al.*, 2015).

Diamond–like carbon (DLC) is an amorphous carbon with a structural combination of diamond (sp^3 bonding) and graphite (sp^2 bonding). It has recently been applied to the automotive industry due to its unique properties, for example, it has high hardness, a low friction coefficient, and is chemically inert. The DLC coating has been challenging because high internal stress can exist in the films when a thickness layer is required. Moreover, decreasing the sp^3/sp^2 ratio of DLC film at high temperature has an effect in low hardness. Therefore, the incorporation of elements in the DLC structure has been employed to enhance the adhesion efficiency and mechanical properties (Grill, 1999; Yang *et al.*, 2012).

In this research, the improvement of the oxidation and corrosion properties of the AISI 4140 through the DLC doping method with aluminium and nitrogen will be studied and discussed. Also, the mechanical properties and tribology will be investigated.

1.2 Aims of thesis

The purpose of this thesis was to synthesize DLC (ta–C), N–doped DLC (ta–C:N), Al–doped DLC (ta–C:Al), and co–doped (Al, N) DLC (ta–C:Al:N) films on an AISI 4140 low alloy steel substrate using a pulsed two–FCVA deposition method for improving the DLC films' oxidation and corrosion resistance. In addition, the structural bonding, nanomechanical properties, adhesion strength, and corrosion properties were examined, using several effective analytical approaches to gain a better understanding of the films' properties. The purpose was separated into three major areas:

1.2.1 To determine the optimal conditions for the deposition of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films using the pulsed two–FCVA method.

1.2.2 To examine the thermal stability (oxidation resistance) of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films at room temperature (RT) and the annealing temperature range to 700°C.

1.2.3 To get a better understanding of the mechanisms that contribute to the enhancement of the nanomechanical characteristics, corrosion resistance, and adhesion strength of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films.

1.3 The scope of the study

1.3.1 The ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N depositions were performed on a Si (100) wafer and an AISI 4140 low alloy steel substrate.

1.3.2 The ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films were synthesized using the developed pulsed two–FCVA deposition method with a separate cathodic arc source.

1.3.3 The doping elements were Al and N.

1.3.4 The following factors were used to determine the critical deposition parameters: base vacuum pressure, the negative direct current bias voltage of the substrate, deposition time, arc voltage, pulse repetition or frequency rate, and duty cycle.

1.3.5 The following methodology was used to determine the identity of the ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films:

(a) for the microstructure, chemical composition, and bonding configuration,

Raman spectroscopy, X–ray photoelectron spectroscopy (XPS), and near edge X–ray absorption fine structure spectroscopy (NEXAFS) were used.

(b) morphological evaluation of the surface used scanning electron microscopy (SEM) and atomic force microscopy (AFM).

(c) X–ray reflectometry (XRR) was used to determine density.

(d) nanomechanical properties were determined by nanoindentation testing.

(e) adhesion strength was determined by the nanoscratch testing.

(f) corrosion resistance was determined using a potentiostat analyzer.

(g) thermal stability was measured with X–ray photoemission electron microscopy (X–PEEM) in conjunction with in–situ NEXAFS.

1.4 The research places

1.4.1 Suranaree University of Technology's (SUT) Center for Scientific and Technological Equipment, Nakhon Ratchasima, Thailand.

1.4.2 Synchrotron Light Research Institute (SLRI), Nakhon Ratchasima, Thailand:

(a) Research Department Beamline 3.2Ub PEEM,

(b) Building and Utilities Division, Mechanical System Development and Utilities Department,

(c) Electrical and Electronics Division, Technical and Engineering Department.

1.5 Expected results

1.5.1 The ability to synthesize and analyze ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films deposited using the pulsed two–FCVA method.

1.5.2 Knowledge of the microstructures, bonding configurations, nanomechanical properties, adhesion strengths, thermal stability, and corrosion resistance of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films is essential.

1.5.3 Al and N co-doping represents a promising strategy for improving the thermal stability, oxidation resistance, and corrosion resistance of DLC films.

1.5.4 Gain experience in research in line with the principles of research

practice, the solution of problems during research, and practice collaboration, together with contact and coordination to accomplish the research.

1.5.5 The study findings are published in international publications and are available in the SCOPUS or ISI databases.

1.6 Outline of the thesis

This thesis is split into five chapters, each of which is concerned with the deposition and characterization of the structure and properties of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films produced by pulsed two–FCVA deposition.

The introduction to this thesis is stated above in this Chapter 1, including the rationale of the study, aims of this thesis, scope of the study, research places, expected results, and thesis outline.

The literature reviews in Chapter 2 provide a basic principle and brief review of AISI 4140 low alloy steel, diamond–like carbon (DLC) films, incorporation of alloying elements in DLC films, deposition methods for DLC films, applications of DLC films, nanomechanical properties, and adhesion strength of non–doped DLC, doped DLC, and co–doped DLC films, the thermal stability of DLC films, electrochemical corrosion, and a review of the literature.

The experimental procedures that have been implemented are described in Chapter 3 and include the preparation of the DLC films, the structural bonding configuration, elemental analysis, film thickness, density, nanomechanical properties and adhesion strength, and electrochemical corrosion analysis of the DLC films.

Chapter 4 offers a detailed description of the findings as well as a commentary of this study, which is divided into two major sections: (i) the structure, bonding configuration, thickness, and morphology of FCVA–synthesized ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films; and (ii) the nanomechanical properties and adhesion strength, thermal stability, and corrosion resistance of Al and N co–doped DLC films deposited on AISI 4140.

Finally, Chapter 5 discusses the key findings of the thesis and provides recommendations for future research.

CHAPTER 2

LITERATURE REVIEWS

2.1 AISI 4140 low alloy steel

Despite its exceptional strength and flexibility, AISI 4140 alloy steel, which is distinguished by its chromium and molybdenum content, is a low-alloy steel used extensively in industrial applications like gears, blades, and other critical components. Operating under extreme working conditions, such as rising temperatures, corrosive and oxidative environments, and high tribological stresses, which can cause significant mechanical degradation, it often runs across severe working situations. Often leading to complete component failure and reduced service life, failure modes like micro-pitting and scuffing are rather common (Liu *et al.*, 2017; Khani Sanij *et al.*, 2012; Li *et al.*, 2014). Many heat treatment and surface engineering processes have been applied to help to solve these issues and improve the performance of AISI 4140 steel. Mechanical properties, wear resistance, and corrosion resistance have shown gains in techniques including quenching and tempering, carburizing, nitriding, nitrocarburizing, and plasma nitriding (Li *et al.*, 2014; Sayuti *et al.*, 2014; Kovaci *et al.*, 2018).

As indicated in Table 2.1, the chemical composition of AISI 4140 usually consists of carbon (C) at 0.39–0.48 wt%, chromium (Cr) at 0.80–1.10 wt%, and molybdenum (Mo). Moreover, **Table 2.2** and **Table 2.3** separately define their mechanical and physical characteristics, respectively.

Table 2.1 Chemical composition of AISI 4140 (modified from Suryo *et al.*, 2018)

Chemical composition (wt%)							
C	Si	Mn	P	S	Cr	Mo	Fe
0.39 – 0.48	0.20 – 0.35	0.75 – 1.00	≤0.035	≤0.04	0.80 – 1.10	0.15 – 0.25	balance

Table 2.2 Mechanical properties of AISI 4140 (modified from [Online], Available: https://www.theworldmaterial.com/astm–sae–aisi–4140–steel/)

Conditions	Normalized at 870 °C	Annealed at 815 °C	Water quenched from 845°C & tempered at 540 °C
Mechanical Properties			
Tensile strength (MPa)	1020	655	1075
Yield strength (MPa)	655	414	986
Elongation in 50 mm, %	17.7	25.7	15.5
Reduction in area, %	46.8	56.9	56.9
Hardness (HB)	302	197	311
Density (g cm^{-3})	7.85* (Liu *et al.*, 2017)		

Table 2.3 Physical properties of AISI 4140 (modified from [Online], Available: https://www.theworldmaterial.com/astm–sae–aisi–4140–steel/)

Physical Properties	Temperature (°C)				
	20	100	200	400	600
Electrical resistivity value (μΩ m)	0.22	0.26	0.33	0.48	0.65
Thermal conductivity value (W/m·K)		42.7	42.3	37.7	33.1
	Temperature Range (°C)				
		20–100	20–200	20–400	20–600
Coefficients of linear thermal-expansion value (10^{-6}/K)		12.2	12.6	13.6	14.5
Specific heat value (J/Kg·K)			473	519	561

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2.2 Diamond–like carbon (DLC) films

Because of its remarkable mechanical, tribological, and chemical properties, diamond-like carbon (DLC) has attracted major attention in industry since the 1990s. Along with a low coefficient of friction (Donnet, 1998; Robertson, 2002; Vetter, 2014; Bootkul *et al*., 2014; Dai *et al*., 2017; Zhou *et al*., 2019), these characteristics include notable hardness, higher elastic modulus, enhanced wear, oxidation, and corrosion resistance. One of the properties is DLCs, depending on the carbon structure. Technologies and deposition techniques can change the DLC structure; materials can be inserted, including gas doping (e.g., hydrogen and nitrogen) and metal doping (e.g., silicon, titanium, aluminium, tungsten, chromium, and copper).

2.2.1 Structure bonding of DLC films

The DLC is an amorphous carbon structure with a proportion of diamond (sp^3 bonding) and graphite (sp^2 bonding) (Robertson, 2002; Aperador *et al.*, 2013; Ruden *et al.*, 2013; Lei *et al.*, 2019). In terms of being diamond–like, the proportion of sp^3 bonding can be manipulated to give different mechanical properties of DLC films. **Figure 2.1** shows the various structures of carbon–based materials, such as graphite, diamond, and amorphous carbon films (Robertson, 2002).

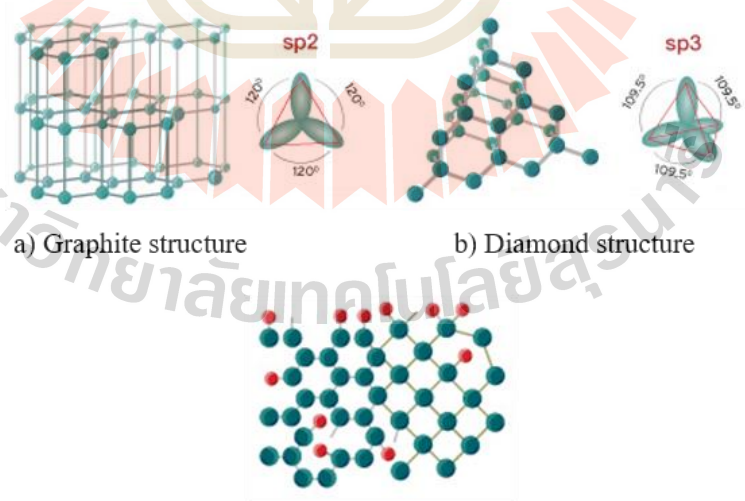


Figure 2.1 The structure of graphite, diamond, and DLC [Online], Available: [http://www.pvdadvancedtech.com/dlc/] Dec 30, 2021

DLC films can be classified into four primary categories based on hydrogen concentration: hydrogen-free tetrahedral amorphous carbon (ta–C), hydrogenated amorphous carbon (*a*–C:H), hydrogen-free amorphous carbon (*a*–C), and hydrogenated tetrahedral amorphous carbon (ta–C:H), respectively (Grill, 1999). **Figure 2.2** presents the ternary phase diagram illustrating the sp^2, sp^3, and hydrogen (H) components of various amorphous carbon structures (Robertson, 2002). The lower-left corner of the diagram corresponds to the sp^2 bond, representing the graphitic carbon and glassy carbon phases. The central region contains both sp^2 and sp^3 bonded carbon, as indicated by the *a*–C:H and ta–C:H areas (Grill, 1999; Robertson, 2002). The lower-right corner denotes the boundaries of hydrocarbon polymers, within which no stable films can form. **Table 2.4** summarizes the key properties of DLC films (Grill, 1999).

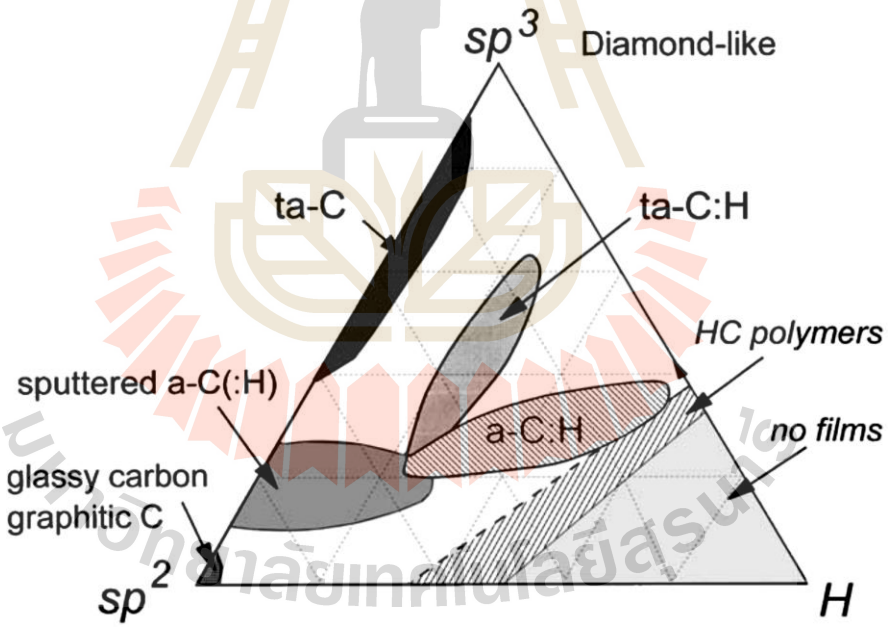


Figure 2.2 Ternary phase diagram of sp^2, sp^3, and H components of various amorphous carbon (Robertson, 2002).

2.2.2 Structure and mechanical properties of DLC films

The maximum hardness of the DLC film is the tetrahedral–bonded hydrogen–free coating (ta–C), which is generated when carbon from graphite or

hydrocarbon gas is evaporated or ionized in a vacuum and deposited on the substrate. When the DLC film is deposited on the specimen's surface, it is organized with amorphous carbon atoms, and thus the term amorphous carbon. Amorphous carbon is made of carbon links between graphite (sp^2 bonds) and diamond (sp^3 bonds), with the ratio of diamond to graphite determined by the film's structure. Arc voltage, bias voltage, carbon ion energy, ion density, and temperature are critical parameters for creating a high–quality DLC film. The larger the sp^3 percentage of the diamond carbon bond (DLC) or sp^3 fraction, the more diamond–like the DLC film's characteristics. The DLC layer's distinguishing characteristics are its hardness, Young's modulus of elasticity (Young's modulus), and strong chemical inertness (Grill, 1999; Ferrari *et al.*, 2000; Robertson, 2002; Anders, 2008; Vetter, 2014).

Table 2.4 The comparison of the main properties of various amorphous carbon materials (Grill, 1999)

Materials	sp^3 (%)	H (%)	Density ($g.cm^{-3}$)	Energy gap (eV)	Hardness (GPa)
Diamond	100	0	3.515	55	100
Graphite	0	0	2.267	0	–
Glassy C	0	0	1.3–1.55	0.01	3
Evaporated C	0	0	1.9	0.4–0.7	3
Sputtered C	5	0	2.2	0.5	–
ta–C	80–88	0	3.1	2.5	80
a–C:H Hard	40	30–40	1.6–2.2	1.1–1.7	10–20
a–C:H soft	60	40–50	1.2–1.6	1.7–4	<10
ta–C:H	70	30	2.4	2.0–2.5	50

2.3 Doping elements in DLC films

The adhesion of the DLC layer to the substrate often presents challenges, despite the DLC film's strength, robustness, and chemical inertness. Rising compressive stresses within the film arise from either the increasing thickness of the DLC film during

growth or from the film detaching from the substrate material (Wang *et al.*, 2007; Zhang *et al.*, 2013; Bootkul *et al.*, 2014). Therefore, it is essential to optimize the performance of the DLC film to prevent peeling and reduce internal tension within the film layer. It is utilized for enhancement and is prevalent today due to its ability to improve adhesion between the film layer and the substrate material. This is why it is applied in combinations of materials within the DLC film layer or by forming an interlayer between the film layer and the substrate material. Additionally, mixed components that integrate two or more types are utilized to provide additional characteristics as required for the application (Sun *et al.*, 2016; Xu *et al.*, 2020; Dai *et al.*, 2016, 2017). DLC films incorporate three distinct categories of doping agents:

In diamond-like carbon (DLC) films, non-metallic dopants such as nitrogen (N), oxygen (O), and fluorine (F) form bonds with carbon (C) (Hauert *et al.*, 1995; Bootkul *et al.*, 2014; Safaie *et al.*, 2017; Ryu *et. al.*, 2020).

Secondly, a category of metal alloys interacts with carbon in the DLC film to produce metal carbides. Notable examples include titanium (Ti), chromium (Cr), tungsten (W), molybdenum (Mo), and iron (Fe) (Liu *et al.*, 2018; Zhang *et al.*, 2015; Cui *et al.*, 2019; Constantinou *et. al.*, 2017; Ray *et al.*, 2016).

Carbide compounds comprising aluminium (Al), gold (Au), silver (Ag), copper (Cu), nickel (Ni), and cobalt (Co) (Ding *et al*. 2021; Zou *et al*., 2012; Wang *et al*., 2012) form a category of metal alloys that exhibit no reactivity with the carbon present in the DLC layer. These are present either as a cluster of nanocrystals or as pure metal encapsulated within a film. The incorporation of metal atom alloying components into the DLC structure reduces compressive stress and enhances adhesion strength. Additionally, enhancing mechanical, tribological, corrosion resistance, thermal stability, electrical and optical properties, as well as biocompatibility, is it enables a broader range of film applications. Doping can increase the sp^2 content within the carbon network structure; therefore, it is essential to consider doping concentrations. (Bootkul *et al.*, 2014). This will assist the DLC film in preserving its attributes.

2.4 Deposition methods for DLC films

DLC films can be synthesized by various techniques. In 1971, the first DLC

thin film was deposited by Aisenberg and Chabot using the ion beam deposition technique. Subsequently, the DLC deposition was developed by the chemical vapor deposition (CVD) and physical vapor deposition (PVD) methods, respectively. For the synthesis of DLC films, plasma enhanced chemical vapor deposition (PECVD) is the most commonly used method for the laboratory scale, but it has limited industrial applications. The sputtering method is preferred for industrial processes because of its ability and simplicity to adjust the process. Finally, the cathodic arc method can generate a high–density plasma ion, but it is limited in its applications because of the unstable cathode spot and insufficient filtering for the macroparticle elimination in the process. Currently, methods such as sputtering and cathodic arc coating have evolved into the high–power impulse magnetron sputtering (HiPIMS) and filtered cathodic vacuum arc (FCVA) processes, respectively, to enable the generation of high–density and uniform plasma ions throughout the coating. Additionally, a magnetic filtered coil is included to filter and decrease the number of macroscopic particles that fall onto the film layer during coating, consequently, facilitating the generation of a superior diamond-like carbon film and the eradication of film imperfections.

2.4.1 Sputtering

Sputtering is a popular coating technique. The coated target is bombarded with ion energy created by the plasma in a glow discharge, causing sputtering of the coated target atoms, which condense and form a thin layer on the coating surface. This procedure is carried out under argon gas conditions to promote the co–reaction of sputtering and acetylene gas. Furthermore, the specimen must be heated to roughly 200°C at a base pressure of approximately 10^{-1} Pa, to allow the ionization process to proceed easily. The method can uniformly coat the workpiece. However, the consequence of significant surface heating is that there is a modest rate of film deposition and ionization in the plasma. At present, it is created by arranging magnets in such a manner that the initial pole is positioned in the middle of the workpiece. The second pole generates a magnetic ring around the workpiece's outside border, trapping electrons and increasing the likelihood of atomic collisions and electron–ionization. This results in concentrated plasma in the coated target region and greater ion bombardment of the coated target. This results in a faster sputtering

rate and a faster surface coating deposition rate (Kelly and Arnell, 2000; Hainsworth and Uhure, 2007). This technique is known as magnetron sputtering and is shown in **Figure 2.3**.

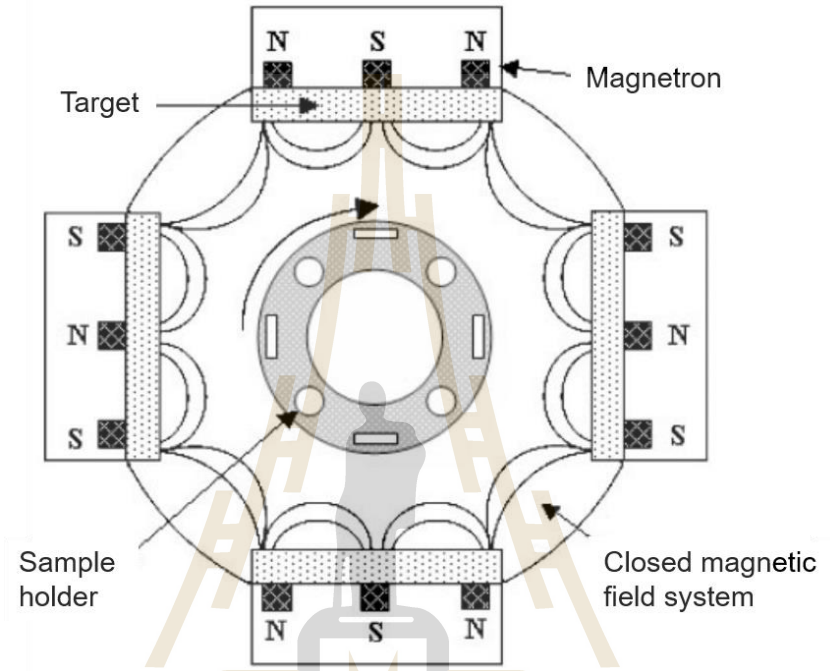


Figure 2.3 Schematic of the plasma in magnetron sputtering process (Hainsworth and Uhure, 2007)

2.4.2 Plasma-enhanced chemical vapor deposition (PECVD)

To induce electron production between cyclotron resonance, inductively coupled or capacitively coupled areas, most PECVDs use radio frequency (RF) plasma at the ambient temperature. The capacitive parallel plate design is the most frequently used parallel plate configuration in which ion densities and temperature distinguish the features of the plasma employed in the PECVD process. To reduce the reflected energy, the plasma has a radio frequency generator and a matching box. For traditional film coatings, the RF power ranges from 200 W to 20 kW, with RF electrodes utilized to form the plasma. Deposition variables such as temperature, deposition duration, pressure, inert gas flow rate, and the RF power

employed for the PECVD process all impact the deposition rate of the thin film created at 13.56 MHz. In plasma production, the surface might be positioned immediately between the parallel plates or at the plasma zone tip. The monomer intake and argon gas are essential for plasma generation and for mitigating the effects of bombardment within the plasma zone. Additionally, it is connected to a vacuum pump which allows low-pressure film deposition within the standard PECVD coating chamber, which is shown in **Figure 2.4** (Vasudev *et al.*, 2013; Pauschitz *et al.*, 2003; Woehrl *et al.*, 2014).

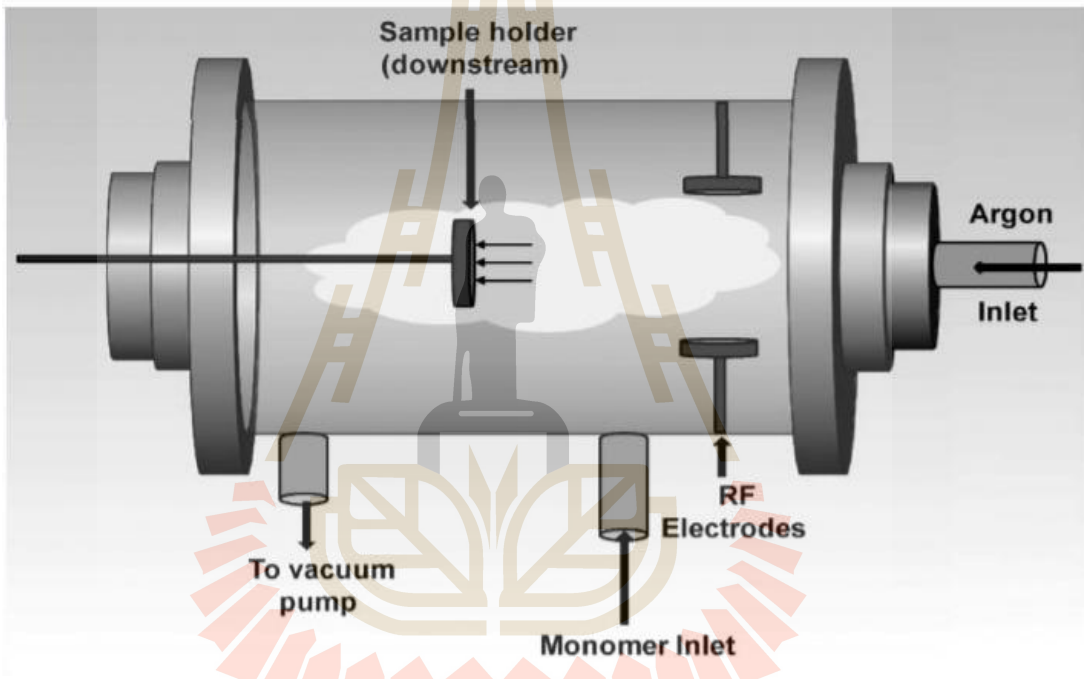


Figure 2.4 Schematic representation of a standard chamber used in the PECVD process (Vasudev *et al.*, 2013)

2.4.3 High power impulse magnetron sputtering (HiPIMS)

HiPIMS is a technology that uses a sputtering mechanism to generate vapor plasma at a base pressure of 10^{-4} Pa while being evacuated by rotary vane pumps and turbomolecular pumps to maintain a constant plasma discharge during the coating process. It uses up to 1 kW/cm² of electrical power, a kHz pulse frequency, and a microsecond duty cycle. A control approach may also be used to alter the plasma density. High levels of ionization are produced via power, frequency, and duty

cycle, comparable to arc evaporation methods. As a result, ionization during coating is high, and the coating layer is thick. To reduce the number of flaws in the film, surfaces with intricate shapes may be coated using this method. A low amount of heat is applied to the workpiece's surface. HiPIMS is more suitable for creating usable films at lower temperatures than other technologies because, during lamination, ion bombardment is delivered to the workpiece's surface to deposit the film. The schematic of the HiPIMS process is shown in **Figure 2.5** (Tucker, 2016; Gómez *et al.*, 2021).

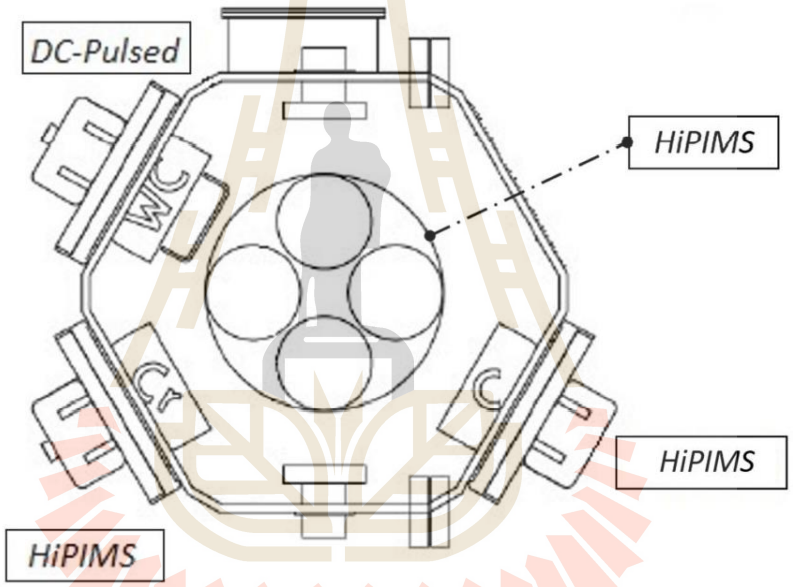


Figure 2.5 A horizontal cross–section of the HiPIMS chamber (Gómez *et al.*, 2021)

2.4.4 Filtered cathodic vacuum arc (FCVA)

The filtered cathodic vacuum arc (FCVA) is the most common technique used to synthesize the DLC film since it produces an excellent DLC film with sp^3 carbon bonds of more than 80% in the DLC film's structure, but it will produce the so–called macroparticles during the deposition. A 90–degree bending magnetic coil is used as a filter to control the plasma's direction. Subsequently, the macroparticles are trapped inside the coil, and the remaining ions are controllable within the coil before expanding rapidly toward the substrate, which can remove more than 99% of the

macroparticles. The schematic diagram of the FCVA machine is depicted in **Figure 2.6**. It uses a high–frequency power DC voltage, a negative bias voltage at the substrate, a solid graphite used as the cathode, and a counter anode connected to the ground potential. The DLC film can thus be deposited in gas plasma by active ions moving through a magnetic coil and deposited on the substrate. **Figure 2.6** illustrates the architecture of the FCVA system for doping Al into the DLC film. As a result, carbon and aluminium ions can be simultaneously deposited on the substrate. The amount of the doping can be controlled by adjusting the arcing frequency ratio of the two cathodes. Nitrogen doping can be performed by introducing nitrogen gas into a deposition chamber during the coating process (Anders, 2008; Marques *et al*., 2003; Wei and Yen, 2007; Lu and Chung, 2008).

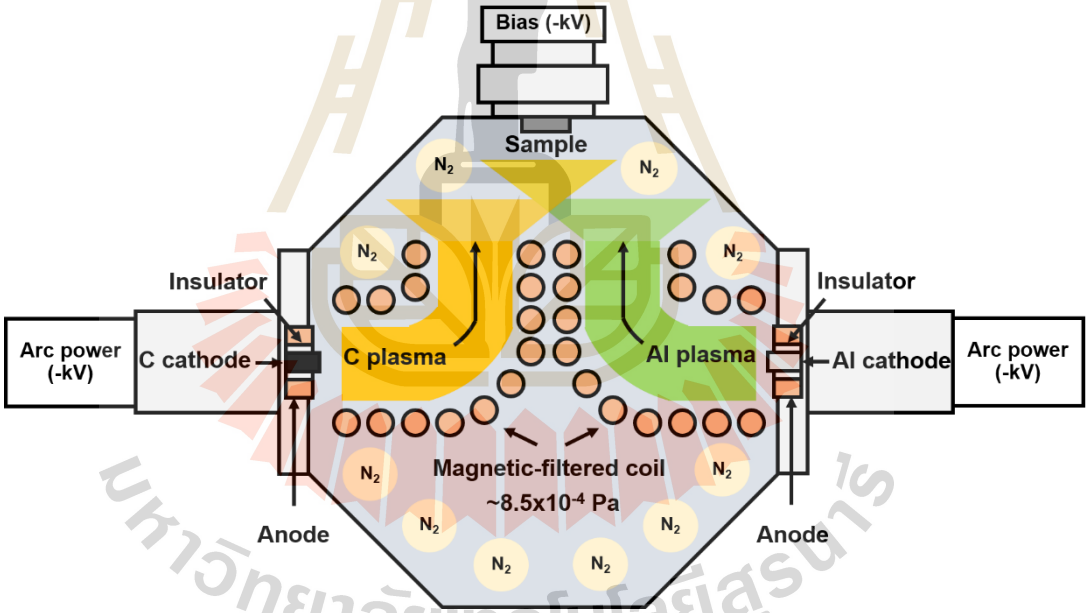


Figure 2.6 Schematic of developed FCVA technique for metal doping (Wongpanya, Silawong, & Photongkam, 2022)

2.5 Applications of DLC films

The DLC coating techniques are becoming more prevalent nowadays due to their high hardness, wear resistance, and corrosion resistance, as well as their excellent thermal stability. As a result, the techniques are well–suited for automotive applications such as bearings and pistons for motors and pumps, as well as driving components such as gears and shafts. The diamond–like carbon coating on the drive shafts results in a 1% improvement in fuel efficiency and a 1% reduction in CO_2 emissions (Hainsworth and Uhure, 2007). Due to its strong electrical resistance, excellent thermal conductivity, and dielectric properties, DLC film may be used in a variety of applications in the electronics sector, including hard disk heads. Additionally, the use of elemental alloys such as Ti doping to increase the DLC characteristics may improve biocompatibility while maintaining strong corrosion resistance. Notably, it is non–toxic to the body (Wongpanya, Pintitraratibodee, Thumanu, & Euaruksakul, 2021; Liu *et al*., 2018). This facilitates the application of DLC's tribological properties in the medical sector. Currently, it is employed as a coating on materials used in artificial joints–knees and hips–implants, and artificial heart valves. Depending on its composition, DLC coating offers excellent wear resistance, corrosion resistance, and thermal stability. As a result, DLC films are gaining widespread popularity and are increasingly being used in a variety of applications, including household appliances, razor blades, jewelry, and wristwatches. As can be seen, the DLC covering has been a huge success for many decades in addressing many real engineering difficulties. The potential exists to enhance DLC features to meet the requirements of forthcoming applications (Hainsworth and Uhure, 2007; Konkhonthot *et al*., 2018). Some examples of the application of DLC films are shown briefly in **Figure 2.7**.

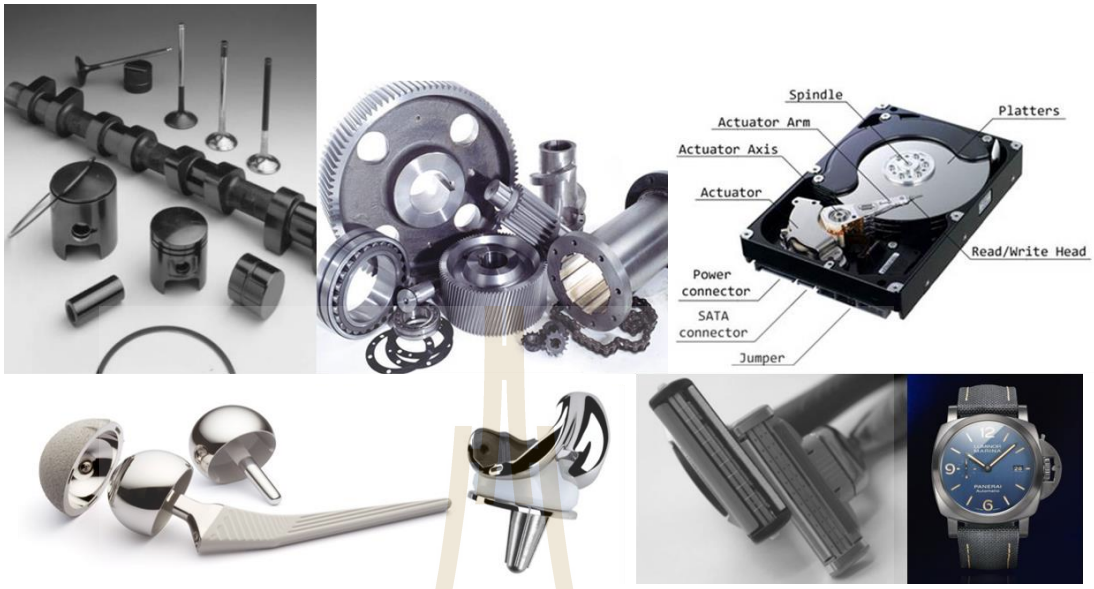


Figure 2.7 Examples of the DLC coating application: automotive parts, engineering parts, hard disk drive parts, medical parts, razor blades, and a watch (Hainsworth and Uhure, 2007; [Online], Available: http://nptel.ac.in /courses/115103038/28; [Online], Available: http://www.indiamart.com /devraj– engineering/job–work.html; [Online], Available: http://www. caperay. com/blog/ index.php /2013/i–guarantee–this–device–wont–fail/; [Online], Available: http://www.intechopen. com/books/ arthroplasty–update/the–evolution–of–modern–total–knee–prostheses; [Online], Available: https://watchessiam.com/2019/10/30/panerai–luminor –titanium –dlc–bucherer –blue–pam01021/)

2.6 The nanomechanical and adhesion strength of DLC films

2.6.1 Nanoindentation testing

Nanoindentation is commonly used for determining the mechanical properties (i.e., hardness, elastic modulus, creep, and residual stress) of thin–film and nanocomposite materials. The result of the nanoindentation shows the load and contact stiffness as a function of the displacement of the indenter onto the samples, as shown in **Figure 2.8**. The Oliver and Pharr equation model is used to determine the elastic modulus of the thin films from the linear portion of the force–displacement

unloading curve that can be shown in the following Equation (2.1) (Oliver and Pharr, 2004):

$$S = \frac{dP}{dh} = \frac{2\sqrt{A}}{\sqrt{\pi}} \times E_r \tag{2.1}$$

where E_r is the reduced modulus (GPa), S is the contact stiffness (N/m), and A is the contact area (m^2). Then, the reduced modulus E_r can be computed from the following Equation (2.2):

$$\frac{1}{E_r} = \frac{1-\nu_i^2}{E_i} + \frac{1-\nu_s^2}{E_s} \tag{2.2}$$

Here, E_i and ν_i denote the Young's modulus and Poisson's ratio of the indenter, while E_s and ν_s represent, respectively, the Young's modulus and Poisson's ratio of the specimen.

Finally, the hardness can be calculated using the relative of the following Equation (2.3),

$$H = \frac{P_{max}}{A} \tag{2.3}$$

where H is the hardness (H_v), P_{max} is the peak of indentation load (N), and A is the projected area of the hardness impression (m^2).

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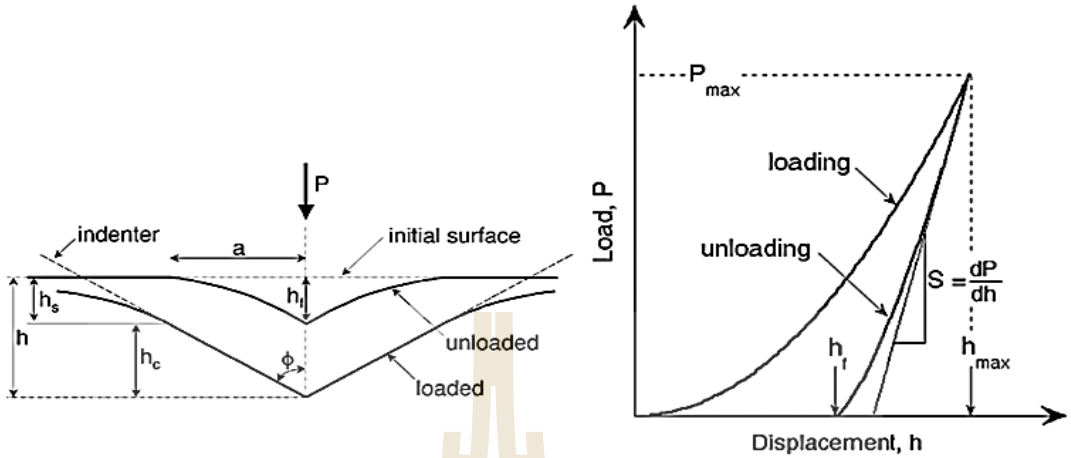


Figure 2.8 Schematic of the load and displacement curve, and deformation surface (Oliver and Pharr, 2004)

2.6.2 Adhesion testing

Reflecting the interfacial bonding strength between the coating and the substrate, adherence strength is a fundamental quality of coating films (Marjanovic *et al*., 2006; Moerlooze *et al*., 2011). Adhesion strength is extremely important in scientific and engineering uses, including the design of tools, medical equipment, and automobile components. Because of their simplicity in sample preparation and their dependability of the outcomes, adhesion tests are extensively used to assess this quality. The pull-off test, tape test, chisel test, bend test, and scratch test (Marjanovic *et al*., 2006), among several techniques, have been applied with success to evaluate the cohesive strength of diamond-like carbon (DLC) films. Among these, the scratch test is often used to assess adhesion strength by steadily increasing the typical stress applied to the coating until film failure results. This method provides the critical load (L_c) at which the coating delaminates. Additionally, the progression of film damage during scratch testing can be monitored using acoustic emission (AE) and electrical surface resistance (ESR) techniques (Moerlooze *et al*., 2011).

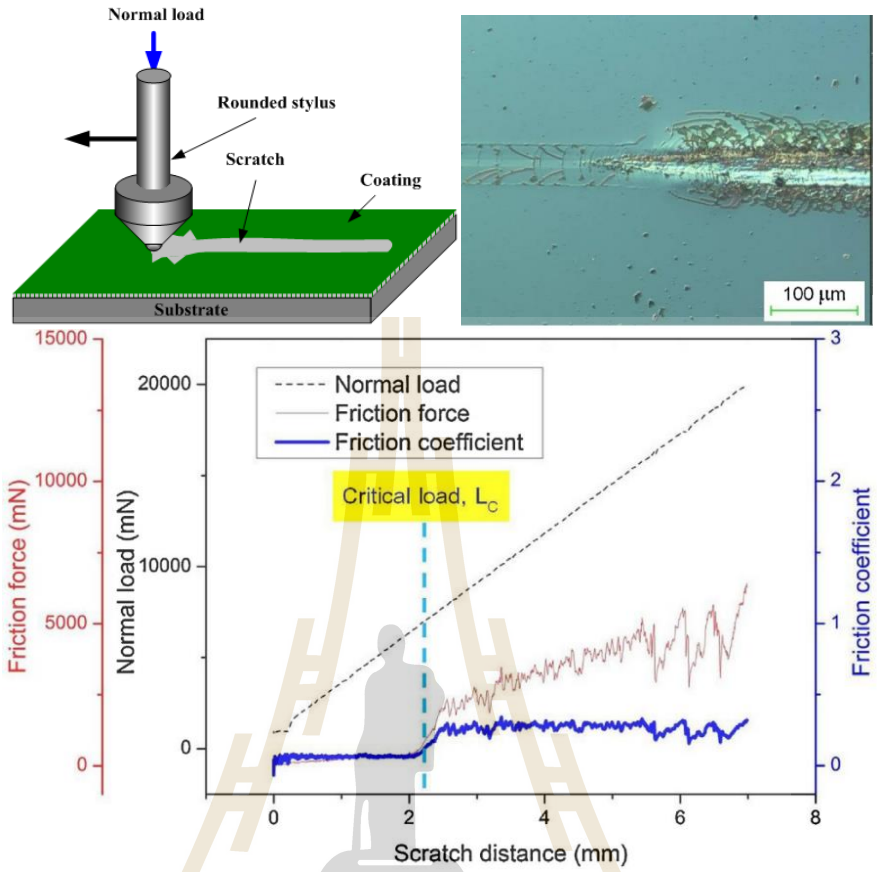


Figure 2.9 The schematic of a scratch tester, the result of the scratch test, and a microscope image of the damaged features at the critical (L_c) (Bootkul *et al*., 2014; Tay *et al*., 2000)

In adhesion testing, resistance to crack initiation is assessed based on the first critical load (L_{c1}). A higher L_{c1} indicates greater difficulty in initiating a fracture in the coating film. Furthermore, the toughness of the film is considered to be proportional to both the difference between the higher and lower critical loads ($L_{c2} - L_{c1}$) and the value of L_{c1} itself (Zhang *et al*., 2004). Therefore, scratch crack propagation resistance (CPRs) is commonly used to evaluate adhesion strength, as illustrated in Equation (2.4) below:

$$\text{CPRs} = L_{c1}\,(L_{c2} - L_{c1}) \tag{2.4}$$

2.7 Thermal stability of DLC films by in–situ NEXAFS

High–temperature oxidation of metals is a corrosion process, involving the reaction between a metal and the atmospheric oxygen at a high temperature. It results in an oxide layer formed on the surface of the oxidized metal. The oxide layer may protect an underlying metal or may also thicken into a non–protective layer with various defects, such as a cavity, micro–crack, and porosity. The oxide layer degrades the underlying material's properties, particularly the strength, corrosion resistance, and conductivity. These degradations are a problem for engineering parts such as heat exchangers, valves, pistons, and cutting tools. Rapid deterioration is observed for steel automotive parts exposed to high temperatures during service. The in–situ NEXAFS methodology (Maruyama *et al*., 2015; Lapteva *et al*., 2019) was utilized to evaluate the structural changes of the DLC film layer while heated by rapid thermal annealing (RTA), which is a heating method, for the thermal stability investigation in this work. RTA uses filaments to heat the specimen in a high vacuum system in the main analysis chamber until the test temperature is attained, and then the heating period is measured. At the end of the time, the temperature was lowered to 300°C, and the local bonding structure was assessed to determine its thermal stability based on the increasing quantity of the graphite structure (sp^2 fraction), known as graphitization, in the DLC film layer (Konkhunthot *et. al*., 2019; Zhang *et al*., 2002).

Photoemission electron microscopy (PEEM) is an imaging technique that utilizes photo–emitted electrons to generate an image of a surface. It can be used to analyze the elemental components and chemical structures in a particular area at a microscale. **Figure 2.10** shows the SPELEEM schematic. The microscope consists of multiple lenses and an energy analyzer between the projector lens and the multichannel plate screen (MCP). Secondary electrons, Auger electrons, and photoelectrons can be selected with the energy analyzer to form the image (i.e., low pass filtering).

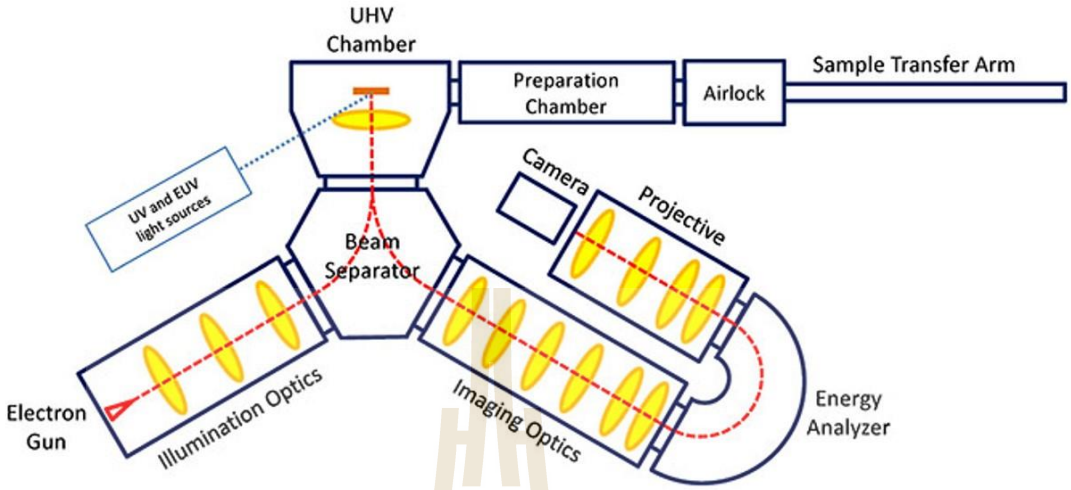


Figure 2.10 The schematic of spectroscopic photoemission and low electron microscope (SPELEEM) [Online], Available: https://groups.oist.jp/fsu/leem–peem

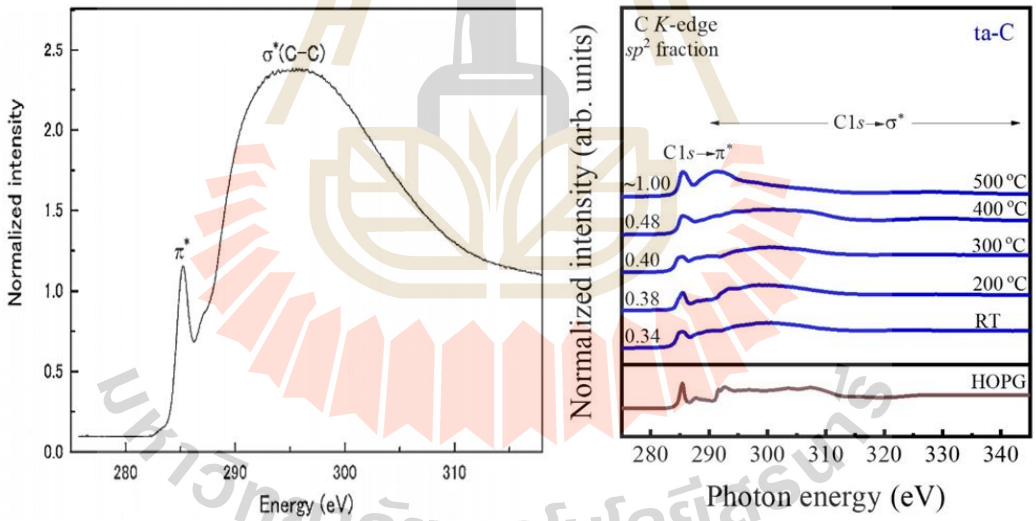


Figure 2.11 C *K*–edge NEXAFS spectrum of DLC film from X–ray absorption technique and C *K*–edge NEXAFS spectra obtained at room temperature (RT) and thermally annealed to graphitization temperature for ta–C (Saikubo *et al.*, 2006; Wongpanya, Silawong, & Photongkam, 2021).

In metallurgy, PEEM is used to observe the formation of microstructures and to characterize the chemical compositions on a material's surface in real time. The technique has the capability for X-ray absorption spectroscopic imaging, particularly in the soft X-ray region. It can be used to analyze the structure of C, Al, and N in the DLC film (Euaruksakul *et al.*, 2013). **Figure 2.11** shows the C *K*-edge NEXAFS spectrum obtained from PEEM, along with the C *K*-edge NEXAFS spectra acquired at room temperature (RT) and after thermal annealing to the graphitization temperature for ta-C. These spectra represent the local bonding of carbon elements as determined by NEXAFS analysis in this study, as illustrated in **Table 2.5**.

Table 2.5 The local bonding of carbon elements obtained from the NEXAFS analysis.

Type of bonding	Energy band (eV)	Reference
π* (C=C sp^2)	285.4	Konkhunthot *et. al.*, 2019
π* (C=N sp^2)	285.9	Zhang, 2003
π* (C=OH)	286.1	Sainio, 2021
π* (C–O)	286.5	Gandhiraman, 2014
σ* (C–H)	287.5	Sainio, 2016, McChan, 2005
σ* (C–N sp^3)	287.7	Zhang, 2003
π* (C=O)	288.5	Gandhiraman, 2014 Sainio, 2016
σ* (C–C sp^3)	289.8	Sainio, 2016
σ* (C=C sp^2)	292.8	Sainio, 2016
σ* (C–O)	297.5	Gandhiraman, 2014
σ* (C≡C sp^1)	303.8	Ohmagari, 2009

2.8 Electrochemical corrosion of DLC films

2.8.1 Electrochemical corrosion

Corrosion is the deterioration and disintegration of a metal that has reacted with the environment. The corrosion product is mostly formed as an oxide

film on the surface that affects the decrease of mechanical properties, conductivities, and the reflection of the material. Delamination of the oxide film can be generated by an initial crack on the surface and develop into a fracture. Consequently, corrosion testing is vital for comprehending the corrosion behavior of materials. Currently, potentiostat analyzers are widely used to evaluate the corrosion rates of various materials. The concept of a potentiostat analyzer is that the corrosion current and potential occurring from an electrochemical reaction will be measured between the specimen and the reference electrode, and the specimen and the counter electrode, respectively.

The relationship between potential and current density is plotted as a polarization curve, which is used to determine the corrosion rate. **Figure 2.12** shows a schematic diagram of a potentiostat analyzer.

There are three electrodes used to conduct the corrosion test:

1. An Ag/AgCl (3.3M KCL) is used as a reference electrode;
2. A platinum or graphite rod is used as a counter electrode;
3. A specimen is used as a working electrode.

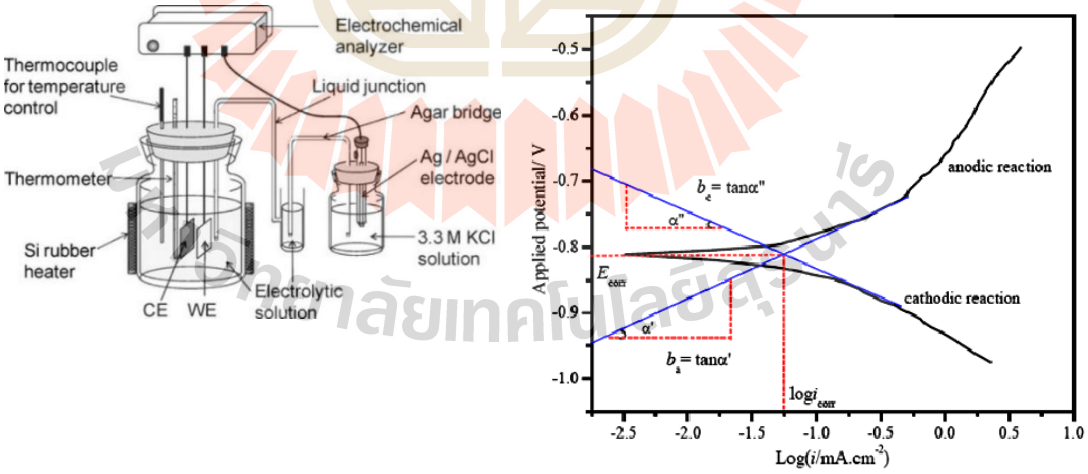


Figure 2.12 The schematic of a potentiostat analyzer and polarization curve [Online], Available: http://jes.ecsdl.org/content/159/4/D181.abstract., (Bhandari *et al.*, 2012)

In the DLC films, the corrosion resistance has been evaluated by a potentiostat analyzer in sodium chloride (NaCl) solution (Bhandari *et al*., 2012; Khun *et al*., 2009). **Figure 2.13** shows an example of the polarization curve of the DLC film and an SEM image of the corrosive area after corrosion testing**.**

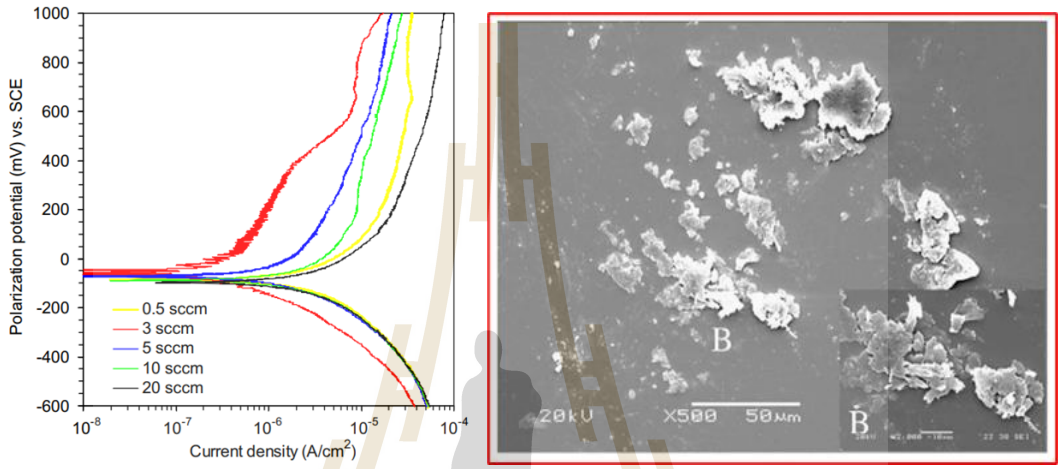


Figure 2.13 The polarization curve of ta–C:N and SEM image after potentiodynamic polarization test (Khun *et al.*, 2009).

2.8.2 Electrochemical analytical method and Interpretation of result data

From the obtained polarization curves as shown in **Figure 2.14**, important corrosion parameters including the corrosion potential (E_{corr}), the corrosion current density (i_{corr}), the polarization resistance (R_p), and the anodic and cathodic Tafel constants (b_a and b_c, respectively) were extracted using Faraday's law and the Tafel extrapolation technique.

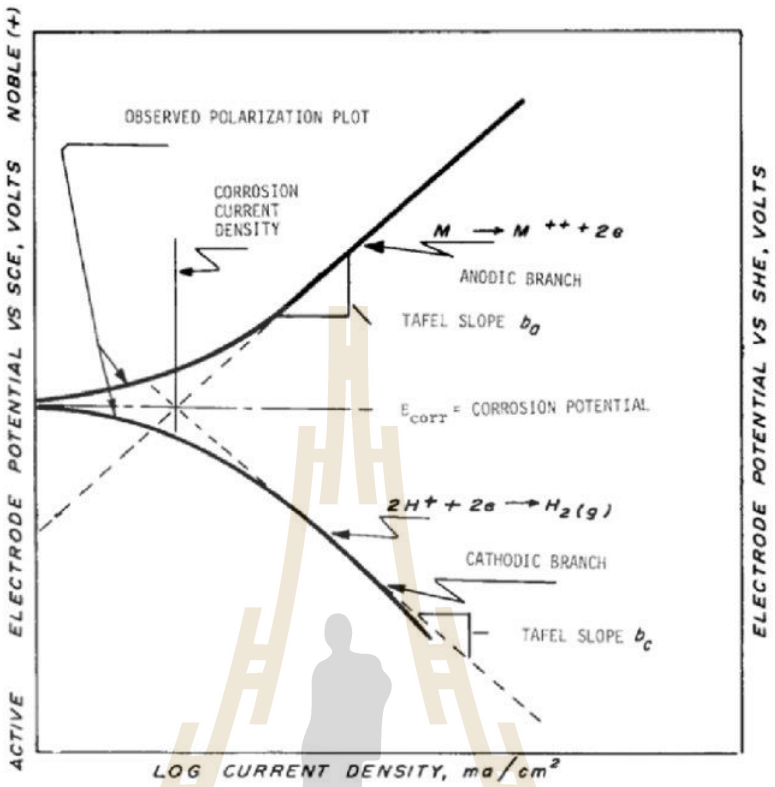


Figure 2.14 The polarization curve of E_{corr} and i_{corr} from the polarization test [ASTM standard G3–89, 2006]

The corrosion rate (CR) was calculated using i_{corr}, whereas R_p was calculated using Equations (2.5) – (2.6) according to ASTM G102–89 and ASTM G59–97, respectively (ASTM Standard G102–89, 2015; ASTM Standard G59–97, 2014).

$$CR = \frac{0.00327 \times i_{corr} \times EW}{\rho} \tag{2.5}$$

Here, EW is the equivalent weight of the alloy determined with Equation (2.6), and i_{corr} is the corrosion current density (μA cm^{-2}). The density of each sample (g cm^{-3}), required for this calculation, was determined using X-ray reflectometry (XRR) in combination with X-ray diffraction (XRD), yielding values of 7.85, 2.52, 2.22, 2.17, and 2.32 g cm^{-3} for AISI 4140, ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N, respectively.

$$EW = \frac{1}{\sum \frac{f_i n_i}{W_i}} \tag{2.6}$$

Hence, f_i is the mass fraction of the ith element in the sample, n_i is the number of electrons transferred during corrosion of the ith element in the sample, and W_i is the ith element's atomic weight.

$$R_p = \frac{(b_a \times b_c)}{(2.303 \times (b_a + b_c) \times i_{corr})} \tag{2.7}$$

Where R_p denotes the polarization resistance in Ω cm^2, i_{corr} denotes the corrosion current density in A cm^{-2}, and b_c and b_a denote the cathode and anode Tafel slopes in V dec^{-1}, respectively (ASTM Standard G59–97, 2014).

In addition, Equations (2.8) – (2.9) (Konkhunthot *et al*., 2019; Matthes *et al*., 1991; Yu *et al*., 2003) may be used to calculate the porosity (P) and protective efficiency (P_i) of each DLC film, which are crucial indicators of the films' corrosion resistance.

$$P = \frac{R_{\mathrm{P}}^0}{R_{\mathrm{p}}} \times 10^{-|\Delta E_{\mathrm{corr}/b_{\mathrm{a}}}|} \tag{2.8}$$

Where R_{p}^0 and R_{p} are the substrate's and the DLC's polarization resistances, respectively, ΔE_{corr} is the substrate's and the DLC's corrosion potential difference, and b_a is the substrate's anodic Tafel slope.

$$P_{\mathrm{i}} = 100\left(1 - \frac{i_{\mathrm{corr}}}{i_{\mathrm{corr}}^0}\right) \tag{2.9}$$

The corrosion current density of the substrate and the DLC film, respectively, are i_{corr}^0 and i_{corr}.

This thesis will investigate the influence of Al–N dopants on the structure, mechanical properties, adhesion strength, thermal stability, and corrosion resistance, respectively. The DLC films were deposited utilizing 2 pulsed FCVA deposition processes to produce the DLC films of the ta–C type. In the system, there is a magnetic field coil that can be used to eliminate the macroparticles that produce surface defects in each of the DLC films. To investigate the link between the films' structures, mechanical characteristics, adhesion strengths, thermal stability, and corrosion resistance capabilities, AISI 4140 steel was coated with DLC films. It was utilized to analyze a film's structure and thermal stability using in–situ Near edge x–ray absorption fine structure (in–situ NEXAFS) spectroscopy. The ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films were investigated at room temperature (RT) and during utilizing radiant heating and electron beam bombardment. The cross–section was evaluated using heat annealing to 700°C, field emission scanning electron microscopy (FE–SEM), and focused ion beam etching in conjunction with scanning electron microscopy (FIB–SEM). DLC Raman spectroscopy was used to determine the critical structural parameters such as the I_D/I_G ratio, peak D and G, full width at half maximum (FWHM (G)), compressive residual stress (CRS), and cluster size of the sp^2 sites or graphite (L_a), while X–ray photoelectron spectroscopy (XPS) was used to determine the impurities content and sp^3/sp^2 ratio. Nanoindentation was used to determine a film layer's adhesion capability.

Finally, the DLC film's corrosion resistance was examined using a potentiostat analyzer, and the specimen's surface was evaluated after corrosion tests using XPS, NEXAFS, and SEM, respectively.

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CHAPTER 3

EXPERIMENTAL PROCEDURES

3.1 Preparation of DLC films by FCVA

The workpieces were separated into two groups for this investigation. The first set was investigated for the coating's nanomechanical characteristics, thermal stability, and layer thickness. The first set (set I) of the specimens used was coated with ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films. All films were coated on AISI 4140 steel samples. After 30 minutes of the coating time, the specimens were evaluated for the film layer structure in preparation for mechanical property testing, thermal stability, and the thickness of the film layer, respectively.

For the second set (set II) of workpieces, all four types of film were coated, and the workpieces were named identically to the first set, but the thickness was uniform throughout. All film layers were coated on Si (100) specimens to determine the film density and thickness, as well as on AISI 4140 steel to determine the corrosion resistance and film adhesion strength, and to analyze the complete film layer's structure. The procedure chart of the thesis activities for the research and the coating parameters for the FCVA deposition of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N are shown in **Figure 3.1** and **Table 3.1**, respectively.

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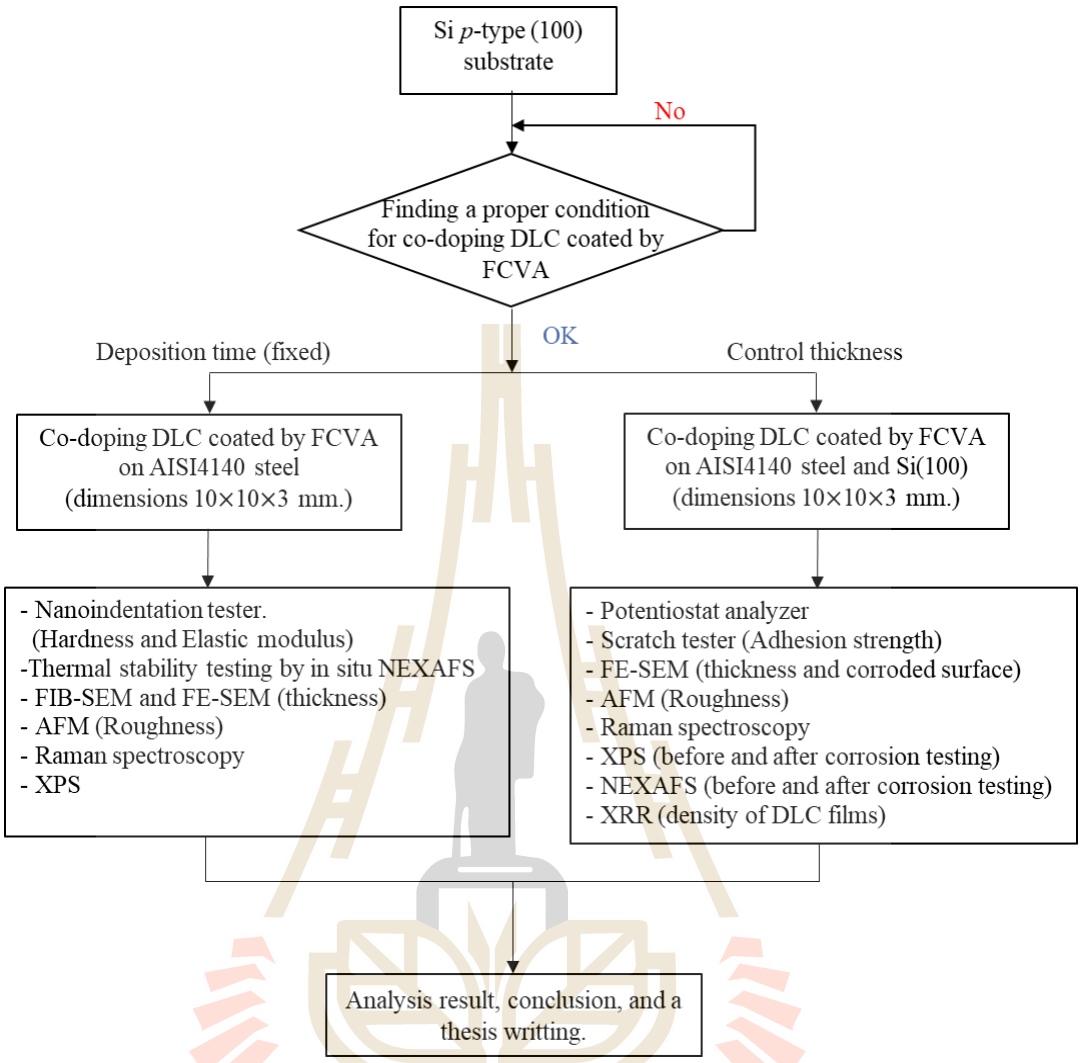


Figure 3.1 The procedure chart of project activities for research on the topic of nanomechanical properties, thermal stability, and corrosion resistance of aluminium and nitrogen–doped diamond–like carbon film

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Table 3.1 Coating parameters for FCVA deposition of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N. (modified from Wongpanya, Silawong, & Photongkam, 2021; Wongpanya *et al*., 2022)

Coating parameters	Deposited time	Control thickness (fixed)
Coating materials (Targets)	Graphite (99.99% C) and Aluminium (99.99% Al)	
Arc potential applied to cathodes (V_{arc})	400 and 800 V for Al and C	
Base pressure	8.5×10^{-4} Pa	
Base pressure for N doping	3.0×10^{-2} Pa	
UHP N_2 flow rate	2.5 SCCM* for ta–C:N and ta–C:Al:N	
Bias voltage applied to cathodes (V_{bias})	–1000 V	
Duty cycle	0.003%	
Frequency	6.0 Hz	
Coating time	30 min	19, 15, 30, and 22 min for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N, respectively

*SCCM denotes standard cubic centimeters per minute at standard temperature and pressure (STP)

3.1.1 The DLC film samples were coated on AISI 4140 steel and Si (100), which were cut into 10 mm^2 pieces. All the samples were ground using silicon carbide paper of successively finer grits up to 1500 grit, and then ultrasonically cleaned with acetone and ethanol for 20 minutes to remove surface contamination before being dried with N_2 gas (99.99% pure).

3.1.2 To deposit the non–doped, doped, and co–doped DLC coatings, the pre–cleaned substrates were put into an FCVA chamber, which was then evacuated to a regulated base pressure of 8.5×10^{-4} Pa.

3.1.3 Each cathodic source was independently equipped with a graphite cathode and an aluminium cathode (99.00% C and 99.99% Al), both in the form of 8-mm rods. During the DLC deposition process, targets and ceramic insulators were placed between the anode and cathode. A conduction line was drawn with a graphite pencil to initiate the spot arc and generate the plasma arc discharge. Magnetic filter coils with 90-degree bends were employed to filter the plasma generated by

the source during DLC deposition. The distance between the magnetic filter coil output and the substrate was maintained at 30 mm, as illustrated in **Figure 3.2**.

3.1.4 To maintain the balance between the cathode consumption and arc stability during deposition, a bias voltage (V_{bias}) of −1000V was used to drive the arc current with pulse repetition rates of 6.0 Hz and a duty cycle of 0.003% for both the graphite and aluminium cathodes, as shown in **Table 3.1**.

3.1.5 To eliminate any surface contaminations, both the aluminium and graphite cathodes were arced for 5 minutes at V_{bias} of −1500 V (Konkhunthot *et al.*, 2018, 2019). To eliminate any surface oxides and provide an active surface for DLC films, the substrate was blasted with carbon ions at a V_{bias} of −1500 V, which was greater than the bias employed in the deposition procedure.

3.1.6 After the vacuum pressure was reduced to 8.5×10^{-4} Pa, the film coating process began. Before N doping, ultrahigh purity (UHP) N_2 gas was constantly circulated into the chamber, raising the vacuum pressure from the base pressure to 3×10^{-2} Pa; there was a wait of 5 minutes to ensure that the N_2 gas was flowing stably within the chamber (Bootkul *et al.*, 2014).

3.1.7 On the jig, the sample was deposited (a cross region between C and Al) and V_{bias} was applied immediately.

3.1.8 Non-doped DLC (ta-C), nitrogen-doped DLC (ta-C:N), aluminium-doped DLC (ta-C:Al), and aluminium and nitrogen co-doped DLC (ta-C:Al:N) films can all be fabricated using the FCVA deposition method, as summarized in **Table 3.1**.

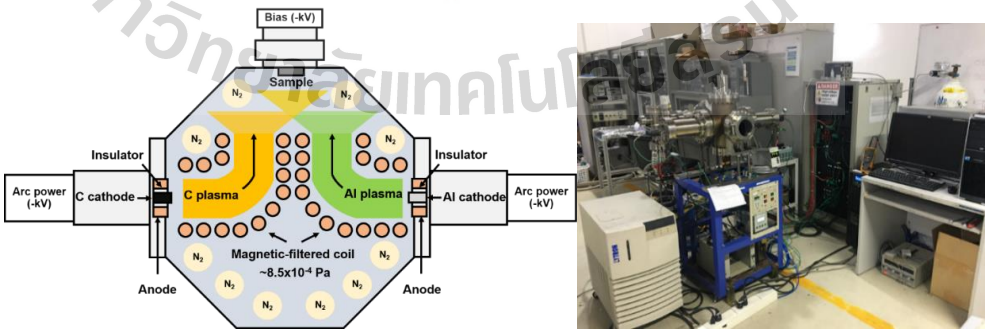


Figure 3.2 Schematic of developed FCVA technique for synthesis films (Wongpanya *et al.*, 2022)

3.2 Structural bonding configuration, elemental analysis, film thickness, and surface morphology

3.2.1 Raman spectroscopy

Raman spectroscopy, a popular technique, is a non–destructive method to characterize the structure of carbon–based materials. As light is scattered on a surface, there are two main types of scattering: an elastic process (Rayleigh scattering) and an inelastic process (Raman scattering). The Raman scattering occurs by atomic vibration in the excited state within the energy the energy shell according the Boltzmann's law based on Raman spectroscopy. The scattered photon is generated mostly into low energy (Stokes scattering) and high energy (anti–Stokes scattering) more than an absorbed photon, as shown in **Figure 3.3**.

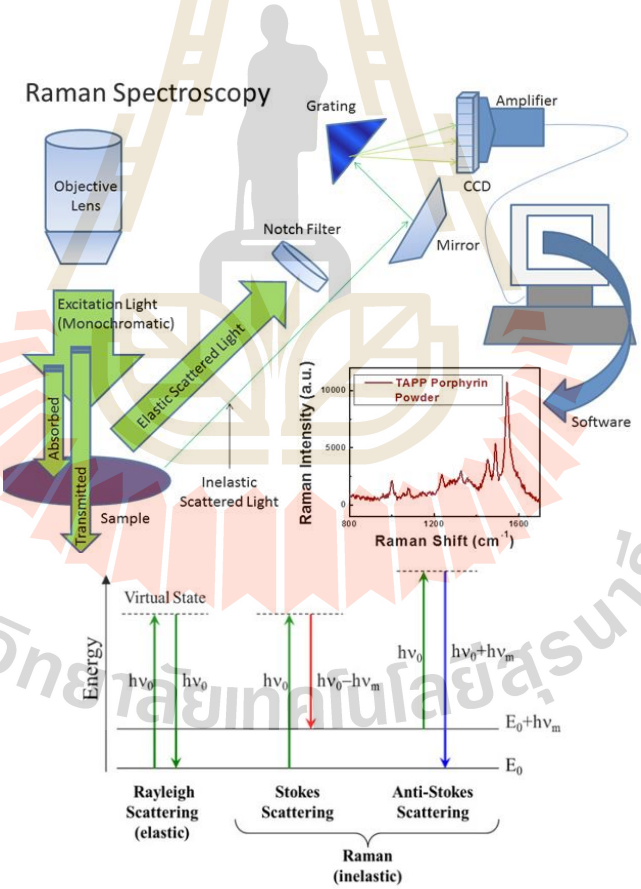


Figure 3.3 Schematic of Raman spectroscopy [Online], Available: http://bwtek.com/Raman–theory–of–Raman–scattering/; [Online], Available : https://www.nd.edu/~kamatlab/facilities_spectroscopy.html

Figure 3.4 presents the Raman spectra of HOPG, glassy carbon, and the DLC film. Raman shifts are commonly used to characterize the microstructure of amorphous carbon through key Raman parameters, such as the intensity ratio of the D and G bands (I_D/I_G), the positions of the D and G bands (expressed as Raman shifts or wavenumbers in cm^{-1}), and the full width at half maximum (FWHM) of the D and G bands. These Raman features reflect atomic and molecular vibrations, providing insights into domain size and internal stress sensitivity in amorphous thin films (Chu and Li, 2006).

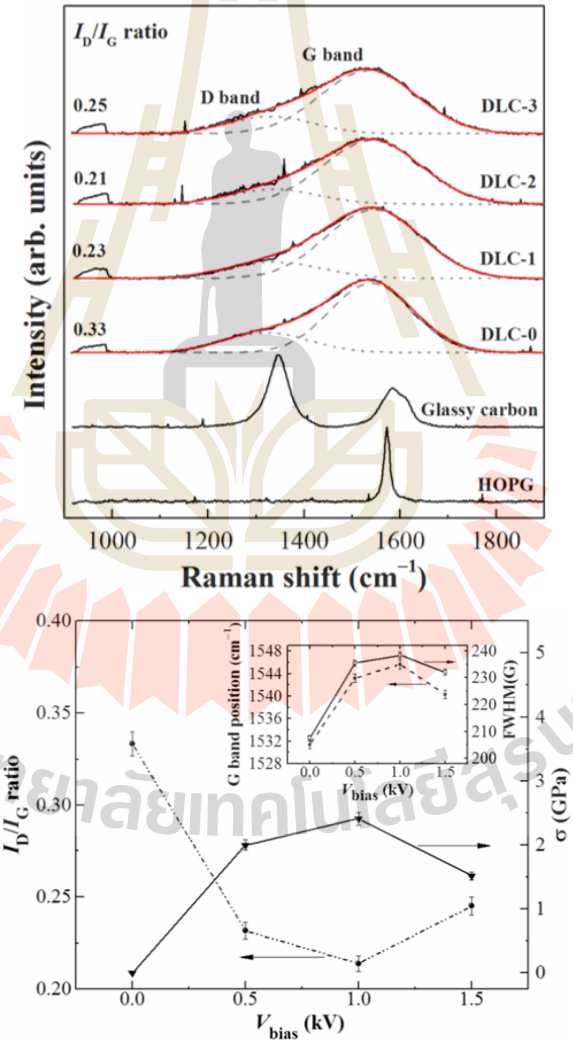


Figure 3.4 The Raman spectra of DLC films and the relationship of I_D/I_G ratio, FWHM (G) as a function of the various V_{bias} (Konkhunthot *et al.*, 2018)

A dispersive Raman microscope (SENTERRA, Bruker Optik GmbH, Ettlingen, Germany) working in backscattering mode was utilized to explore the bonding structures of the ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films. An Ar^+ laser (λ = 532 nm; power: 25 mW) was employed as the excitation source. For the scanned Raman range (800–2000 cm^{-1}), the focused–spot size and spectral resolution were 3 μm^2 and 3 cm^{-1}, respectively. OriginPro software, Version 2018 (OriginLab Corporation, Northampton, MA, USA) was used to fit the Raman spectra to three Gaussian line forms. Peaks at around 1360 and 1540 cm^{-1} showed the sites of the D (disordered) and G (graphite) bands, respectively, and the full width at half maximum (FWHM) was used to determine the D–G band intensity ratio (I_D/I_G) from the fitted Raman spectra (Bootkul *et al.*, 2014; Libassi *et al.*, 2000; Srisang *et al.*, 2012; Ferrari, 2002; Konkhunthot *et al.*, 2013).

3.2.2 X–ray photoelectron spectroscopy (XPS)

XPS is a qualitative and quantitative analysis used to study the chemical composition and chemical structure on the surface. **Figure 3.5** shows the basic principle of the XPS. Since the photon energy activates the electron in the inner shell under the surface of a material, the energy analyzer measures the kinetic energy distribution of photo–emitted electrons. Therefore, the binding energy is calculated using the law of energy conservation as shown in Equation (3.1) (Panwar *et al.*, 2008; Gunther *et al.*, 2002):

$$E_B = h\nu - E_{kin} - \phi_{analyzer} \tag{3.1}$$

Where E_B is the electron binding energy, E_{kin} is the electron kinetic energy, $h\nu$ is the photon energy, and $\phi_{analyzer}$ is the work function of the energy analyzer.

This binding energy is useful to identify elements. The results of XPS are a spectrum line; an example of the XPS spectrum is shown in **Figure 3.5**. The binding energy also varies according to the chemical state (i.e., oxidation number) and chemical structure (bonding) of the elements.

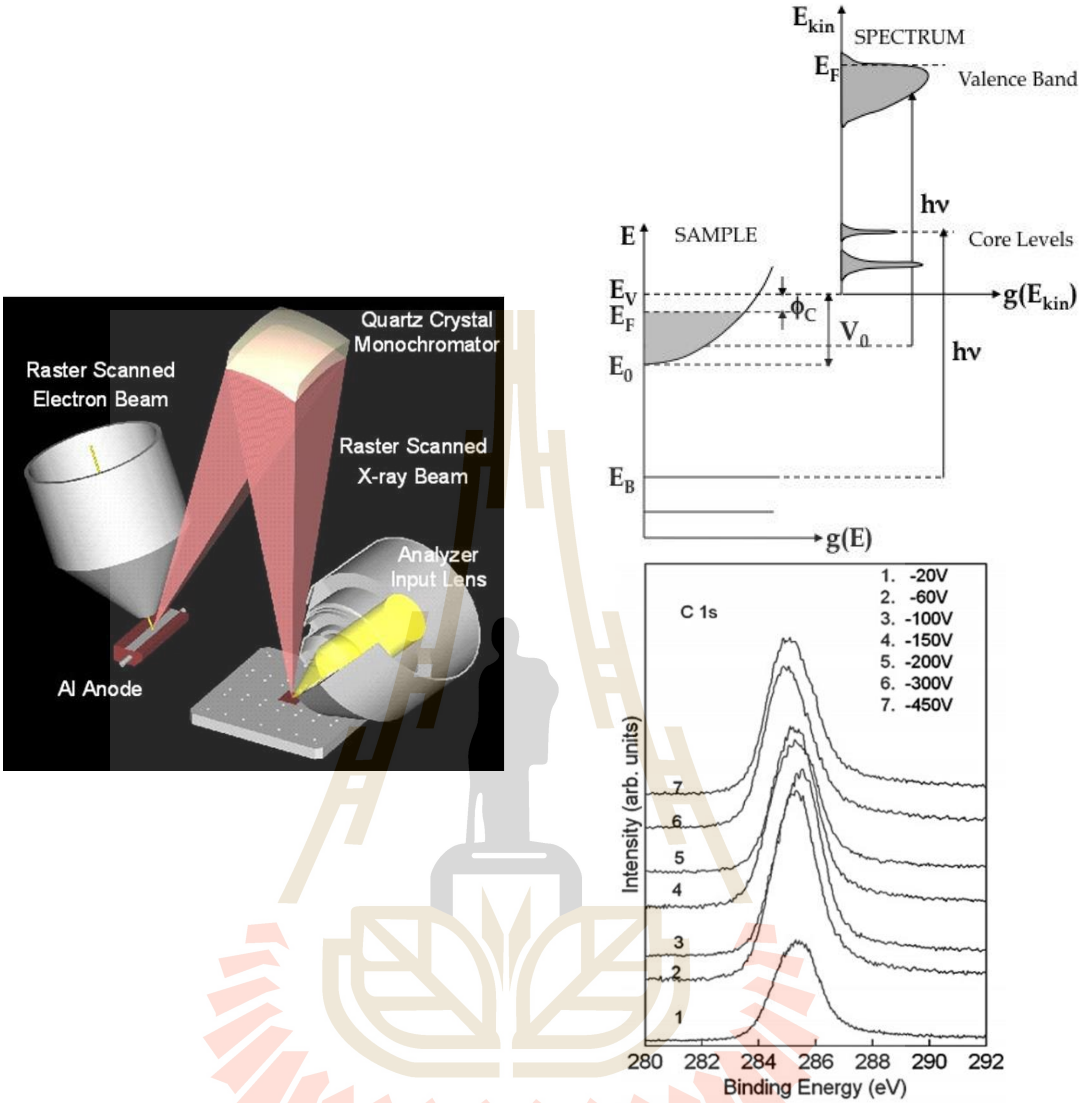


Figure 3.5 Schematic of X–ray photoelectron spectroscopy (XPS) [Online], Available : http : //www.phi.com/images/products/quantera/scanning–xray.jpg 18/13; [Online], Available : https://www.uj.ac.za/ faculties/ science/physics/ research/ Pages/Electronic–Structure–studies–at–UJ–Physics.aspx. ; and the C 1*s* XPS spectra of ta–C films at different negative substrate bias voltages (Panwar *et al.*, 2008)

In this study, the elemental composition of the DLC films was determined by XPS (PHI5000; VersaProbe^{TM}, ULVAC–PHI INC, Chigasaki, Japan) at the SUT–NANOTEC–SLRI joint research facility, beamline 5.3: SUT–NANOTEC–SLRI XPS, SLRI,

Nakhon Ratchasima, Thailand. To remove any natural oxides, the sample surfaces were sputtered with Ar^+ ions accelerated at 1000 V for 1 minute before the examination. At a 100 μm spot, the pass energy and scanning step were 46.95 and 0.1 eV, respectively. The film bonding states were quantified using XPS spectra with CasaXPS software, and elemental atomic concentrations were computed using MultiPak Spectrum ESCA software.

3.2.3 X–ray Photoemission electron microscopy (X–PEEM) and near edge X–ray absorption fine structure (NEXAFS) spectroscopy

The thermal stabilities of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N were examined sequentially in a UHV system employing in–situ high–temperature NEXAFS spectroscopy from room temperature (RT) to 700°C at 10°C for 1 min, with the films held for 20 minutes at each annealing temperature. At each stage, the films were cooled to 300°C, and the local bonding configuration was assessed using in-situ NEXAFS spectroscopy in conjunction with spectroscopic photoemission and low-energy electron microscopy (SPELEEM), (ELMITEC Elektronenmikroskopie GmbH, Clausthal-Zellerfeld, Germany) at beamline 3.2Ub: PEEM, SLRI, Nakhon Ratchasima, Thailand. The beamline's monochromatic photon energy ranged from 40 to 1040 eV, and the synchrotron radiation was applied at 17 degrees incident to the films' surfaces under UHV (3×10^{-8} Pa). NEXAFS spectra were acquired in partial-electron-yield (PEY) mode by adjusting the bias to 20 kV, corresponding to the pass energy of the hemispherical energy analyzer. As a result, the NEXAFS intensity was limited to low–energy electrons (around the photoelectron threshold). Photons in the range 270–350 eV were used to analyze the NEXAFS C *K*–edge spectra, which were scanned in 0.1 eV increments. The NEXAFS intensity (in the same photon–energy range) of a flashed–Si wafer and a highly oriented pyrolytic graphite (HOPG) as the reference material were used to standardize the absorption signals of all the DLC films. To determine the sp^2–bonding percentage of the films, the normalized C *K*–edge spectra were deconvoluted using IGOR Pro 6.3 software. Based on the change in the sp^2–bonding percentage, the thermal stability of non–doped, doped, and co–doped DLC films was examined, and correlations between thermal stability and other film parameters were found.

3.2.4 Scanning electron microscopy (FE–SEM and FIB–SEM)

The scanning electron microscope (SEM) utilizes an electron beam to image a specimen's surface. It provides information about the sample's surface and near–surface at high magnification and resolution. **Figure 3.6** shows the schematic of the SEM. The electrons are accelerated from the electron gun to the bottom of the column with a range of the potential accelerating voltage between 0 to 50 kV. The condenser lenses are used for controlling the electron beam's moving direction, while the apertures are used for controlling the emitted electrons' beam size through the column to the sample. When the electrons penetrate the surface, interactions occur, leading to the emission of electrons or photons from the surface. Emitted electrons are collected with a detector and interpreted as an image. The incident electrons or primary electrons lead to the secondary effects, classified into three types: secondary electrons (SE), backscattering electrons (BSE), and relaxation of excited atoms (REA). Nonetheless, all Scanning Electron Microscopes (SEMs) possess capabilities solely for the detection of Secondary Electrons (SE) and Backscattered Electrons (BSE). The SE is mostly used in the SEM system. When a primary electron penetrates the sample surface, it can attack an electron of an atom at the surface, leading to its emission. The BSE occurs when the primary electron goes back and leaves the surface without collision. Most of the BSEs carry higher energies than the SE. The BSE is used for surface imaging and elemental analysis. The pictures acquired from SE and BSE modes differ. The SE provides topographic information and higher resolution images while the BSE gives the contrast information (Toya *et al*., 1986; Zhang and M. Fujii, 2015; [Online], Available: https://cellularphysiology.wikispaces.com).

This study utilized FIB–SEM (AURIGA, Carl Zeiss AG, Oberkochen, Germany) at 50,000 magnification and FE–SEM at 5 kV acceleration to estimate the thicknesses of the DLC film cross sections.

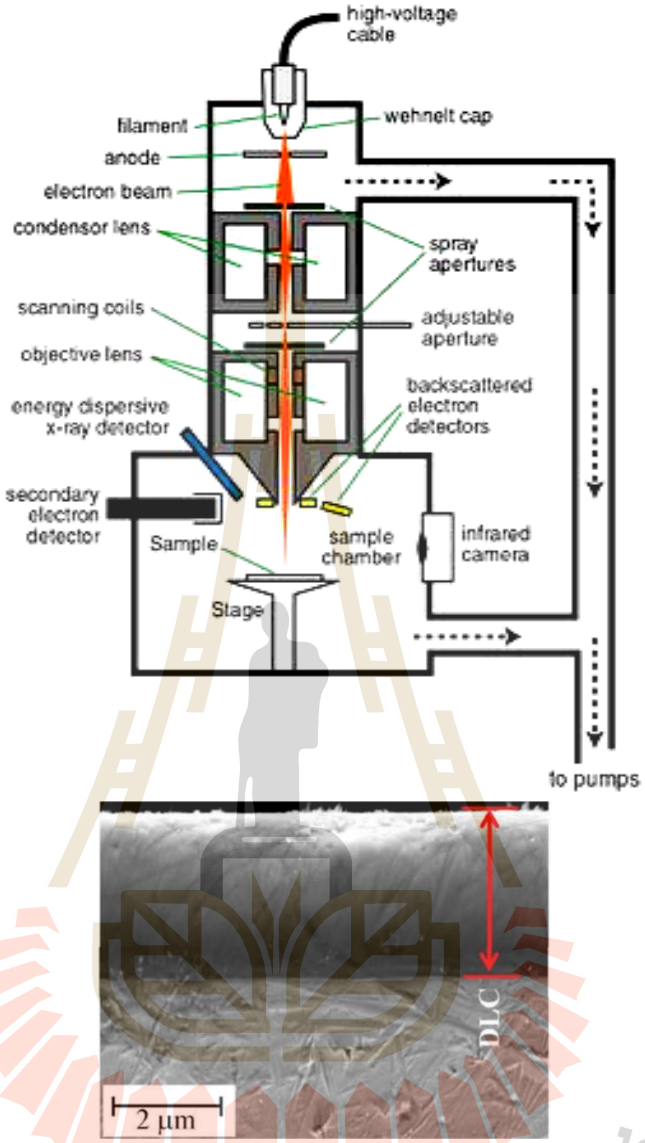


Figure 3.6 Schematic and cross–section image resulting from Scanning Electron Microscope (SEM) [Online], Available : https://cellularphysiology.wikispaces.com; (Zhang and Fujii, 2015)

3.2.5 Atomic force microscopy (AFM)

Atomic force microscopy (AFM) is a versatile technique for analyzing surface properties. It provides topographic imaging of a surface at the nanoscale and microscale. The important area is the study of force and friction force with the piconewton force resolution. The basic principle is to use a probe tip to map the

surface of the material, controlled by a piezoelectric scanner unit. The probe tip will bend along the surface as it changes, and the changes can be measured by a photodetector, resulting in images that correspond to the surface conditions in each area, as shown in **Figure 3.7** (Sharifahmadian *et al*., 2019; [Online],Available:https://pharm.virginia.edu/facilities/atomic–force–microscope–afm/; [Online], Available:http://www.parkafm.com/index.php/products/small–sample–afm/park–nx10/technical–info.

The surface roughness of the AISI 4140 substrate and all DLC layers was assessed using an atomic force microscope (AFM XE–120, Park Systems Corporation, Suwon, South Korea) in non-contact mode, covering a 5×5 μm area at a scan rate of 0.3 Hz.

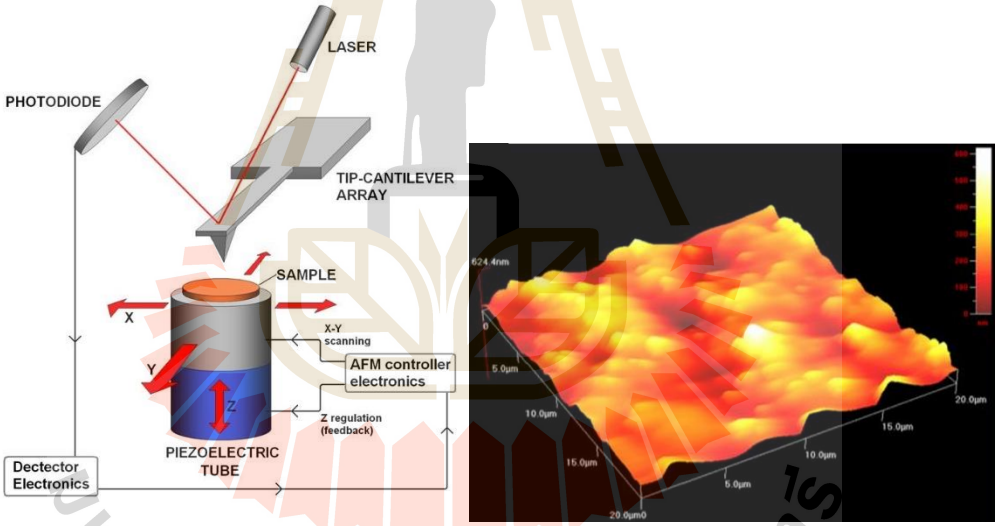


Figure 3.7 Schematic and surface image resulting from Atomic Force Microscopy (AFM) [Online], Available : https://pharm.virginia.edu/facilities/atomic–force–microscope–afm/; (Sharifahmadian *et al.*, 2019)

3.2.6 X–ray reflectometry (XRR)

To determine the density of DLC film, X–ray reflectivity (XRR) and a high–resolution X–ray diffractometer (XRD D8 ADVANCE, Bruker Optik GmbH, Ettlingen, Germany) were used with a Cu *K* radiation source at a wavelength of 1.541 Å, a voltage

of 40 kV, and a current of 40 mA (Konkhunthot *et al.*, 2018; Libassi *et al.*, 2000). The incidence angle was varied in the range of 0.0–3.0° with a scanning step of 0.005° for the XRR measurements of each DLC film. The entire reflection happened at a critical angle (θ_c), dependent on the electrical density of the material when X–rays were incident on each surface of the DLC films at grazing angles of incidence. The square of the modulus of the Fourier transform of the electron density is proportional to the reflection intensity of each DLC film; hence, the profile of the electron density can be calculated from the observed intensity pattern (Konkhunthot *et al.*, 2018; Libassi *et al.*, 2000). According to Parratt's idea (Parratt, 1954), the XRR profiles were simulated using the Leptos 7.1 program. The θ_c and interference fringe give the average electron density from XRR data (reflectivity profiles); hence, Equation (3.2) may be used to measure the thickness of the DLC films at a low angle (Konkhunthot *et al.*, 2018; Ferrari *et al.*, 2000; Kishimoto *et al.*, 2008).

$$\rho = \left[\frac{\pi\theta_c^2}{N_A r_e \lambda^2}\right]\left[\frac{X_C(M_C - M_H) + M_H}{X_C(Z_C - Z_H) + Z_H}\right] \quad (3.2)$$

Where θ_c and r_e are the critical angles and the classical electron radius, respectively, N_A is Avogadro's number, λ is the experiment's applied wavelength, X_C and X_H represent the relative atomic fractions of carbon and hydrogen, respectively, (where X_H is expressed as $1–X_C$), Z_C and Z_H denote the atomic numbers of carbon and hydrogen, respectively, and M_C and M_H are the molar of carbon and hydrogen element, respectively.

3.3 Nanomechanical and Adhesion strength performance analysis

3.3.1 Nanoindentation tests

The ASTM Standard (E2546–07, 2007) was followed to analyze the hardness and elastic moduli of the DLC films using nanoindentation testing with a NanoTest Vantage (Micro Materials Limited, Wrexham, UK), equipped with a Berkovich indenter under maximum stress. Nanoindentation is a technique for mechanically characterizing amorphous carbon thin films, utilizing a pendulum-based approach to

measure depth-sensing. Each specimen was measured 10 times, and the six-point average value was selected to ensure statistical reliability. To minimize the substrate effect, measurements were performed using a Berkovich indenter, with the maximum penetration depth of the films in the range of 10–15% of the films' thickness (Konkhunthot *et al*., 2019). Additionally, the maximum penetration depth for each film adhered to the ASTM Standard (E2546–07, 2007). As a result, the nanomechanical properties in this study were consistent with international standards, despite variations in film thickness. Loading and unloading curves were recorded with a dwell time of 10 seconds at a rate of 0.1 mN s^{-1}.

3.3.2 Nanoscratch tests

Adhesion testing was conducted while the platform was in motion, with friction and acoustic emissions measured throughout the scratch test. The nanoscratch tests were performed at a relative humidity of approximately 50% and a temperature of 27 ± 0.5°C. A conical diamond tip (90° angle, with a final radius of 5 µm) was used to perform three consecutive scratches on each DLC film. A pre-scratching method was employed to minimize the influence of surface roughness, topography, slope, and instrument bending (Beake *et al*., 2006; Hassan *et al*., 2015). The scratch process involved three sequential scans at 12.30 µm s^{-1} over a 5000 µm scan length: (i) a preliminary topography scan at a constant load of 0.50 mN, (ii) a scratch scan conducted with an applied load of 1.0 mN s^{-1}, increasing to a maximum load of 400 mN after 10 µm, and (iii) a concluding topography scan at 0.50 mN with a constant load over the scratched region. Additionally, a very low speed was maintained to minimize heat effects, which could cause degradation of the DLC film during testing.

Finally, an SEM microscope and digital capture system were used to observe the scratch tracks, which were then evaluated and integrated with the nanoscratch test results.

3.4 Electrochemical corrosion analysis

3.4.1 Potentiodynamic polarization technique

The tests were carried out at 27 ± 0.5°C in a 3.5 wt% NaCl solution (pH ~6.6) using an Autolab PGSTAT 128N (Metrohm AG, Herisau, Switzerland) equipped

with a graphite counter electrode (CE), an Ag/AgCl (3M, KCl) reference electrode (RE), and AISI 4140 steel with non–doped and co–doped DLC coatings as the working electrodes (WE) (Konkhunthot *et al.*, 2019). The samples were immersed in the solution for 20 minutes before beginning the corrosion tests at a scan rate of 1 mV s^{-1} (Wongpanya, Pintitraratibodee, Thumanu, & Euaruksakul, 2021; Wachesk *et al.*, 2016) to maintain the steady–state or open–circuit potential (OCP). A fixed exposure area of 0.19625 cm^2 was also used in the scan, which ranged from –150 mV below the OCP (the cathodic region) to +300 mV above the OCP (the anodic region) (Konkhunthot *et al.*, 2019).

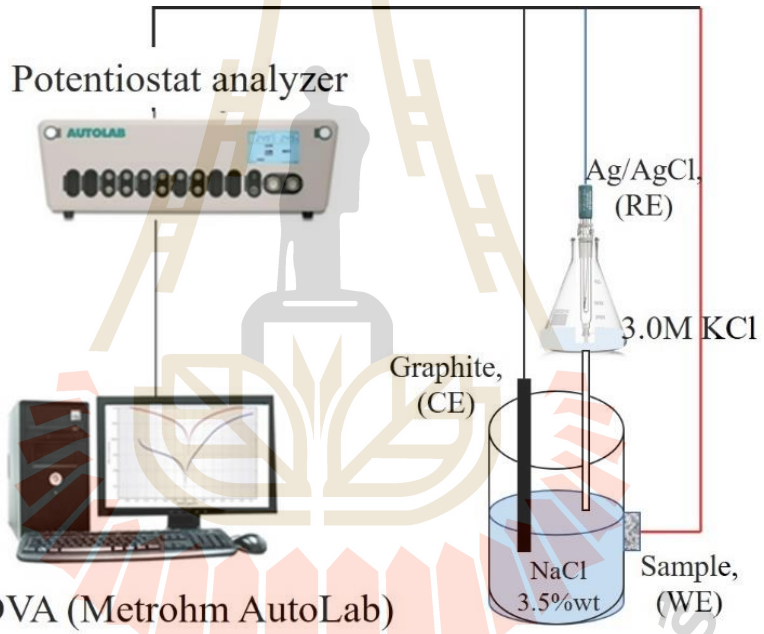


Figure 3.8 The schematic of a potentiostat analyzer by Autolab PGSTAT 128N (Metrohm AG®, Switzerland)

CHAPTER 4

RESULTS AND DISCUSSION

4.1 The structural bonding configuration, thickness, and morphology of non–doped N–doped, Al–doped, and Al–N co–doped films synthesis by FCVA

4.1.1 Raman analysis

Raman spectroscopy is a widely used non-destructive technique, commonly employed to investigate the bonding structure of amorphous carbon films or DLC. It provides data in the form of D and G peaks, full width at half maximum (FWHM), I_D/I_G ratios, L_a, and compressive stress (**σ**) (Ferrari, 2002; Hauert *et al.*, 1995).

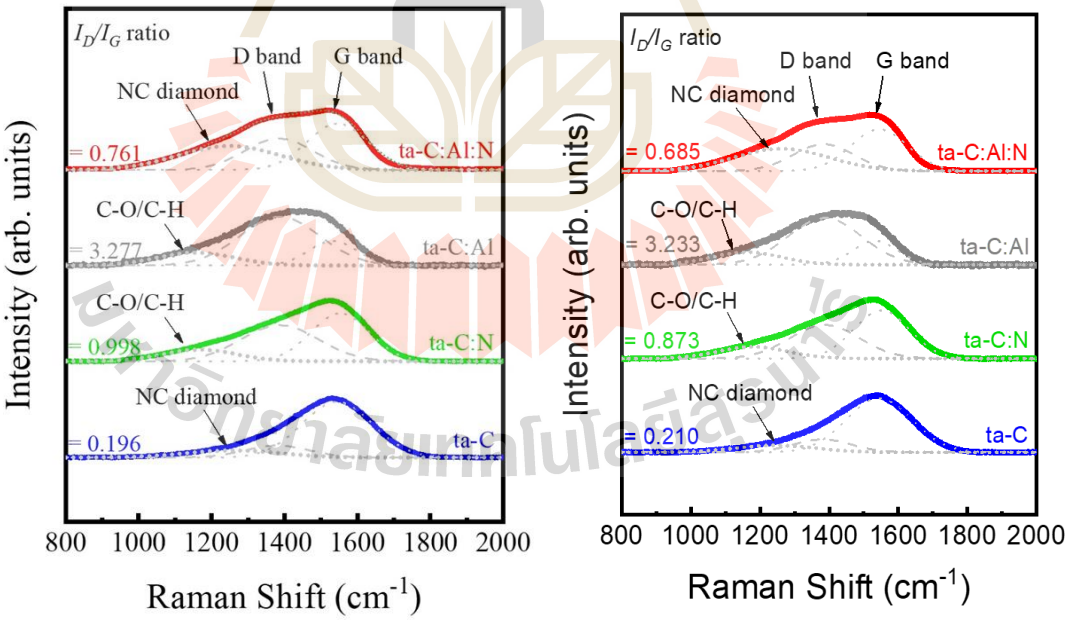


Figure. 4.1 Raman spectra of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N ((a) Set sample I and (b) Set sample II) (modified from Wongpanya, Silawong, & Photongkam, 2021; Wongpanya *et al.*, 2022)

Table 4.1 The Raman analysis parameters: D and G peaks, FWHM (D), FWHM (G), I_D/I_G ratios with L_a, and of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N (set I) and (set II) (modified from Wongpanya, Silawong, & Photongkam, 2021; Wongpanya *et al*., 2022)

Sample	Raman analysis						
	G Peak (cm^{-1})	D Peak (cm^{-1})	FWHM of G peak (cm^{-1})	FWHM of D peak (cm^{-1})	I_D/I_G ratio	L_a (nm)	**σ** (GPa)
ta–C_(I)	1544.54	1379.77	226.91	205.44	0.196	5.965	0.000
ta–C:N_(I)	1552.49	1386.85	189.17	250.05	0.998	13.469	1.339
ta–C:Al_(I)	1532.33	1387.15	156.16	257.53	3.277	24.409	–2.056
ta–C:Al:N_(I)	1545.14	1384.34	195.66	219.15	0.761	11.765	0.102
ta–C_(II)	1544.18	1379.58	223.94	196.61	0.210	6.185	0.000
ta–C:N_(II)	1551.26	1389.18	189.52	236.43	0.873	12.601	1.193
ta–C:Al_(II)	1532.97	1387.53	151.65	249.93	3.233	24.246	–1.886
ta–C:Al:N_(II)	1544.93	1383.84	193.93	205.09	0.685	11.159	0.127

The findings of the Raman measurements are shown as spectra in **Figure 4.1** (a) and (b), and all the DLC films were Raman measured in the 800–2000 cm^{-1} range of the wavenumber in this investigation. The Raman spectra on the main Gaussian curve were split in half; the D peak, with a wavelength of 1360 cm^{-1}, corresponds to the disordered structure of six aromatic rings, also known as the aromatic rings' breathing or vibrational mode, and the G peak, which corresponds to vibrations in the carbon chain and aromatic rings, is at a wavelength of 1540 cm^{-1}. The other wavenumber is a band centered between 1140 and 1260 cm^{-1}, which involves sp^2 and sp^3 bonds in a trans-polyacetylene (trans–PA) DLC film, and is related to an atom of trans–PA DLC (Nakazawa *et al.*, 2007; Piazza *et al.*, 2003). Hydrogen is bonded to an sp^2-site carbon atom in the chain. A nanocrystalline (NC) diamond structure is also indicated by the peak at 1260 cm^{-1} (Singha *et al*., 2006), which might reflect the

amount of mixed carbon sp^3-hybridized and hydrogen in the DLC film (Piazza *et al.*, 2003; Pu *et al.*, 2015; Liu *et al.*, 2005; Rao *et al.*, 2020). The major findings from the Raman analysis are presented in **Table 4.1**. All the DLC films display data for the D and G peaks, the FWHM of the D and G peaks, I_D/I_G ratios with L_a, and **σ**. Notably, the G peaks of the ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films from both sample sets (set I and II) were found at 1544.50–1544.18, 1552.49–1551.26, 1532.33–1532.97, and 1554.49–1551.26 cm^{-1}, respectively. A higher wavenumber shift is observed for the transition of the G peaks in the ta–C:N and ta–C:Al:N film layers, whereas the ta–C:Al films show a shift of the G peak to a lower wavenumber compared to the G peak position of the ta–C film. In previous research (Liu *et al.*, 2005; Rao *et al.*, 2020), G–peak shifting has been linked to changes in L_a in DLC films. Important Raman parameters such as the G and D peaks, I_D/I_G, and the FWHM of the G peak are calculated from the area under the Gaussian curves of the G and D peaks, while L_a and **σ** are estimated using Equations (4.1) and (4.2) below (Konkhunthot *et al.*, 2018; Zarei Moghadam *et al.*, 2019; Tunmee *et al.*, 2016; Ferrari and Robertson, 2001; Lifshitz *et al.*,1989):

$$\frac{I_{\mathrm{D}}}{I_{\mathrm{G}}} = C(\lambda)L_{\mathrm{a}}^2 \tag{4.1}$$

where $C'(514\ \mathrm{nm}) \approx 0.0055$.

$$\sigma = 2G\left[\frac{1+\upsilon}{1-\upsilon}\right]\left[\frac{\Delta\omega}{\omega_0}\right] \tag{4.2}$$

Where G is the shear modulus (70 GPa), υ = 0.3 is the Poisson's ratio, $\Delta\omega$ is the change in the G-peak Raman wavenumber, and ω_0 is the Raman wavenumber of the stress-free DLC sample used as a reference material.

The I_D/I_G ratio may be considerably increased by doping with N, Al, or Al–N. The doping also resulted in a significant decrease in the FWHM (G). Because L_a, estimated using Equation (4.1), was similar to values reported in earlier research (Konkhunthot *et al.*, 2018; Ferrari, 2002; Tunmee *et al.*, 2016), the decrease in the G

peak corresponded to larger graphite clusters at sp^2–hybridized carbon sites. According to the Raman analysis, the addition of N, Al, or Al–N into the DLC film resulted in a shift toward an sp^2–hybridized carbon structure and increased carbon content, while the pure DLC film contained more sp^3–hybridized carbon.

Internal stresses in materials may also be quantified using Raman analysis methods, as the vibrational frequency of atoms is directly related to stress. Furthermore, Raman spectroscopy produces several waves proportional to the frequency of oscillations, which is indicated by the shift in the wavenumber position. Therefore, the Raman spectroscopy technique can be employed to measure the internal compressive stress (σ) in DLC films (Miki *et al.*, 2015; Narayan *et al.*, 2005; Lubwama *et al.*, 2013). Consequently, the inter-atomic force constant, linked to inter-atomic spacing and influencing atomic vibrational frequency, undergoes a shift. For instance, as the tensile load on the DLC film increases, the bond length also increases, leading to a reduction in both the vibrational frequency and the force constant. In contrast, when the material is subjected to compressive stress, the force acts in the opposite direction, decreasing the bond length (Miki *et al.*, 2015; Narayan *et al.*, 2005; Lubwama *et al.*, 2013). The Raman spectra distinctly show that merely incorporating N or Al–N into the DLC film causes the G peak to shift to a higher wavenumber. The G peak in the Al–doped material has moved to a lower wavenumber at 1532.33–1532.97 cm^{-1}, while the G peak in ta–C:N and ta–C:Al:N appears in the ranges of 1552.49–1551.26 cm^{-1} and 1545.14–1544.93 cm^{-1}, respectively. The computed values of σ for the ta–C:N, ta–C:Al, and ta–C:Al:N films in set I were 1.339, –2.056, and 0.102 GPa, respectively, while the corresponding values in set II were 1.193, –1.886, and 0.127 GPa.

Residual stress forms and accumulates within the DLC coating during the film growth process. High residual stress is often associated with films of high hardness and is a primary cause of delamination and distortion of the film on flexible surfaces. This is because significant residual stress can lead to deformation of the film (Xu *et al.*, 2012, 2013). Furthermore, as the thickness of a DLC film increases, the residual stress within the film also tends to increase. The film stabilizes at a certain thickness before the residual stress reaches its maximum value, beyond which cracking

may occur (Sheeja *et al*., 2002). To prevent film delamination, it is essential to control the residual stress. One method of reducing residual stress in DLC films involves the incorporation of specific elements into the film or the introduction of a buffer layer between the substrate and the film (Xu *et al*., 2013). In this study, the addition of alloying elements such as nitrogen, aluminium, and co-doping resulted in residual stress values determined using Equation (4.2). Two of the ta–C:N, ta–C:Al, and ta–C:Al:N specimens exhibited similar internal stress (σ) and L_a values.

The similarity was demonstrated by the G peak and the computed σ value, which were based on the difference between the higher and lower wavenumbers, corresponding to the increasing and decreasing compressive stress in the DLC films (Miki *et al.*, 2015; Narayan *et al.*, 2005; Lubwama *et al.*, 2013). The structural bonding was strengthened by increasing the compressive stress (σ) in the ta–C:N and ta–C:Al:N films. In contrast, the compressive stress in ta–C:Al was lower, which played a key role in the transition of carbon bonds from sp^3 to sp^2. This transition was less pronounced in ta–C:Al, where the conversion from sp^3 to sp^2–hybridized carbon was particularly minimal (Xu *et al.*, 2018; Narayan *et al.*, 2005). The increased graphite content within the disordered sp^2–hybridized carbon in the DLC structure, combined with the low Al/Al_2O_3 content in the ta–C:Al film, likely contributed to the G peak of the ta–C:Al film shifting towards a lower wavenumber. Additionally, the face-centered cubic (FCC) crystal structure of Al prevents carbide formation in the DLC layer, facilitating the development of nanocrystals within the DLC matrix (Chen *et al.*, 2005).

4.1.2 Structural and chemical state of DLC film

XPS analysis was used to quantify the elemental composition, the chemical bond type, the sp^3/sp^2 ratio, and the relative fraction of sp^3 of all the DLC films. It was evident that the elemental–doped DLC film layer exhibited a reduced C atom concentration, which decreased from 90.01–90.65 at.% for ta–C to 79.23–79.57 at.%, 78.20–78.23 at.%, and 58.83–58.76 at.% for ta–C:N, ta–C:Al, and ta–C:Al:N, respectively, as indicated in **Table 4.2**, along with the sp^3 C–C content of the DLC film, as shown in **Figure 4.2**. The N content was approximately 11.21–11.46 at.% and 14.12–13.99 at.% in ta–C:N and ta–C:Al:N, respectively, while the Al content was approximately 4.77–5.05 at.% and 7.18–7.59 at.% in ta–C:Al and ta–C:Al:N, respectively.

The O content increases with the increasing Al content, possibly because O has adsorbed or adhered to the Al on the film's surface, forming an oxide layer upon exposure to air (Zhou *et al.*, 2019). The chemical composition presented in **Table 4.2** indicates that the number of compounds in each film is quite comparable. This results in both sets of films exhibiting similar structural and mechanical properties, thermal stability, corrosion resistance, and other characteristics associated with films of comparable composition.

Table 4.2 The ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N elemental compositions (at.%) quantitively measured using XPS (modified from Wongpanya, Silawong, & Photongkam, 2021; Wongpanya *et al.*, 2022)

Sample	Atomic Concentration* (at.%)			
	C 1*s*	N 1*s*	O 1*s*	Al 2*p*
ta–C_(I)	90.01	–	9.99	–
ta–C:N_(I)	79.23	11.21	9.56	–
ta–C:Al_(I)	78.20	–	17.03	4.77
ta–C:Al:N_(I)	58.83	14.12	19.87	7.18
ta–C_(II)	90.65	–	9.35	–
ta–C:N_(II)	79.57	11.46	8.97	–
ta–C:Al_(II)	78.23	–	16.72	5.05
ta–C:Al:N_(II)	58.76	13.99	19.67	7.59

*Atomic concentration was calculated using MultiPak Spectrum ESCA software

The chemical compositions and bonding states of the undoped, doped, and co-doped DLC films were examined using XPS, with the C 1*s*, N 1*s*, and Al 2*p* peaks identified across the spectra, as shown in **Figures 4.2–4.4**. As illustrated in **Figure 4.2**, the XPS spectra of C 1s were deconvoluted into distinct Gaussian-Lorentzian peaks, using Shirley backgrounds, to quantify the fraction of sp^3 C–C bonds in the DLC films (Modabberasl *et al.*, 2015; Yan *et al.*, 2004).

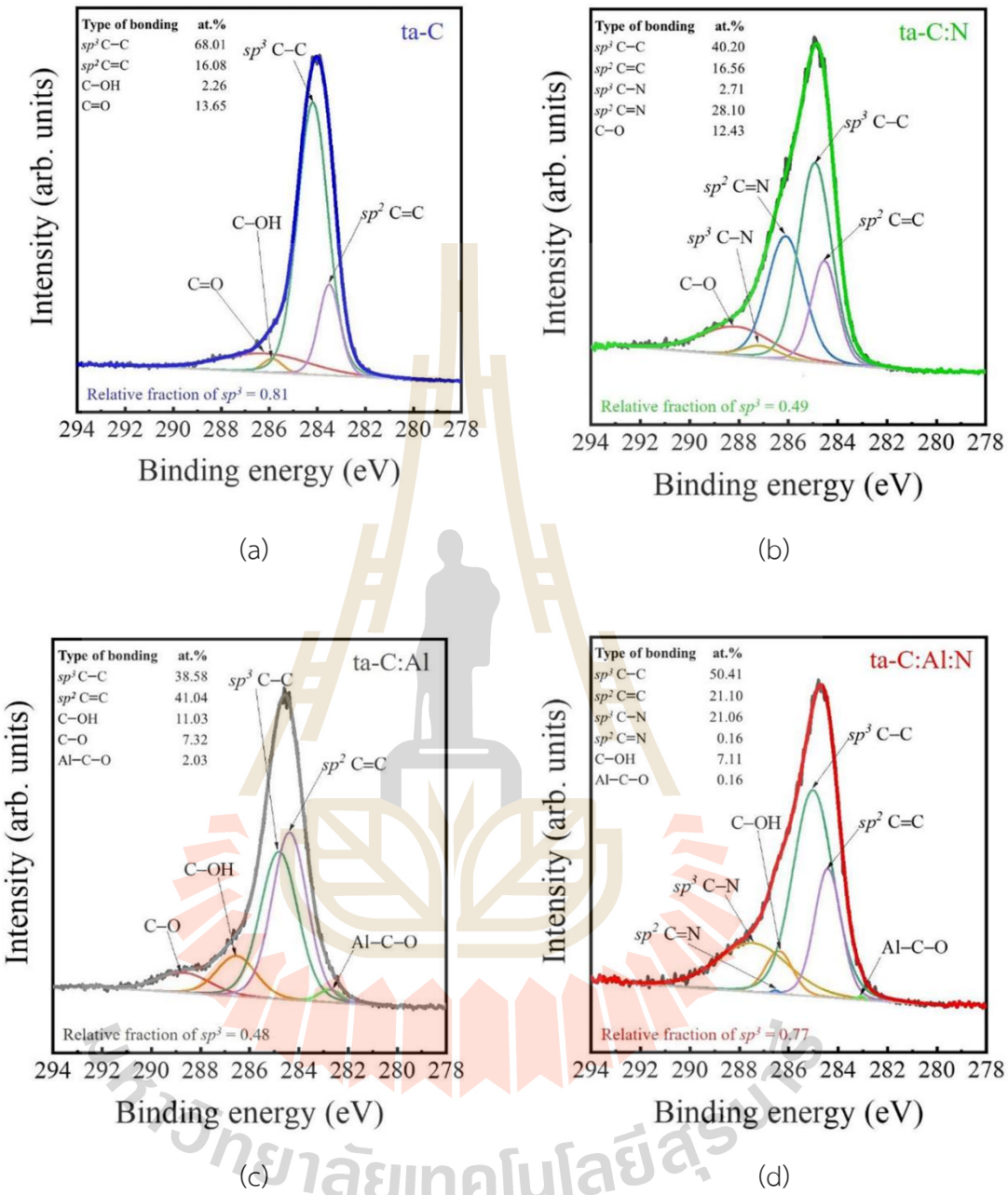


Figure 4.2 The C 1*s* XPS spectra and corresponding deconvoluted Gaussian peaks of (a) ta–C, (b) ta–C:N, (c) ta–C:Al, and (d) ta–C:Al:N. (Wongpanya, Silawong, & Photongkam, 2021)

Figure 4.2 illustrates the obtained peaks for the C 1*s* spectra deconvoluted for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N, relating to the C–C bonds at 283.5 and 284.19 eV. The C=C bond exhibits sp^2 hybridization, and the C–C bond shows

sp^3 hybridization, whereas the additional peak in the 286–288 eV binding energy range relates to the C–OH, C–O, or C=O bonds, revealing the bond structure of the films, which includes hydrogen atoms and oxygen impurities from the surroundings (Wu *et al*., 2007; Konkhunthot *et al*., 2018; Mabuchi *et al*., 2013; Zarei Moghadam *et al*., 2019; Tunmee *et al*., 2016; Honglertkongsakul *et al*., 2010; Maruno *et al*., 2018).

Because the double bond is somewhat shorter than the single bond, the divided C 1*s* peak produced for the (sp^3 C–C) and (sp^2 C=C) bonds shifts significantly. In the C=C sp^2–hybridized bond, the charge density surrounding the C atom shifts closer to the carbon nucleus, and the valence electrons compress. In the deconvoluted spectra for ta–C:N, ta–C:Al, and ta–C:Al:N, the binding energy of the C 1*s* axis level (Wu et al., 2007) decreases. The sp^2 C=C bonds (at 284.54, 284.38, and 284.42 eV for ta–C:N, ta–C:Al, and ta–C:Al:N, respectively) and sp^3 C–C bonds (at 284.92, 284.80, and 285.02 eV for ta–C:N, ta–C:Al, and ta–C:Al:N, respectively) were converted to higher binding energies than those found in practically all other work (Wu *et al.*, 2007; Zhou *et al.*, 2019; Bouabibsa *et al.*, 2018).

Due to the DLC film being doped with Al or N, the percentage of the bond (sp^3 C–C) in the DLC film fell substantially from 68.01 at.% for ta–C to 40.20 and 38.58 at.% for ta–C:N and ta–C:Al, respectively. In contrast, the co-doping of Al and N led to a slight decrease in the percentage of the bond (sp^3 C–C) in comparison to the films doped individually, decreasing from 68.01 to 50.41 at.% for *ta*-C and *ta*-C:Al:N, respectively. These data indicate that as the alloy content increases, the relative fraction of the (sp^3 C–C) bond decreases. Moreover, the reduction in the relative proportion of sp^3 C–C bonds in the ta–C:N, ta–C:Al, and ta–C:Al:N films is linked to a decline in hardness (H) in the doped DLC films. It can be noted that the deconvoluted peaks in the C 1*s* spectra of ta–C:N and ta–C:Al:N, within the ranges of 285.50–286.54 eV and 285.20–287.45 eV, relate to sp^2–hybridized C=N and sp^3–hybridized C–N, respectively. The spectra lack peaks around 286.70 eV, the characteristic energy for the *sp*-hybridized C≡N bond (nitrile group) (Hauert *et al.*, 1995; Mabuchi *et al.*, 2013; Yan *et al.*, 2004; Shi, 2006). Introducing nitrogen during the DLC coating process leads to the formation of various bonds. Notably, an amorphous structure arises from neighboring carbon atoms, pyridine (sp^2-hybridized C=N bond), urotropine

(sp^3-hybridized C–N bond), and nitrile groups. Consequently, the $sp^3/(sp^2 + sp^3)$ ratio for ta–C decreases to 0.49, 0.48, and 0.77 for ta–C:N, ta–C:Al, and ta–C:Al:N, respectively, as illustrated in **Figure 4.2**. Analysis of the C 1*s* spectra revealed that increasing the concentrations of N and Al resulted in a reduction of sp^3-hybridized C atoms, correlating with lower hardness (H) values. Furthermore, the decreased relative amounts of sp^3-bonded C and N atoms are associated with larger sp^2-bonded (L_a) clusters and elevated I_D/I_G ratios, as evidenced by the Raman findings (Ferrari and Robertson, 2000).

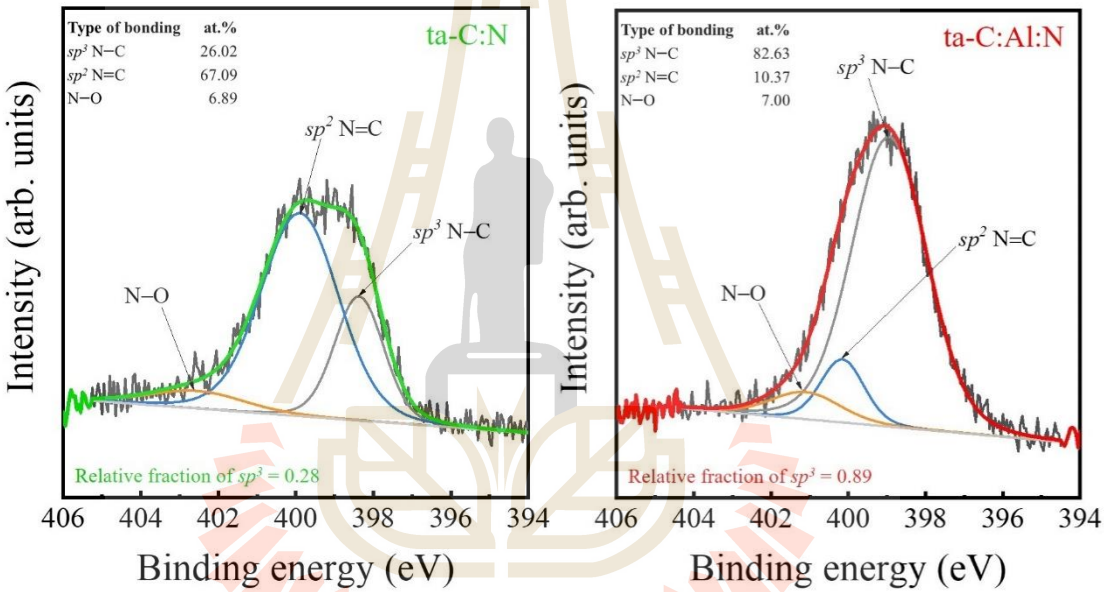


Figure 4.3 The N 1*s* XPS spectra and corresponding deconvoluted Gaussian peaks of (a) ta–C:N, and (b) ta–C:Al:N (Wongpanya, Silawong, & Photongkam, 2021)

Figure 4.3 emphasizes the three main peaks for sp^3–hybridized C–N bonds, sp^2–hybridized C=N bonds, and N–O bonds. The separated N 1*s* spectra for ta–C:N and ta–C:Al:N shown here match the literature (Zhou *et al.*, 2019; Mabuchi *et al.*, 2013; Yan *et al.*, 2004). Urotropine, which has sp^3 C–N bonds, shows C 1*s* and N 1*s* peaks at 286.9 eV and 399.9 eV, respectively. By contrast, pyridine with sp^2 C=N bonds

shows C 1*s* and N 1*s* at 285.5 eV and 400.6 eV, respectively (Yan *et al.*, 2004). Most nitrogen atoms in both ta–C:N and ta–C:Al:N are linked to either carbon atoms with sp^2 hybridization, which form C=N bonds, or carbon atoms with sp^3 hybridization, which form C–N bonds. **Figure 4.3** shows how the ratio of sp^3 C–N bonded atoms changes, increasing from 0.28 to 0.89, based on the formula (sp^3 C–N/(sp^3 C–N + sp^2 C=N)). Having more sp^2–hybridized C=N bonds in the DLC films, particularly in ta–C:N, reduces the amount of sp^3 C–N bonds (Mabuchi *et al.*, 2013). This reduction is ascribed to the fact that nitrogen lowers the number of suspended bonds in the aromatic ring. The Al–O–C bond looks weak in the C 1*s* spectra of both ta–C:Al and ta–C:Al:N at 282.2 eV, probably due to contamination and contact with oxygen in the air.

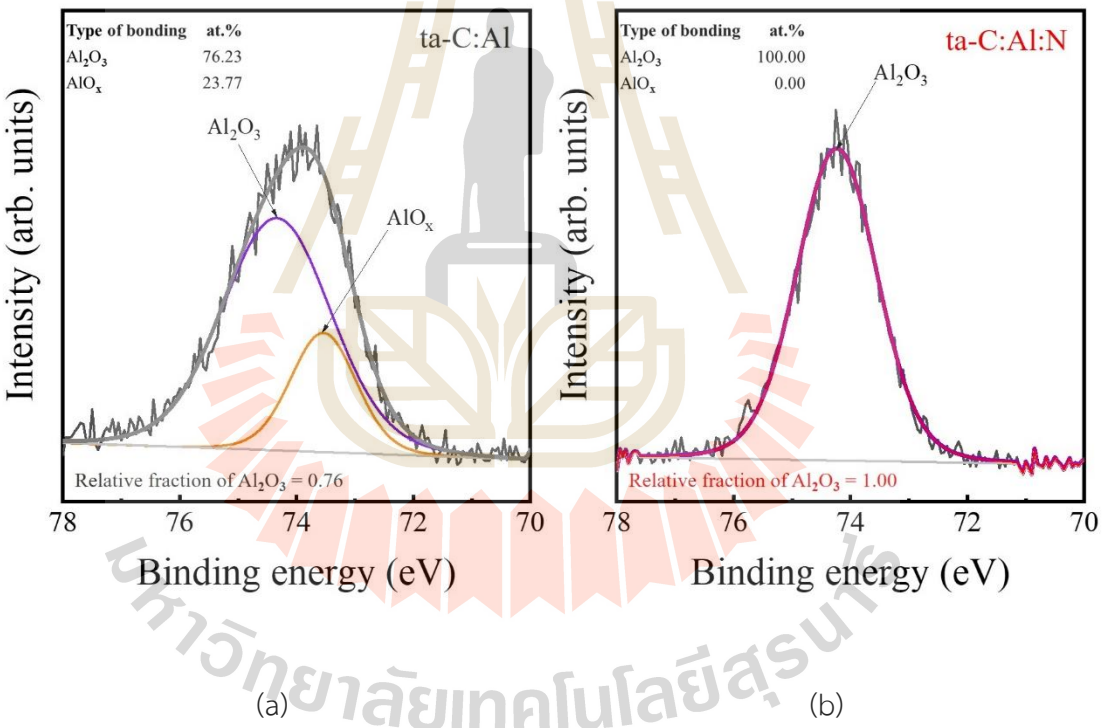


Figure 4.4 The Al 2*p* XPS spectra and corresponding deconvoluted Gaussian peaks of (a) ta–C:Al, and (b) ta–C:Al:N (Wongpanya, Silawong, & Photongkam, 2021)

Figure 4.4 shows the peaks in the Al 2*p* deconvoluted spectra of ta–C:Al and ta–C:Al:N. AlO_x and Al_2O_3 have peaks at 73.54 and 74.24 eV, respectively. While the spectra for ta–C:Al:N contains just one peak of 74.24 eV, the relative percentages for Al_2O_3: $Al_2O_3/(Al_2O_3+AlO_x)$ for ta–C:Al and *ta* C:Al:N are 0.76 and 1.00, respectively, as shown in **Figure 4.4**. Aluminium oxide (Al_2O_3) (Edlmayr *et al.*, 2010), the most stable aluminium oxide, is present in ta–C:Al:N, whereas aluminium suboxide (AlO_x) coexists with Al_2O_3 in ta–C:Al:N (Zhou *et al.*, 2019; Dai and Wang, 2011; Ozensoy *et al.*, 2005). Al_2O_3 possesses outstanding qualities, including wear resistance (Dingemans *et al.*, 2010; Eklund *et al.*, 2009), thermal stability, and corrosion resistance; the doped DLC with Al only, on the other hand, reduces compressive stress (**σ**) and hardness (H), both of which are key qualities for tribological applications such as adhesion and wear resistance. This is owing to far fewer sp^3 C–C bonds, as previously observed (Bootkul *et al.*, 2014).

In this experiment, the aluminium concentration in the DLC films ranged from 4.77 to 5.05 at.%. This results in a deterioration of mechanical characteristics and hardness. The interaction between Al and N in ta–C:Al:N preserves the **σ** and H necessary for adhesion and wear resistance. This is mostly attributable to the predominance of sp^3 C–N bonds formed by the bulk of nitrogen atoms. This pertains to Al_2O_3 in ta–C:Al:N, except ta–C:Al, which is unbonded (sp^3 C–N), nevertheless has a mixture of AlO_x and Al_2O_3.

4.1.3 Local bonding configuration

The local bonding structures and sp^2 proportion of all the DLC films were evaluated using NEXAFS spectroscopy, as illustrated in **Figures 4.5 – 4.7**. The normalized C *K*–edge NEXAFS spectra generated for all the films are shown in **Figure 4.5**, with two energy edges at 285.4 eV corresponding to the transitions from C 1*s* to the unoccupied **π*** and **σ*** states of the sp^2–hybridized C=C site and the *sp*–hybridized C≡C site, if present, and 288–335 eV corresponding to the overlapping C 1*s* transitions to the unoccupied **π*** transitions at 285.1, 285.9, 286.3, 287.6, 287.7, 288.5, 289.6, and 293.7 eV, which corresponded to transitions of the following states: **π*** (C=C), **π*** (C=N), **π*** (C=OH), **σ*** (C–H), **σ*** (C–N), **π*** (C=O) or **π*** (C≡C), **σ*** (C–C), and **σ*** (C=C),

respectively. As shown in **Figure 4.5**, for the ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N, the sp^2 fraction was 0.345, 0.394, 0.538, and 0.348, respectively. Single dopants like N-doped or Al-doped DLC films increased graphitization, shown by a rise in the sp^2 fraction, but Al-N co-doping only slightly improved graphitization, and these results were consistent with the XPS findings.

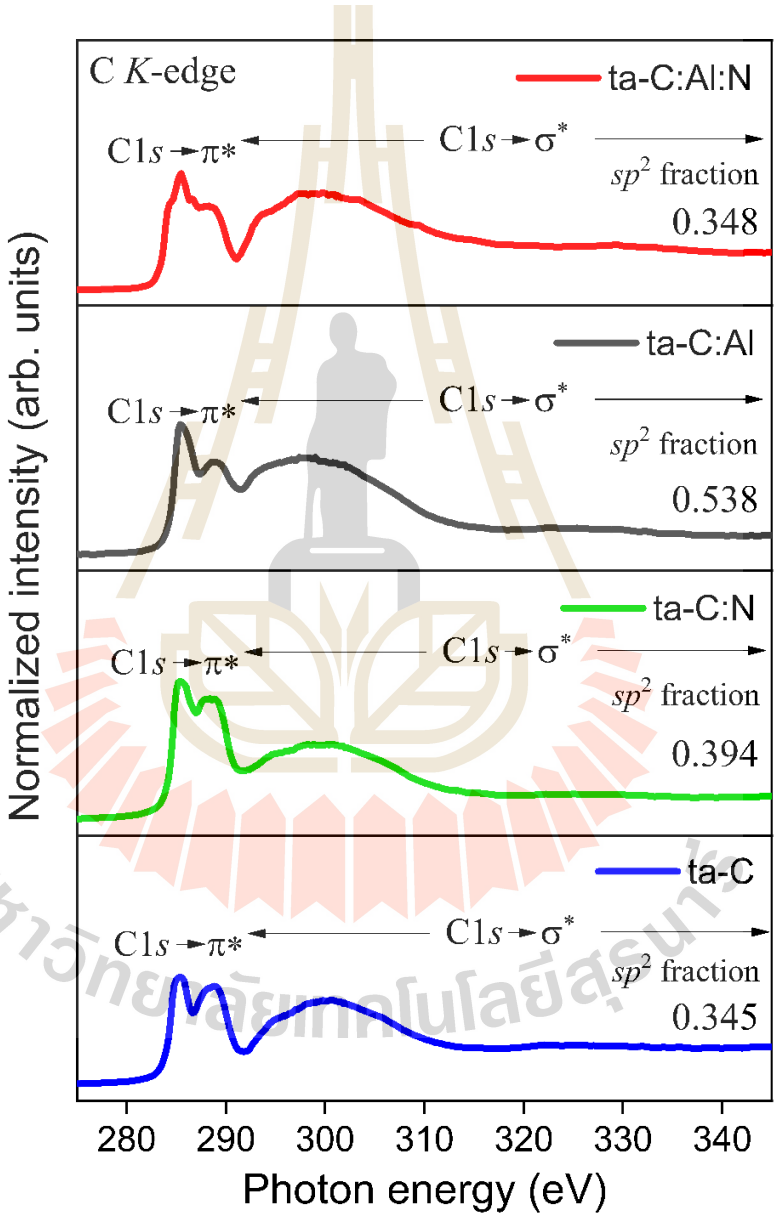


Figure 4.5 The C *K*–edge NEXAFS spectra generated for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N before the corrosion tests (Wongpanya *et al.*, 2022)

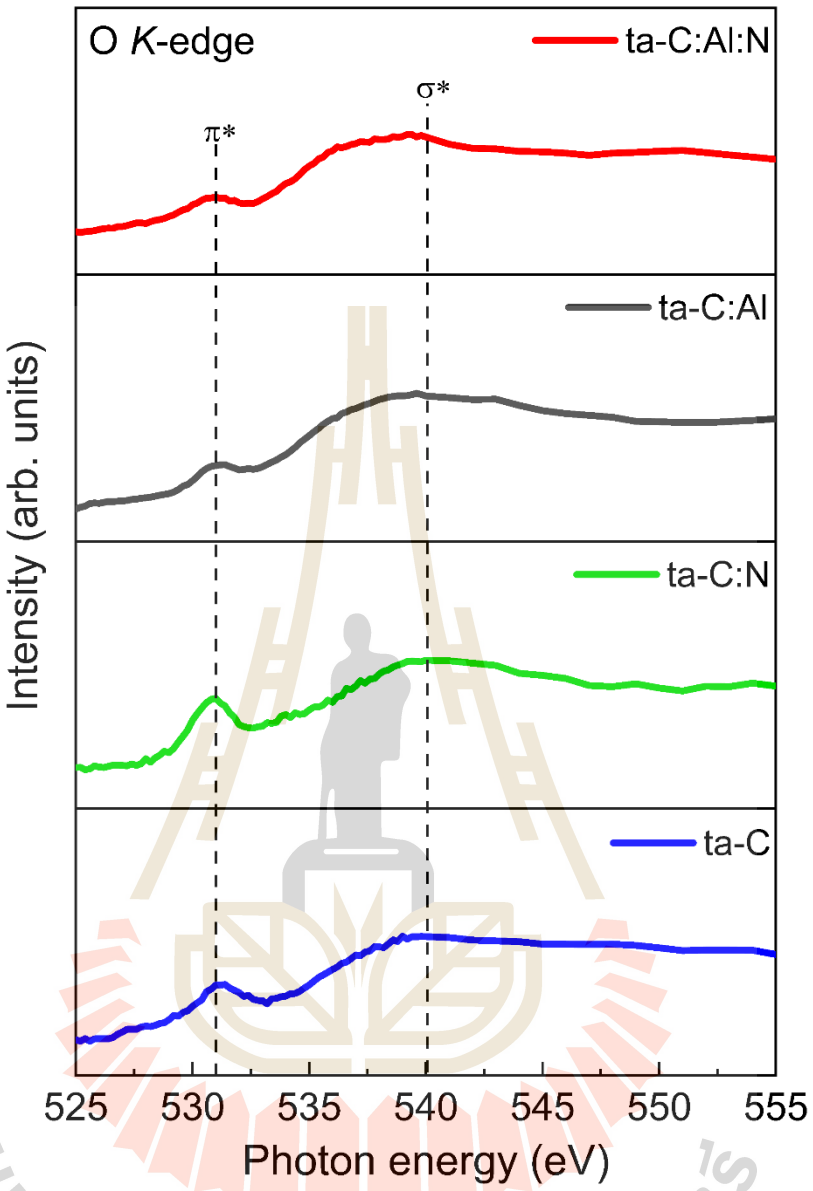


Figure 4.6 The O *K*–edge NEXAFS spectra generated for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N before the corrosion tests (Wongpanya *et al.*, 2022)

A comparison of the DLC films' O *K*–edge NEXAFS spectra shows that the O 1*s*⟶ **π*** transitions from the carbonyl and carboxyl groups of the O atoms double–bonded to the C atom (C=O) at photon energies of 531.2, 533.6, 536.0, and 540.0 eV, and the O 1*s*⟶ **π*** (C–O), **σ*** –OH, and the O 1*s* core–level electrons to the **σ*** C–O and C=O states, respectively, are shown in **Figure 4.6** (Wongpanya,

Pintitraratibodee, Thumanu, & Euaruksakul, 2021; Kim *et al.*, 2018; Lee *et al.*, 2012). For the Al–doped DLC films (ta–C:Al and ta–C:Al:N), the wide peak at 540.0 eV, which corresponds to Al_2O_3 with C=O, was visible, but the intensity of C=O (at 531.2 eV) in the Al_2O_3 that was seen was consistent with the findings from Al 2*p* XPS (Abaffy *et al.*, 2011).

The NEXAFS spectra of N–doped DLC films: ta–C:N and ta–C:Al:N, showed that N was successfully added to the DLC films. In the hexagonal graphitic structure, there were three different peaks at 398.40, 399.50, and 401.50 eV, which were ascribed to sp^3–hybridized C–N (N1), sp^2–hybridized C=N (N2), and substitution nitrogen in graphite or graphite–like (N3), respectively (Roy *et. al.*, 2005). There were moderately high and low–intensity peaks for N1, N2, and N3 at 399.30, 400.81, and 401.50 eV, respectively, in ta–C:N, while ta–C:Al:N had strong and moderately intense peaks for N1, but no sign of N3 in the spectrum. Only N1 and N2 were found in ta–C:Al:N, whereas N3 was not identified in an XPS scan, showing the presence of sp^3–hybridized C–N at 81.99 at.% and sp^2–hybridized at 11.33 at.%. The NEXAFS findings were found to be identical to the XPS results.

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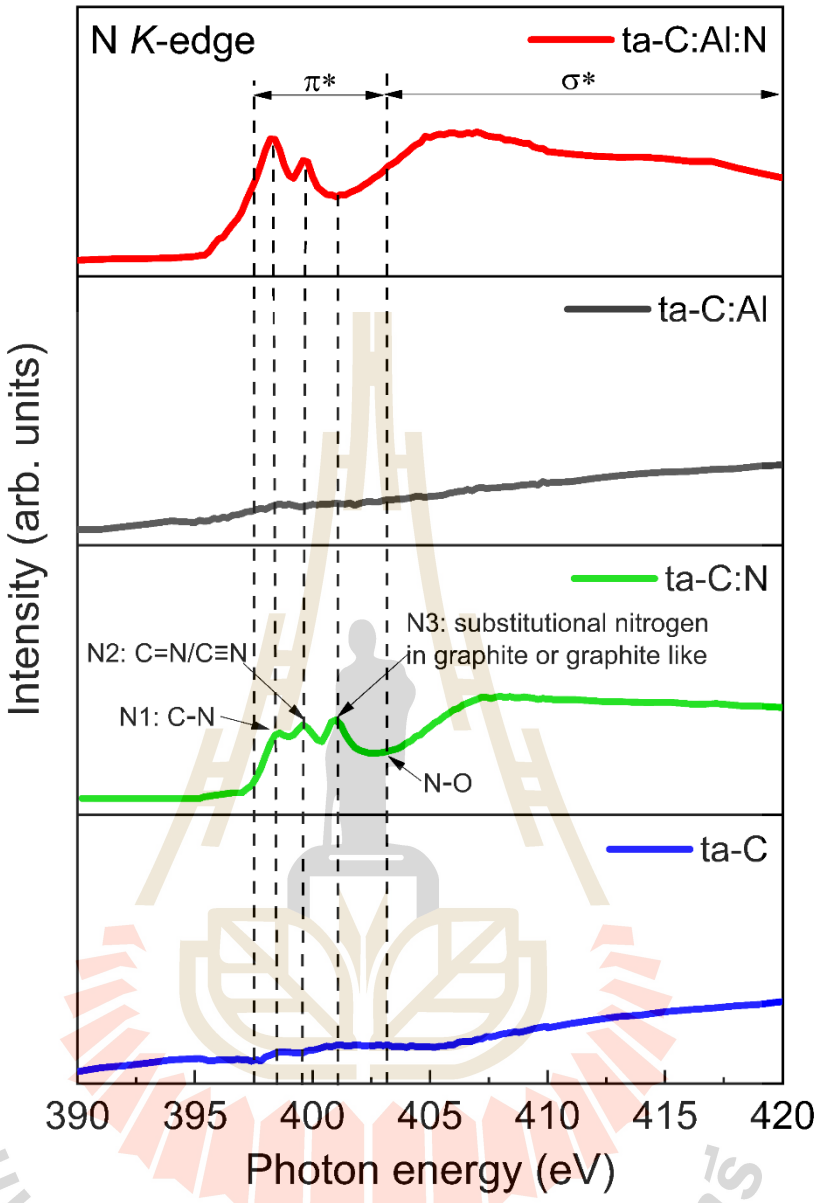


Figure 4.7 The N *K*–edge NEXAFS spectra generated for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N before the corrosion tests (Wongpanya *et al.*, 2022)

The investigation to evaluate the structure of the two coated DLC layers revealed that the I_D/I_G ratio, relative fraction of sp^3, and sp^2 fraction values for both sets were comparable, as shown in **Table 4.3**. The I_D/I_G ratio of the DLC films ta–C, ta–C:N, ta–C:Al, ta–C:Al:N are in the range 0.196–0.210, 0.998–0.873, 3.277–3.233, and 0.761–0.685, respectively, while the relative fraction of sp^3 values of the ta–C, ta–C:N,

ta–C:Al, ta–C:Al:N films are in the range 0.81, 0.49–0.50, 0.48–0.49, and 0.77, respectively, and the sp^2 fraction values of the ta–C, ta–C:N, ta–C:Al, ta–C:Al:N films are in the range 0.340–0.345, 0.390–0.394, 0.550–0.538, and 0.360–0.348, respectively. The mechanical properties, density, thermal stability, and corrosion resistance depend on the structure of the DLC film's layer. High content of sp^3 (or low sp^2 fraction and I_D/I_G) gives a high density, good thermal stability, good corrosion resistance, and good mechanical properties (Konkhunthot *et al*., 2018, 2019; Bootkul *et al*., 2014). As a result, both sets of specimens were produced using the FCVA technique, which indicated that the film's layer structure is the same.

Table 4.3 The summary of the I_D/I_G ratio, relative fraction of sp^3, and sp^2 fraction of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N in both sets.

Sample	I_D/I_G ratio		relative fraction of sp^3		sp^2 fraction	
	set I	set II	set I	set II	set I	set II
ta–C	0.196	0.210	0.81	0.81	0.340	0.345
ta–C:N	0.998	0.873	0.49	0.50	0.390	0.394
ta–C:Al	3.277	3.233	0.48	0.49	0.550	0.538
ta–C:Al:N	0.761	0.685	0.77	0.77	0.360	0.348

4.1.4 Thickness, roughness, and density of the DLC films

The cross–sectional images of all the DLC films and the continuous amorphous film layer were observed using FIB–SEM in the thickness range of 100–250 nm and the films were arranged from thickest to thinnest, as shown in **Figure 4.8**, with ta–C:N (230 nm) > ta–C (180.9 nm) > ta–C:Al:N (154.1 nm) > ta–C:Al (113.9 nm), respectively. Although the coating conditions, pressure, duty cycle, and time are the same for all the films, a film's thickness is inconsistent because the bonding structure and arrangement often influence the thickness of the DLC film. The DLC film's chains and aromatic rings contain impurities and carbon atoms (Bootkul *et al.*, 2014; Konkhunthot *et al.*, 2018; Pu *et al.*, 2015; Liu *et al.*, 2009; Modabberasl *et al.*, 2015; Sikora *et al.*, 2010).

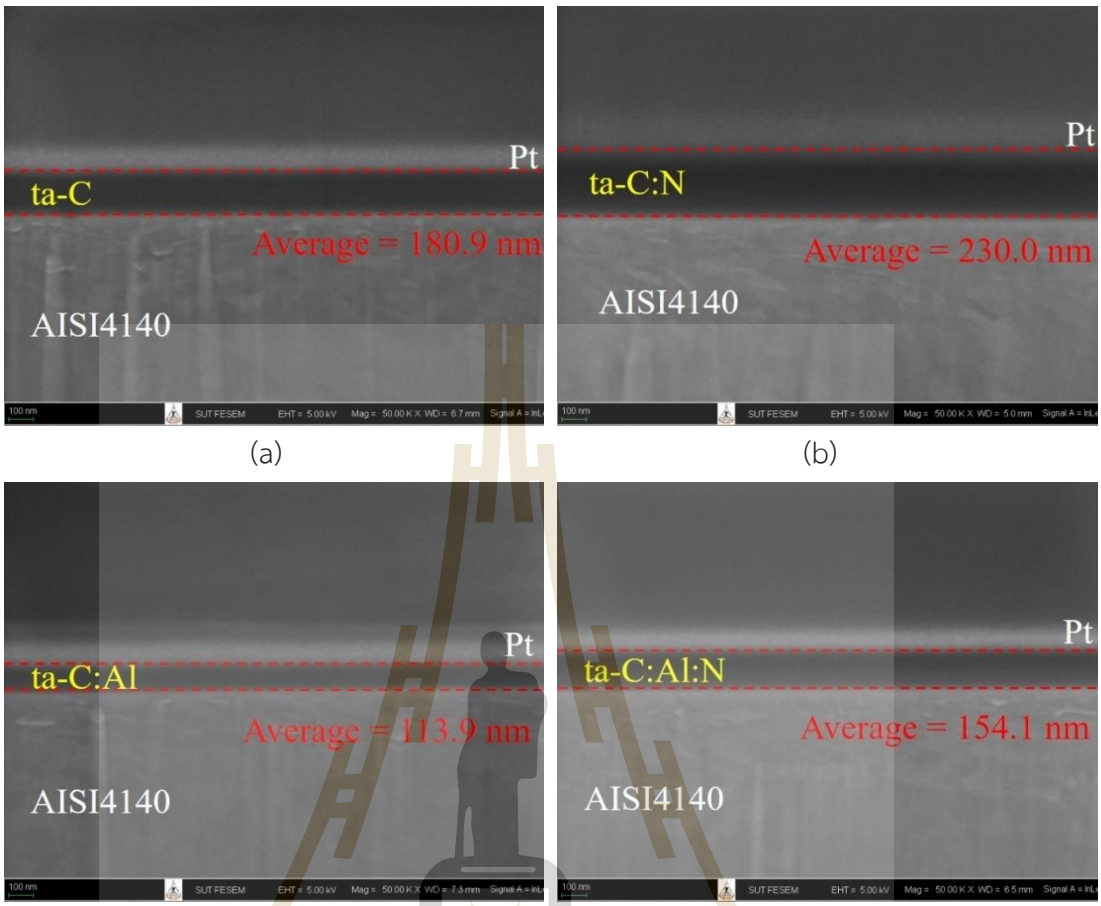


Figure 4.8 The FIB–SEM images of (a) ta–C, (b) ta–C:N, (c) ta–C:Al, and (d) ta–C:Al:N (Wongpanya, Silawong, & Photongkam, 2021)

The compressive residual stress generated during lamination determines the overall film thickness. The Raman results show that the thickness of the film increases when the compressive stress goes up in ta–C:N/ta–C:Al:N, but it decreases when the compressive stress increases in ta–C:Al. The maximum value of the G peak moved to a higher wavenumber when the thickness of the DLC film rose in tandem with the rise in compressive stress. The relationship between film thickness and Raman spectra data is consistent with previous observations (Liu *et al*., 2009). The doping results in a change in the thickness of the DLC film, which can be described as follows.

The reacting N atoms, acting as additional deposition components in the coating chamber, may enhance the thickness of the ta–C:N films. Due to the large amount of N_2 in the plasma while the films are being made, the ta–C:N films experience a lot of internal compressive stress (Bootkul *et al.*, 2014; Zarei Moghadam *et al.*, 2019). The tensile stress and thickness of ta–C:Al are, respectively, the lowest and thinnest. These characteristics may arise from interactions between the C and Al ions during the coating process. Due to Al's inability to react with C to produce aluminium carbide, a reduced number of C ions possess sufficient energy to adhere and establish sp^3 hybridized carbon bonds on the subsequent film layer (Xu *et al.*, 2018; Chen *et al.*, 2005). The highest I_D/I_G and L_a values, together with the lowest hardness values, corroborate this plausible explanation; however, Al and N-co-doped DLC (ta-C:Al:N) films do not. Despite being 26 nm thinner than undoped DLC, ta–C:Al:N exhibits a relative compressive stress of 0.102 GPa in comparison to DLC. The increase in N_2 pressure in the coating chamber from the baseline to 3×10^{-2} Pa during film development, along with the simultaneous introduction of Al and N (Zarei Moghadam *et al.*, 2019; Son *et al.*, 2017), led to a reduced collision rate between C and Al ions. N ions promote the deposition of films, resulting in ta–C:Al:N films being somewhat thinner than undiluted DLC films, as previously elucidated for ta–C:N.

The DLC film thicknesses obtained by FE–FEM for the second specimen set (set II), as shown in **Figure 4.9**, were 118.0, 118.3, 115.3, and 119.7 nm, with deposition times varying at 19, 15, 30, and 22 minutes for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N, respectively. Even if the coating factors for each of the films, such as the deposition rate, are different, it is clear that each DLC film has a different deposition time. Due to the arrangement of carbon atoms in the DLC film chain and the aromatic ring impacted by the doped composition and bond structure, the pressure, bias voltage, and duty cycle are all the same (Wongpanya, Silawong, & Photongkam, 2021; Bootkul *et al*., 2014; Konkhunthot *et al*., 2018; Liu *et al*., 2009). Additionally, the stress effects of the two types of DLC films were similar to what is shown in **Table 4.1**, where the ta–C:N and ta–C:Al:N samples experienced compressive stress, while ta–C:Al experienced tensile stress. Because high-energy N atoms with adequate flow rates may be incorporated into the DLC film (Bootkul *et al.*, 2014), the ta–C:N film's thickness

is reached in the lowest deposition time, while the ta–C:Al film requires more time. Due to the impact of C and Al ions during the coating process, the thickness remains the same; as a result, there is less C ion coating and carbon bonding in the film layer (Wongpanya, Silawong, & Photongkam, 2021; Xu *et al.*, 2018).

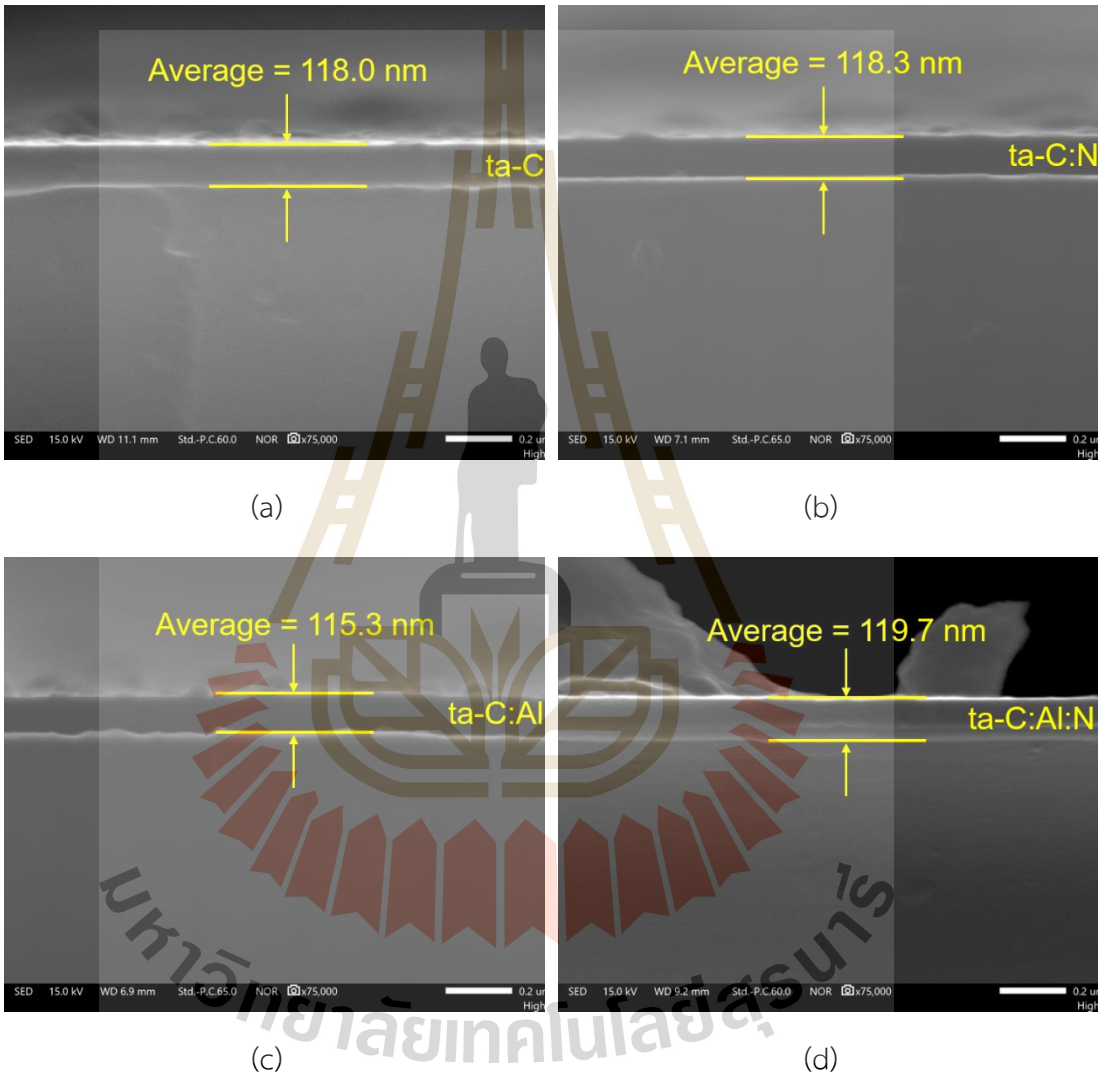


Figure 4.9 The FE–SEM images of (a) ta–C, (b) ta–C:N, (c) ta–C:Al, and (d) ta–C:Al:N (Wongpanya *et al.*, 2022)

Table 4.4 shows the surface roughness of the AISI 4140 material before and after polishing, as well as the AFM measurements for all the DLC layers. The surface treatment has completely removed any SiC from the embedded SiC paper. AISI 4140 exhibits a surface roughness (Ra) of 8.8 nm, falling below the ASTM Standard for block roughness (ASTM, E2546–07, 2007). The construction of the reference blocks must be executed to facilitate the efficient completion of the test, ensuring that the surface is smoothed to the highest degree possible. Also, for many uses, the average surface roughness Ra, measured over a 10 μm length, should be Ra ≤ 10 nm.

The nanoscale mechanical characteristics remained unchanged by our analysis. The surface roughness (Ra) of the DLC films was 8.4, 8.0, 8.8, and 6.4 nm for the ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films, respectively. Overall, the surface roughness values were comparable across all samples, ranging from 6.4 to 8.8 nm. The second set of specimens for AISI 4140 (pre-DLC coating) had a surface roughness (Ra) of 8.16, while the ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films had roughnesses of 8.16, 5.94, 7.48, and 6.14 nm, respectively. N and Al impurities significantly lower the amount of large particles on the DLC surface, as evidenced by the identification of larger particles in ta–C but not in ta–C:N, ta–C:Al, or ta–C:Al:N. The larger particles get smaller as a result of collisions between the dopant and the larger particles. A copper filter coil is then used to filter the big particles after they have been dumped on the ground.

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Table 4.4 AFM topographies of AISI 4140, ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N. (modified from Wongpanya, Silawong, & Photongkam, 2021; Wongpanya *et al*., 2022)

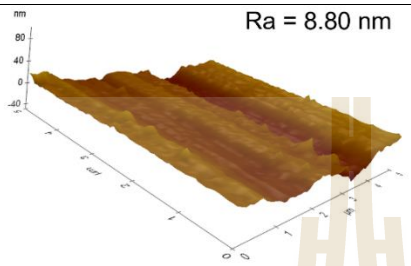
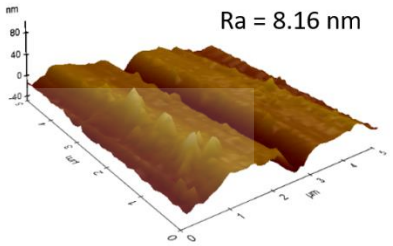
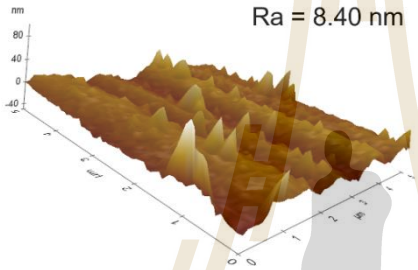
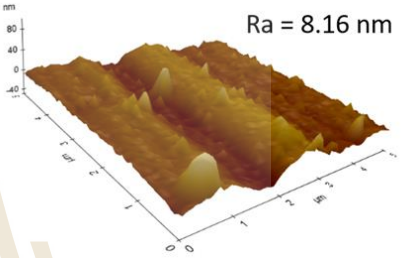
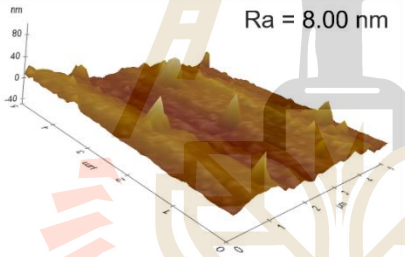
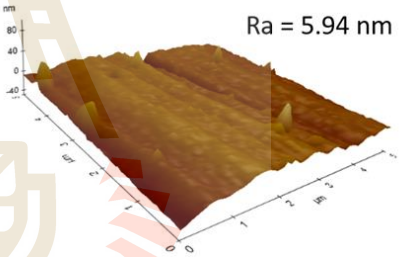
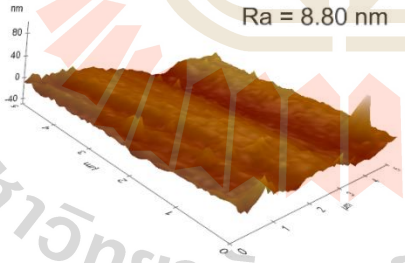
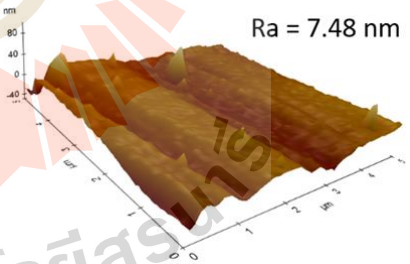
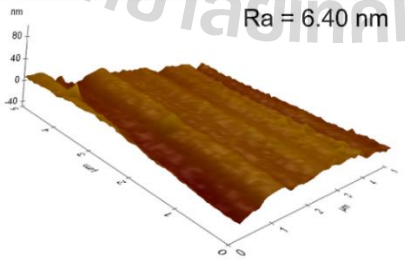
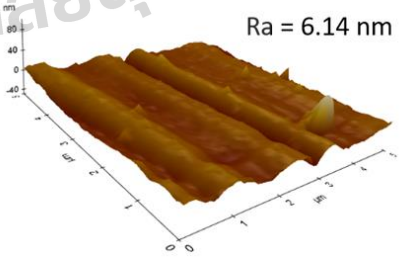
Sample	(set I)	(set II)
AISI4140		
ta–C		
ta–C:N		
ta–C:Al		
ta–C:Al:N		

Figure 4.10 shows the experimental and simulation results of DLC films at angles between 0.01 and 2.5° with steps of 0.005°. The black and red curves represent the experimental and simulated XRR profiles of the DLC films, showing densities of 2.52, 2.22, 2.17, and 2.32 g cm^{-3} for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N, respectively. Adding other materials to the DLC films led to a decrease in the amount of sp^3 observed in the XPS results (Konkhunthot *et al.*, 2018).

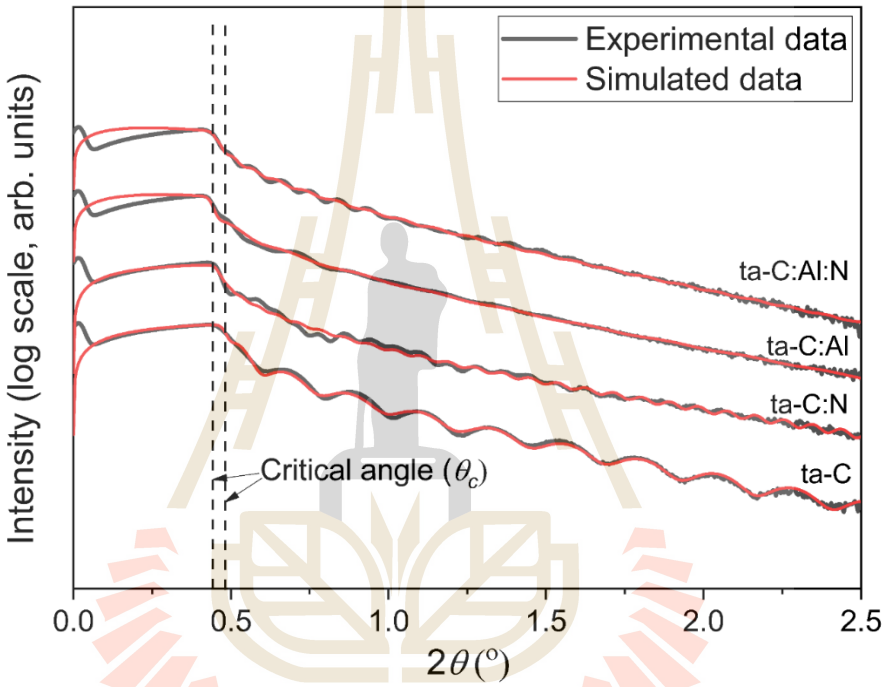


Figure 4.10 XRR profile of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N. (Wongpanya *et al.*, 2022)

4.2 The nanomechanical, adhesion strength, thermal stability, and corrosion resistance of the DLC films deposited on AISI 4140 by Al and N co–doping.

4.2.1 Nanomechanical property and adhesion strength analysis

The uneven changes in the load–displacement curves shown in this study indicate a high elastic recovery (%ER) from the shift between elastic and plastic deformation, as noted by Page *et al*. (1992), and the plastic deformation bands that

typically run alongside the edges of the indentations at low loads. **Figure 4.11** displays the load-displacement curves of all the DLC films.

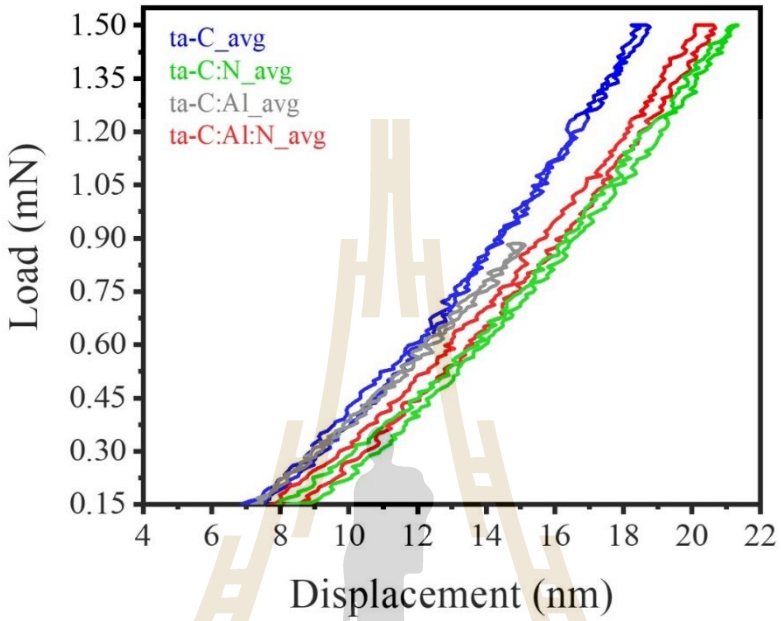


Figure 4.11 Load–displacement curves of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N (Wongpanya, Silawong, & Photongkam, 2021)

Nanoindentation testing was used to evaluate the nanomechanical characteristics of the DLC films, including hardness (H), elastic modulus (E), plastic index parameter, the ratio of hardness to elastic modulus, H/E, and elastic recovery (%ER). The elastic recovery (%ER) obtained from the load–displacement curves displayed in **Figure 4.11** has been used to determine the elasticity of the DLC films, which has been computed using the following equation:

$$\%ER = \left(\frac{d_{\max} - d_{\text{res}}}{d_{\max}}\right) \times 100 \tag{4.3}$$

where $d_{\max}$ and d_{res} are the displacement at the maximum load and the residual displacement after load removal, respectively.

Table 4.5 Mechanical properties of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N (test from set I) (from Wongpanya, Silawong, & Photongkam, 2021)

Sample	Mechanical properties			
	Hardness, *H* (GPa)	Elastic modulus, *E* (GPa)	Plastic index parameter, *H/E*	Elastic recovery (%*ER*)
ta–C	51.12 ± 1.08	302.29 ± 6.35	0.169 ± 0.005	60.06 ± 1.93
ta–C:N	47.32 ± 1.91	210.51 ± 4.82	0.225 ± 0.010	57.92 ± 1.35
ta–C:Al	38.84 ± 1.78	159.65 ± 3.94	0.243 ± 0.013	50.47 ± 1.53
ta–C:Al:N	49.04 ± 1.33	251.09 ± 6.57	0.195 ± 0.007	58.43 ± 1.73

Table 4.5 shows that the H and E of ta–C:N, ta–C:Al, and ta–C:Al:N were 47.32 ± 1.91 and 210.51 ± 4.82, 38.84 ± 1.78 and 159.65 ± 3.94, and 49.04 ± 1.33 and 251.09 ± 6.57 GPa, respectively, and were lower than those of the non–doped DLC (51.12 ± 1.08 and 302.29 ± 6.35 GPa). The XPS spectra show that the lower H and E correlate to greater I_D/I_G and La ascribed to an increased sp^2–hybridized carbon bond concentration and reduced sp^3/sp^2.

As a result of the higher dopant concentration, the nanomechanical characteristics of the DLC films revealed greater graphitization and bigger graphite clusters (L_a). Furthermore, the mechanical characteristics of the DLC films, particularly the ta–C film, were dramatically impacted by the sp^3–hybridized carbon bond concentration, and with a decreasing sp^3–hybridized carbon bond concentration, the mechanical characteristics of the ta–C film, such as hardness, surface smoothness, atomic density, and Young's modulus, all reduced (Bootkul *et al.*, 2014). Because of the NC diamond phase (Singha *et. al.*, 2006) that had developed in the co–doped DLC film, the H of the ta–C:Al:N became lower than that of the non–doped DLC, as demonstrated by the peak at ~1248.17 cm^{-1} in the Raman result from **Figure 4.1**. These findings suggest that doping the DLC film with Al and N increased the film's hardness. Nevertheless, all the DLC films improved the hardness of the AISI 4140 steel bare substrate, as shown by the increased hardness of 38.84 ± 1.78, 47.32 ± 1.91, and

49.04 ± 1.33 GPa for ta–C:Al, ta–C:N, and ta–C:Al:N–coated AISI 4140 steel, respectively, from 3.3 GPa for AISI 4140 (Ochoa *et al.*, 2006). Furthermore, as compared to genuine diamond (56–102 and 1050 GPa, respectively), the DLC nanomechanical characteristics (H and E) were above 38 and 150 GPa, suggesting the deposition of high–quality DLC films. Using these values, the coatings could successfully protect substrate surfaces from scratches and wear (Savvides and Bell, 1993; Robertson, 2002). The H/E and %ER were used to evaluate the DLC films' elastic–plastic behavior and wear resistance (Savvides and Bell, 1993). Materials with high elastic strain–to–failure are ranked according to their H/E ratio. A high H/E indicates that a DLC film has high wear resistance, making it acceptable for use on vehicle components (Ishpal *et al.*, 2012).

The DLC film's hardness is reduced by Al and N–doping even though the elastic strain to failure is increased (**Table 4.5** shows that the H/E values of the ta–C:N, ta–C:Al, and ta–C:Al:N films are 0.225 ± 0.010, 0.243 ± 0.013, and 0.195 ± 0.007, respectively), while the ta–C film is only 0.169 ± 0.005. The relaxation of the elastic strain inside the DLC structure is well–known to result in high elasticity and recovery in typical hard and adherent DLC films (Ankit *et al.*, 2017; Coll *et al.*, 1996). Elastic recovery is also greatly influenced by the amount of sp^3–hybridized carbon bonds in the film (Ishpal *et al.*, 2012). As a result, as shown by the %ER data in **Table 4.5**, the elastic recovery of the DLC films dropped as the dopant concentration increased. According to the XPS study, %ER has been classified in decreasing order as follows: ta–C > ta–C:Al:N > ta–C:N > ta–C:Al, which corresponds to the sp^3–hybridized carbon bond concentration in the films.

The following sections go through important aspects, including local bonding structure and thermal stability, to see whether doping and co–doping are acceptable for DLC films used as protective coatings for wear and tribological applications, particularly for automotive components. Adhesion strength, scratch test data, and SEM pictures were utilized to assess and compare the adhesion failure of all the DLC films in **Figure 4.12**. There are two distinct phases of critical load (L_c), the first of which is loaded and utilized to initiate the DLC film's initial failure, such as plastic deformation. The first term (L_{c1}) represents edge cracks and fine cracks, while the

second term (L_{c2}) represents the critical normal load that identifies the reason for film adhesion failure. The L_{c1} and L_{c2} occurred at 126.57, 87.75, 65.16, and 99.60 mN and 195.29, 191.62, 199.46, and 221.96 mN for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N, respectively. It is obvious that for L_{c1} ta–C has the greatest value and the films may be ranked in decreasing order as ta–C, ta–C:Al:N, ta–C:N, and ta C:Al, respectively, while for L_{c2}, the Al–doped film layers, ta–C:Al and ta–C:Al:N had greater second–stage critical load values than ta–C and ta–C:N. It was discovered that only L_{c1} tended to correlate with the film hardness (H) and elastic recovery (%ER) of the DLC films in previous work (Wongpanya, Silawong, & Photongkam, 2021) in which these properties depend on the quantity of sp^3 C—C in the DLC corresponding to the relative proportion of sp^3. The maximum L_{c1} can be seen in ta–C, as evidenced by the high %ER, which was due to elastic strain relaxation inside the film. As a result, ta–C could recover without deformation and had a greater cohesive strength (L_{c1}) than the other DLC films (Ankit *et al.*, 2017; Coll *et al.*, 1996).

Interestingly, increasing L_{c2} can be seen when the non–doped DLC film (ta–C) has been doped with Al and Al–N. That effect reduces internal stress and increases the graphite cluster size of the sp^2 sites (L_a), resulting in a high content of sp^3–hybridized C–N bonds (ta–C:Al:N only) (Zhou *et al.*, 2019; Dai and Wang, 2011), and the Al doping in DLC film can reduce the friction coefficient as reported. On the other hand, the ta–C:N had the highest stress in the DLC film, resulting in the lowest L_{c2} in this study. Typically, the plastic index parameter (H/E) is a critical attribute for assessing a coating surface that has been heavily deformed during elastic strain to failure to determine wear resistance (Konkhunthot *et al.*, 2019; Wongpanya, Silawong, & Photongkam, 2021; Ishpal *et al.*, 2012). Conversely, the toughness of the film should be proportional to the product of the lower critical load and the difference between the high (L_{c2}) and low (L_{c1}) critical loads, which was defined as scratch crack propagation resistance (CPRs) = L_{c1} ($L_{c2} - L_{c1}$), calculated by Equation (4.4) (Zhou *et al.*, 2019; Zhang et al., 2004):

$$\text{CPRs} = L_{c1}\,(L_{c2} - L_{c1}) \tag{4.4}$$

The ta–C:Al:N, ta–C:N, ta–C:Al, and ta–C films had CPRs values of 12187.06, 9114.59, 8750.99, and 8697.89 mN^2, respectively. As a result, the CPRs values of the Al and N–doped DLC films were elevated much higher than those of the other films, indicating that ta–C:Al:N exhibited the maximum toughness and adhesion strength in this experiment.

The SEM morphologies of scratch tracks for all the DLC films at L_{c2}, which are heavily damaged and peeled off the substrate, thus showing the failure of the adhesion strength of the DLC films to the substrate, are shown in the insets in **Figure 4.12** (a)–(d). There are segment fractures and breaks along both sides of the scratch track for ta–C as evidence of brittle fracture, but for ta-C:N, ta-C:Al, and ta-C:Al:N doping, the wear tracks are deeper and wider, demonstrating the enhancement of the adhesion strength. As shown by the Raman findings in **Table 4.1**, the compressive stress of the film on ta–C:N was 1.193 GPa, while the compressive stress of the films on ta–C:Al and ta–C:Al:N was –2.886 GPa and 0.127 GPa, respectively; the decreases in residual stress in the DLC films have been linked to an improvement in adhesion strength for N–doped, Al–doped, and Al–N co–doped films. Consequently, higher residual stress equals a high amount of stored elastic energy in the films. DLC films have a high stored elastic energy, which leads them to delaminate from the substrate if the adhesion energy between the DLC films and the substrates is inadequate (Konkhunthot *et al.*, 2019). Furthermore, higher sp^3–hybridized C–N bonds for ta–C:N and ta–C:Al:N, as well as Al_2O_3 which has substantially better toughness relative to ta–C for ta–C:Al and ta–C:Al:N, contribute to improved lubrication performance or friction–reducing properties (Bootkul *et al.*, 2014; Bouabibsa *et al.*, 2018; Dai and Wang, 2011).

This is because, during the scratch test, the temperature in the region of the test contact increases, resulting in film surface oxidation and the creation of a thicker Al_2O_3 film layer, which slows the plastic deformation and the scratch resistance and allows the DLC film layer to maintain its lubricating properties (Zhou *et al*, 2019; Wang *et al.*, 2018; Ye *et al.*, 2017).

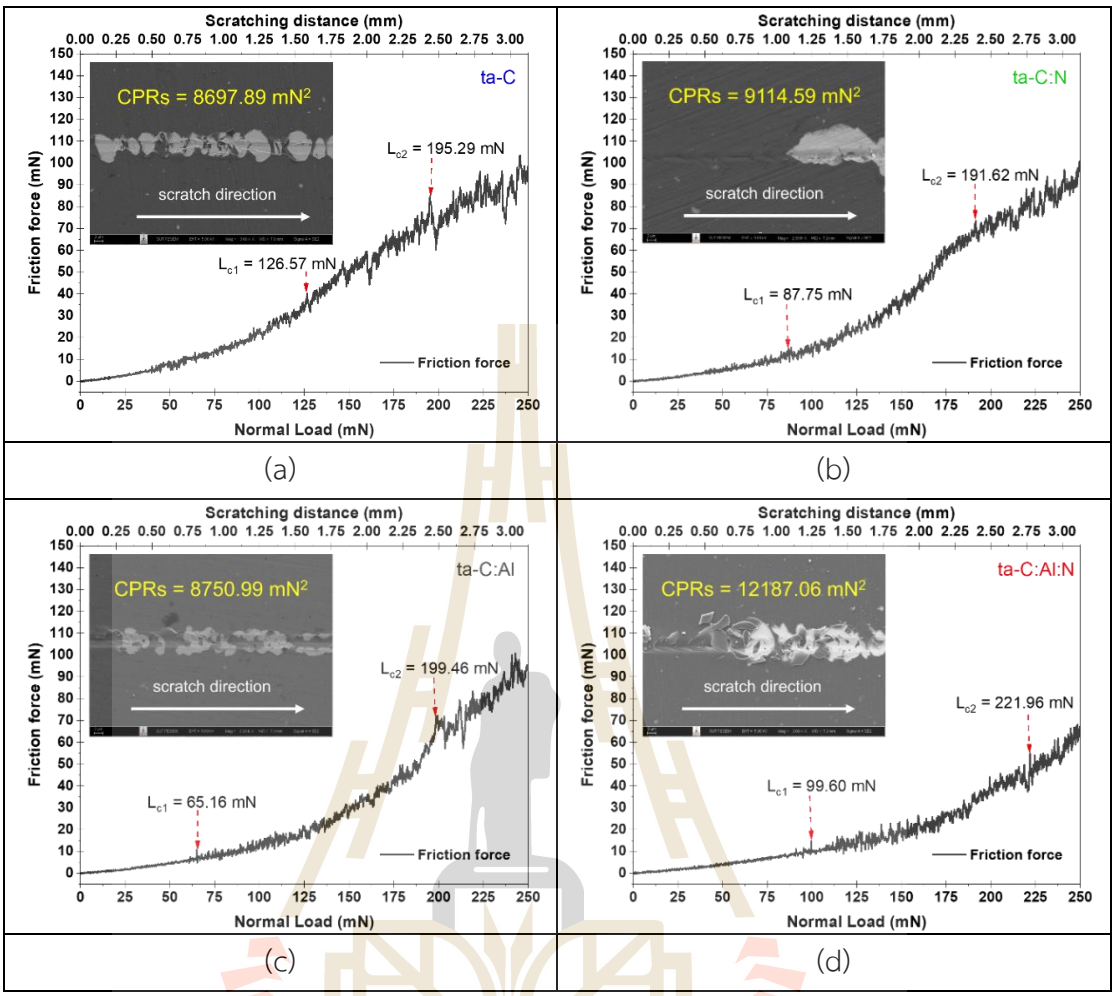


Figure 4.12 Scratch curves and the SEM micrographs of the corresponding scratch tracks at L_{c2} for (a) ta–C, (b) ta–C:N, (c) ta–C:Al, and (d) ta–C:Al:N, respectively (Wongpanya *et al.*, 2022)

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4.2.2 Thermal stability analysis by in–situ NEXAFS

Analyses of the thermal stability of the DLC films at RT and thermally annealed between 200 and 700°C in 100°C increments were carried out utilizing high–temperature NEXAFS spectroscopy of the local atomic structures of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N. The C *K*–edge NEXAFS spectrum produced for ta–C:Al:N at RT is shown in **Figure 4.13**. Subtraction and deconvolution of the spectrum resulted in several peaks. When the sp^2–hybridized C=C site is present, it may have also contributed to the pre–edge resonance at 285.4 eV, which has been determined to be a transition from the unoccupied **π*** state (Konkhunthot *et al.*, 2019; Lenardi *et al.*, 1999; Tagawa *et al.*, 2010).

At the high–energy edge, overlapping C 1*s* transitions to unoccupied **σ*** states at *sp*, sp^2, and sp^3–hybridized sites in DLC films generated the broadband zone between 288 and 335 eV (Lenardi *et al.*, 1999). The intermediate area identified between the **π*** and **σ*** states corresponds to transitions between the states at 285.1, 285.9, 286.3, 287.6, 287.7, 288.5, 289.6, and 293.7 eV (Ashtijoo *et al.*, 2016; Soin *et al.*, 2012). Other high resonances observed at 297.8 and 304.3 eV (Lenardi *et al.*, 1999; Soin *et al.*, 2012) were attributed to C 1*s* ⟶ **π*** (C=C), **π*** (C=N), **π*** (C=OH), **σ*** (C–H), **σ*** (C–N), **π*** (C=O) or **π*** (C≡C), **σ*** (C–C), and **σ*** (C=C). Because hydrogen was not present during the FCVA deposition, the hydrogen saturation of the surface–carbon dangling bonds (i.e., nonpaired electrons) was assigned to **σ*** (C–H) states, while carbon that had been oxidized by air exposure was assigned to **σ*** (C=O) states (Lenardi *et al.*, 1999; Ashtijoo *et al.*, 2016; Soin *et al.*, 2012).

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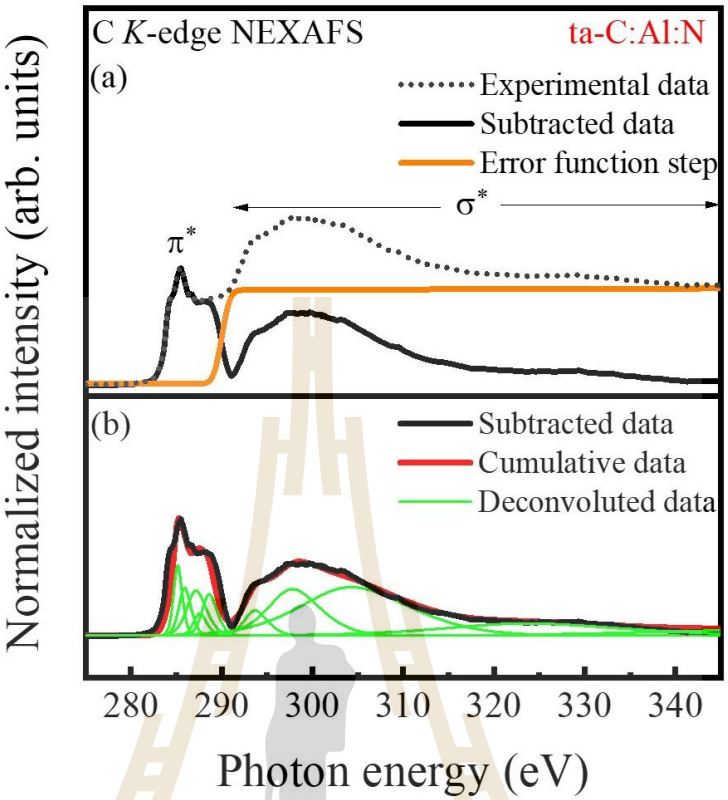


Figure 4.13 In–situ high–temperature NEXAFS C *K*–edge spectra were generated before (a) and after (b) data subtraction (Wongpanya, Silawong, & Photongkam, 2021)

The peak area corresponding to the C 1*s* ⟶ **π*** transition at 285.4 eV must be normalized with C 1*s* ⟶ **σ*** transitions in the range 288–335 eV to estimate the sp^2–hybridized bond content in a sample. The following equation (Lenardi *et al.*, 1999; Tagawa *et al.*, 2010; Yoshitake *et al.*, 2009) may therefore be used to compute the sp^2–hybridized bond fraction:

$$f_{sp^2} = \frac{I_{sam}^{\pi^*}/I_{sam}^{total}}{I_{ref}^{\pi^*}/I_{ref}^{total}} \tag{4.5}$$

where **π*** is the position of the C 1*s* ⟶ **π*** transitions in C=C bonds, the total is the integration areas calculated under the spectrum for binding energies in

the range 288–335 eV, and sam and ref define the deconvoluted peaks for a sample thin film and a reference sample (highly oriented pyrolytic graphite (HOPG)), respectively.

The in–situ C *K–edge* NEXAFS spectra of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N at RT and thermally annealed up to 700°C are shown in **Figure 4.14**. As demonstrated by the spectrum characteristics, the chemical bonding configuration displayed minor heterogeneities, indicating that the atomic bonding structure altered gradually when the dopant concentration (Al and N) was low. As illustrated in **Figure 4.14** and **Figure 4.15**, the sp^2–hybridized bond fractions of the ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N films were 0.34, 0.39, 0.55, and 0.36 at RT, respectively. Doping with simply N or Al caused the production of graphitic sp^2–hybridized bonds known as "graphitization," as demonstrated by the sp^2–hybridized bond fractions, but co–doping with both Al and N induced very minimal graphitization. Because graphitization converted sp^3–hybridized (σ^*) states in the amorphous carbon film into sp^2–hybridized (π^*), the percentage sp^2–hybridized bond fraction rose with increasing annealing temperature (Grierson *et al.*, 2010). The NEXAFS spectra of ta–C:N, ta–C, and ta–C:Al indicated that sp^3–hybridized (σ^*) states had considerably converted into sp^2–hybridized (π^*) ones in the amorphous carbon films at 400, 500, and 600°C, respectively, which meant that they had already graphitized; this is similar to results in earlier research (Fu *et al.*, 2005; Zhang *et al.*, 2002; Tallant *et al.*, 1995). In ta–C:Al:N, on the other hand, the percentage sp^2–hybridized bond fraction grew steadily from 0.36 at room temperature to 0.39 at 300°C.

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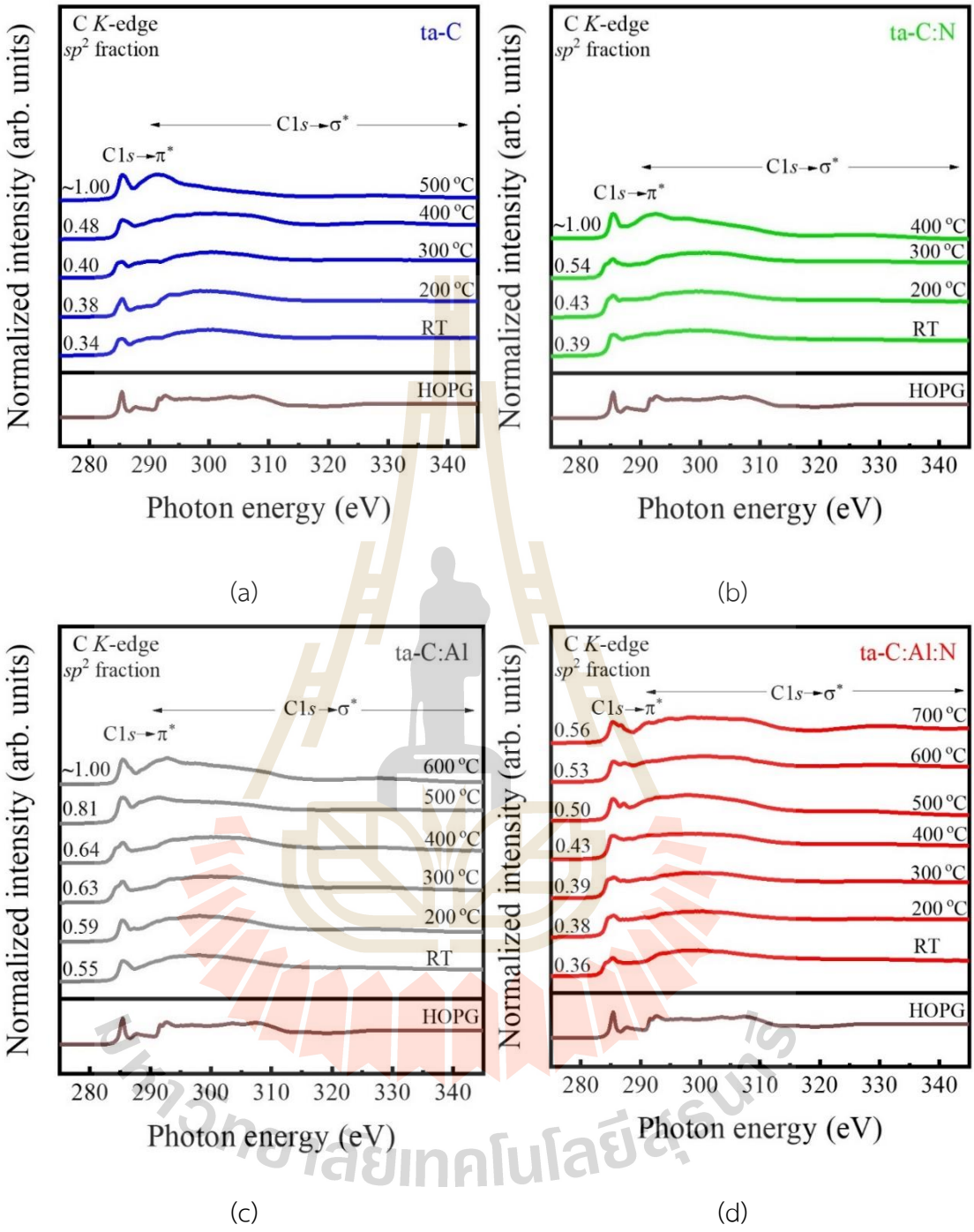


Figure 4.14 The C *K*–edge NEXAFS spectra obtained at room temperature (RT) and thermally annealed to graphitization temperature for (a) ta–C, (b) ta–C:N, (c) ta–C:Al, and (d) ta–C:Al:N (Wongpanya, Silawong, & Photongkam, 2021)

The relative sp^2–hybridized bond ratio in ta–C changed from 0.34 to 0.40 in the same temperature range, which was just slightly different. From 400 to 700 °C, the relative sp^2–hybridized bond fraction of ta–C:Al:N increased dramatically from 0.43 to 0.56. As seen in **Figure 4.15**, the carbon in the ta–C:Al:N film remained amorphous, meaning that ta–C:Al:N graphitized more slowly and at a higher annealing temperature than ta–C:N, ta–C, and ta–C:Al, because the diamond structure had transformed to graphite at 400-700 °C, as indicated by sp^2 fractions up to 1. The great thermal stability of ta–C:Al:N is indeed owing to the synergistic synthesis of stable Al_2O_3 oxide and sp^3–hybridized C–N bonds, as evidenced by the XPS result in section 4.1, respectively, during in–situ high–temperature annealing of amorphous ta–C:Al:N, this greatly delayed graphitization, stabilizing the DLC structure (B. Zhou, 2019, Y. Zhou, 2019, V. Podgursky, 2020)

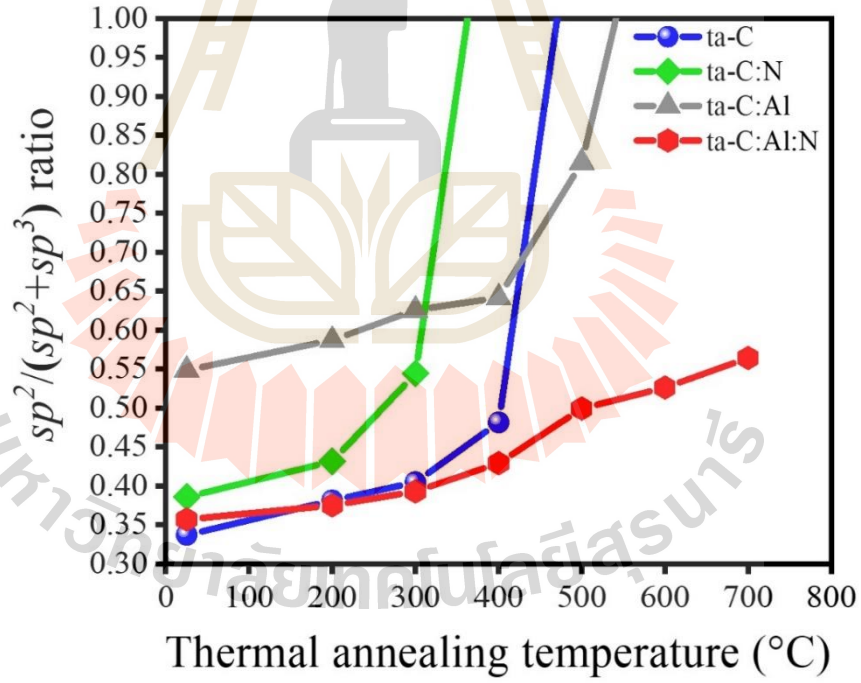


Figure 4.15 The sp^2–hybridized bond fractions of ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N as a function of thermal annealing temperature from room temperature (RT) to graphitization temperature. (Wongpanya, Silawong, & Photongkam, 2021)

4.2.3 Electrochemical corrosion analysis by potentiodynamic polarization technique

The polarization curves for AISI 4140 steel and all the DLC films, ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N, were electrochemically evaluated in 3.5 wt% NaCl solution (pH ~6.6) at 27±0.5 °C are shown in **Figure 4.16**. The E_{corr}, i_{corr}, the anodic and cathodic Tafel constants (b_a and b_c), E_{pit}, i_p, R_p, *CR*, *P*, and P_i, as well as other important corrosion parameters, were determined and are presented in **Table 4.6**. The DLC–coated steels had three separate zones: the active, passive, and transpassive zones, while the AISI 4140 steel had no passive area and no pitting resistance, suggesting inferior corrosion resistance. When compared to the AISI 4140 steel, all the DLC coatings significantly improved corrosion resistance, with increases in E_{corr}, E_{pit}, and R_p, but decreases in i_{corr} and *CR*. All of the DLC films had similar i_{corr} and *CR* values and were three orders of magnitude less than the AISI 4140 steel. The E_{corr} moved from –443.31 and –442.69 mV to –425.08 and –382.93 mV for ta–C and ta–C:N, and ta–C:Al and ta–C:Al:N, respectively, indicating that Al–doped and Al–N–co–doped DLC films are slightly more stable than non–doped and N–doped DLC films. Furthermore, due to the synergy of Al oxide and sp^3 C–N bonds generated in the DLC films, ta–C:Al and ta–C:Al:N showed the second and highest corrosion resistance, respectively, as shown by the high R_p (3890.89 and 4237.02 Ω cm^2), high P_i (77.77 and 79.22 %) and low *P* (2.09×10^{-4} and 3.49×10^{-5}) demonstrated by XPS, which behaves as the primary barrier against the corrosive environment's penetration and destruction (Konkhunthot *et al.*, 2019; Wongpanya *et al.*, 2022; Xu *et al.*, 2018; Zhou *et al.*, 2019).

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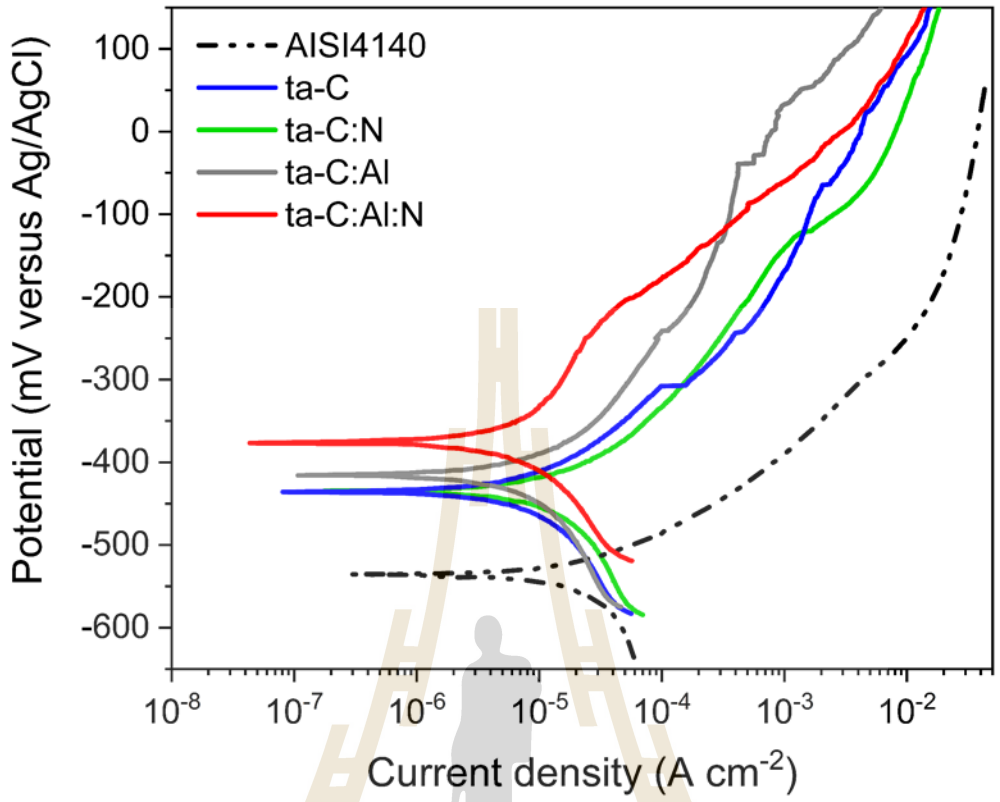


Figure 4.16 The polarization curves of AISI 4140, ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N in 3.5 wt% NaCl solution, respectively (Wongpanya *et al.*, 2022)

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Table 4.6 Corrosion results for 4140 and ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N electrochemically tested in 3.5 wt% NaCl solution (Wongpanya *et al.*, 2022)

Sample	E_{corr} (mV)	i_{corr} (μA cm^{-2})	b_a (mV dec^{-1})	b_c (mV dec^{-1})	E_{pit} (mV)	i_p (μA cm^{-2})	R_p (Ω cm^2)	CR (mm yr^{-1})	P	P_i (%)
AISI 4140	–547.44 (± 8.079)	10.30 (± 0.226)	40.38 (± 1.146)	53.13 (± 0.956)	–	–	967.20	1.22×10^{-1}	–	–
ta–C	–443.31 (± 6.072)	2.39 (± 0.050)	44.76 (± 1.596)	46.79 (± 1.220)	–310.06 (± 4.247)	46.50 (± 0.973)	4156.17	1.01×10^{-4}	1.09×10^{-3}	76.79
ta–C:N	–442.69 (± 7.949)	4.54 (± 0.143)	39.53 (± 1.429)	43.47 (± 1.133)	–126.66 (± 2.274)	354.00 (± 11.150)	1980.11	2.14×10^{-4}	1.09×10^{-3}	55.92
ta–C:Al	–425.08 (± 6.837)	2.29 (± 0.064)	39.80 (± 1.201)	42.36 (± 0.629)	–44.23 (± 0.711)	184.00 (± 5.140)	3890.89	1.28×10^{-4}	2.09×10^{-4}	77.77
ta–C:Al:N	–382.93 (± 5.883)	2.14 (± 0.042)	43.12 (± 1.118)	40.49 (± 0.602)	–201.13 (± 3.090)	22.20 (± 0.436)	4237.02	1.17×10^{-4}	3.49×10^{-5}	79.22

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4.2.4 The structural and local bonding configuration analysis after the corrosion tests

The chemical bond structure was studied using XPS and NEXAFS methods once all the DLC films' corrosion experiments were completed. The observation of chemical elements C, N, and Al, as well as Fe (i.e., corrosion of the metal surface substrate), has been associated with the deterioration of the DLC films, except for O, due to contamination. This suggests that following corrosion testing, the DLC films' degradation was greatly decreased, as seen by the films' characteristics, such as sp^3 C–C, sp^3/sp^2 ratio, and the sp^3 relative fraction. The sp^3 C–C bond was diminished in the DLC films, as evidenced by C 1*s* in **Table 4.8**, suggesting the corrosion degradation of the sp^3 C–C bond to the sp^2 C=C bond (Wongpanya, Pintitraratibodee, Thumanu, & Euaruksakul, 2021). The addition of Al and N to the DLC films reduced the deterioration of the DLC properties, as shown in the difference in the diamond structure (sp^3 C–C) quantity before and after the corrosion test, (11.85, 18.70, and 26.06 at.% declines for ta–C:Al:N, ta–C:Al, and ta–C:N, respectively), showing that the addition of Al and N to the DLC films hindered the degradation of the DLC properties (Konkhunthot *et al.*, 2019; Wongpanya, Silawong, & Photongkam, 2021). The slowing of all elements of the doped DLC films might be attributed to nitrides (sp^3–hybridized C–N for ta–C:N and ta–C:Al:N) and aluminium oxide (Al_2O_3 for ta–C: Al and ta–C:Al:N), as shown in **Tables 4.7** and **4.8**, respectively. Before corrosion testing, for example, ta–C:Al:N was discovered. After corrosion degradation, sp^3–hybridized C–N bonds to the high Al_2O_3 content (81.99 and 100 at.%, respectively, in **Table 4.7**), and these bonds include the converted oxide to sp^2–hybridized C=N mixed with AlO_x (82.95 and 100 at.%, respectively, in **Table 4.8**).

Table 4.7 Type of bonding, sp^3/sp^2 ratio, and relative fraction of sp^3 of all the DLC films before the corrosion tests (Wongpanya *et al.*, 2022)

XPS spectra	Sample	Type of bonding (at.%)								sp^3/sp^2 ratio	relative fraction of sp^3
		sp^3 C—C	sp^2 C=C	sp^3 C—N	sp^2 C=N	C—OH	C—O	C=O	Al—C—O	Total	
C 1*s*	ta-C	68.95	16.12			2.41		12.52		100.00	4.28	0.81
	ta-C:N	40.52	17.74	2.97	26.61		12.16			100.00	0.98	0.50
	ta-C:Al	38.81	40.99			11.09	6.94		2.17	100.00	0.95	0.49
	ta-C:Al:N	50.65	21.20	21.19	0.24	6.64			0.08	100.00	3.35	0.77
		C—O	C—OH	C=O	N—O	O=C—OH						
O 1*s*	ta-C		10.90	89.10						100.00		
	ta-C:N	81.19			18.81					100.00		
	ta-C:Al	35.38	59.40			5.22				100.00		
	ta-C:Al:N	55.13	41.42		3.45					100.00		
		sp^3 C—N	sp^2 C=N	N—O								
N 1*s*	ta-C:N	25.59	67.77	6.64						100.00		
	ta-C:Al:N	81.99	11.33	6.68						100.00		
		AlO_x	Al_2O_3									
Al 2*p*	ta-C:Al	23.40	76.60							100.00		
	ta-C:Al:N		100.00							100.00		

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Table 4.8 Type of bonding, sp^3/sp^2 ratio, and relative fraction of sp^3 of all the DLC films after the corrosion tests (Wongpanya *et al.*, 2022)

XPS spectra	Sample	Type of bonding (at.%)									sp^3/sp^2 ratio	relative fraction of sp^3
		sp^3 C–C	sp^2 C=C	sp^3 C–N	sp^2 C=N	C–OH/C–O–C	C–O	C=O/COOH	Al–C –O	Total		
C 1*s*	ta–C	24.77	50.12			19.39		5.72		100.00	0.49	0.33
	ta–C:N	14.46	50.98	1.51	21.99		3.24	7.82		100.00	0.22	0.18
	ta–C:Al	20.11	50.42			18.56	2.40	6.61	1.90	100.00	0.40	0.29
	ta–C:Al:N	38.80	42.78	1.52	9.43	0.71		6.59	0.17	100.00	0.77	0.44
		C–O/Al–OH	C–OH	C=O	N–O	O=C–OH	Fe_3O_4	FeO/Fe_2O_3	Metal carbonates	Al_2O_3		
O 1*s*	ta–C		1.16	6.32			39.57	47.42	5.53		100.00	
	ta–C:N	2.60			3.00		18.15	71.21	5.04		100.00	
	ta–C:Al	3.74	3.70			3.54	25.45	35.79		27.78	100.00	
	ta–C:Al:N	2.65	5.74		1.62		22.54	31.24		36.21	100.00	
		sp^3 C–N	sp^2 C=N	N–O								
N 1*s*	ta–C:N	8.92	88.23	2.85							100.00	
	ta–C:Al:N	13.54	82.95	3.51							100.00	
		AlO_x	Al_2O_3	$Al(OH)_3$	Al–OH							
Al 2*p*	ta–C:Al	0.56	90.63	4.63	4.18						100.00	
	ta–C:Al:N	100.00									100.00	
		Fe (Me)	Fe (II)	Fe (III)								Fe (II)/Fe (III) ratio
Fe 2*p*	ta–C	13.93	51.59	34.48							100.00	1.496
	ta–C:N	6.53	63.10	30.37							100.00	2.078
	ta–C:Al	27.13	44.73	28.14							100.00	1.589
	ta–C:Al:N	26.59	31.37	42.04							100.00	0.746

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This means that during corrosion, sp^3–hybridized C–N coupled with Al_2O_3 sacrificed itself. Thus, although ta–C:Al or ta–C:N deteriorates and sacrifices itself during corrosion, the deterioration of the sp^3 C–C bonds may be slowed. Both Al_2O_3 (76.60 at.%) and AlO_x (23.40 at.%) were used to determine this, as well as the low content of sp^3–hybridized C–N (25.59 at.%), which evaluated corrosion resistance performance. After corrosion, the quantity of the remaining sp^3 C–C bond was smaller than that for ta–C:Al:N (20.11, 14.46, and 38.80 at.% for ta–C:Al, ta–C:N, and ta–C:Al:N, respectively, in **Table 4.8**). As a result, the corrosion resistance of the DLC films degrading in NaCl solution may be graded as follows: slow decrease in sp^3–hybridized C–N and Al_2O_3 > Al_2O_3 > sp^3–hybridized C–N was established based on the synergistic impact of the two materials. The sp^3–hybridized C–N and Al_2O_3 are remarkable not only for the gradual deterioration of the DLC film in corrosive solutions, but also for the suppression of the DLC film degradation at high temperatures, and they are effective in preventing DLC films from corroding in water. However, there are drawbacks to preventing the DLC films' deterioration at high temperatures (Wongpanya, Silawong, & Photongkam, 2021), but the creation of a single bond sp^3–hybridized C–N structure might inhibit the process. At high temperatures, the film becomes graphitized; while it is not quite up to par in terms of corrosion resistance, Fe 2*p* confirmed that the DLC film had deteriorated. A wide range of Fe (metal and compound) XPS measurements were made, including Fe (II) (Fe_2O_3, Fe_3O_4), Fe (III) (Fe_2O_3, Fe_3O_4), and Fe (III) (FeOOH) at roughly 707.0, 709.6, 710.8, and 711.8 eV, respectively (Fredriksson *et al.*, 2012; Guo *et al.*, 2014). Degradation of all the DLC films occurred until the metal (Fe) surface was found. The oxidation of Fe into Fe^{2+} ions generates oxides of Fe (II), which are further oxidized to create oxides of Fe (III) (Jones, 1996) in a corrosive environment rich in water and oxygen. All films included a combination of Fe (II) and Fe (III) molecules. The Fe (II)/Fe (III) ratio is used to measure the stability of Fe oxides, and it is graded as follows: deterioration of the DLC film structure may be seen in the decrease in ta–C:Al:N < ta–C:Al < ta–C:N. This investigation confirmed the interaction between the O and C or metals (Al and Fe in this work) during corrosion, as well as the O 1*s* measurement findings in the XPS and peaks compatible with Al and/or Fe oxides (O^{2-}) at around 530.3 eV. In Konkhunthot *et al.*, 2019, Wongpanya, Pintitraratibodee,

Thumanu, & Euaruksakul, 2021, Wang *et al.*, 2001, Hanawa *et al.*, 2002, and Marcelin *et al.*, 2013, the N–O/O=C–OH bonds and the C–O, C–OH, and C=O at 530.50 eV and 532.0–533.4 eV peaks which existed before corrosion (Konkhunthot *et al.*, 2019; Jiménez *et al.*, 2001) resembled what was discovered. A combination of X–PEEM and NEXAFS was used to investigate the effects of corrosion on the structural bonding of the DLC films in various locations, including the mildly corroded zone (Area 1) and the severely corroded zone (Area 2), as seen in **Figure 4.17**. The NEXAFS C *K*–edge spectra for all the DLC films in **Figure 4.17** show distinct characteristics for Area 1 and Area 2. According to Area 2, it is clear that the C 1*s* transition to the unoccupied π^* and σ^* states at the sp^2–hybridized site was detected by the peaks at 285.4 and 292.0 eV, respectively (Konkhunthot *et al.*, 2019; Wongpanya, Silawong, & Photongkam, 2021; Soin *et al.*, 2012). Due to severe corrosion, the sp^2–hybridized bond percentage of all the DLC films before corrosion in **Figure 4.5** rose from 0.345, 0.394, 0.538, and 0.348 for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N, respectively, to 1.00. However, in Area 1 these transitions, notably at 292.0 eV, were almost undetectable owing to the minor rise in the sp^2–hybridized bond fraction to 0.491 for ta–C, 0.615 for ta–C:Al, 0.455 for ta–C:Al, and 0.640 for ta–C:N, due to mild corrosion. The graphitization of the DLC films due to corrosion can be seen in these data, which are in agreement with the XPS results.

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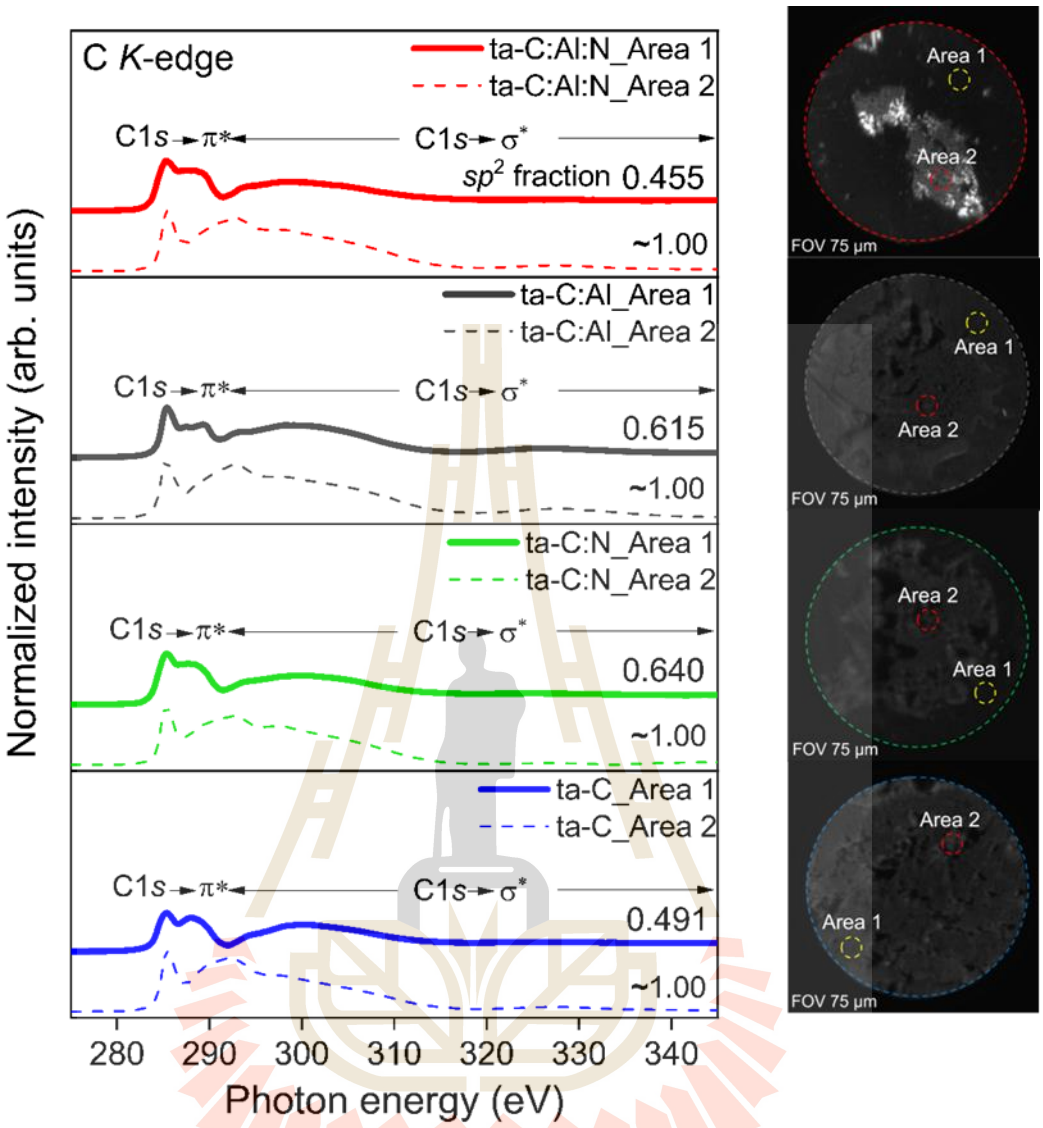


Figure 4.17 The C *K*–edge NEXAFS spectra generated for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N after the corrosion tests (Wongpanya *et al.*, 2022)

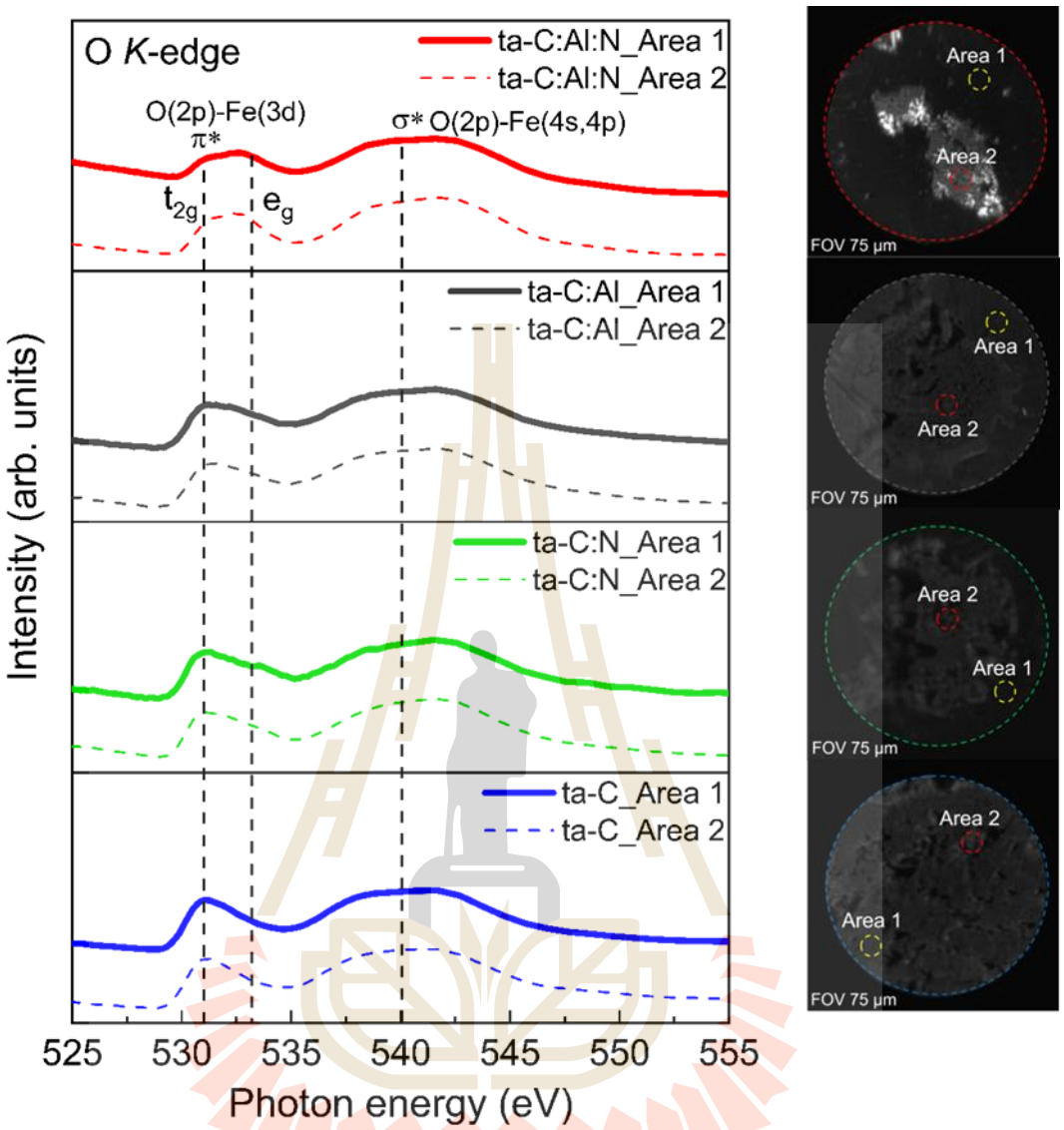


Figure 4.18 The O *K*–edge NEXAFS spectra generated for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N after the corrosion tests (Wongpanya *et al.*, 2022)

Although the NEXAFS O *K*–edge spectra (**Figure 4.18**) of all the DLC films before corrosion were comparable, extra strong peaks at ~533.0 and 540.0 eV, which correspond to O 2*p* hybridization with 3*d* and 4*s* and 4*p* metals, respectively, were seen. Area 1 and Area 2 DLC films had similar O *K*–edge spectra before corrosion, however, the increased predominant peaks at ~533.0 and 540.0 eV, which correspond to O 2*p* had become hybridized with 3*d*, 4*s*, and 4*p* metals, respectively, including the O 1*s* ⟶ **σ*** (C–O and C=O) transitions (at 540.0 eV), clearly indicating the degradation

of the DLC films and the evolution of Fe oxides from corrosion, respectively (de Groot *et al.*, 1989; Kim *et al.*, 2018).

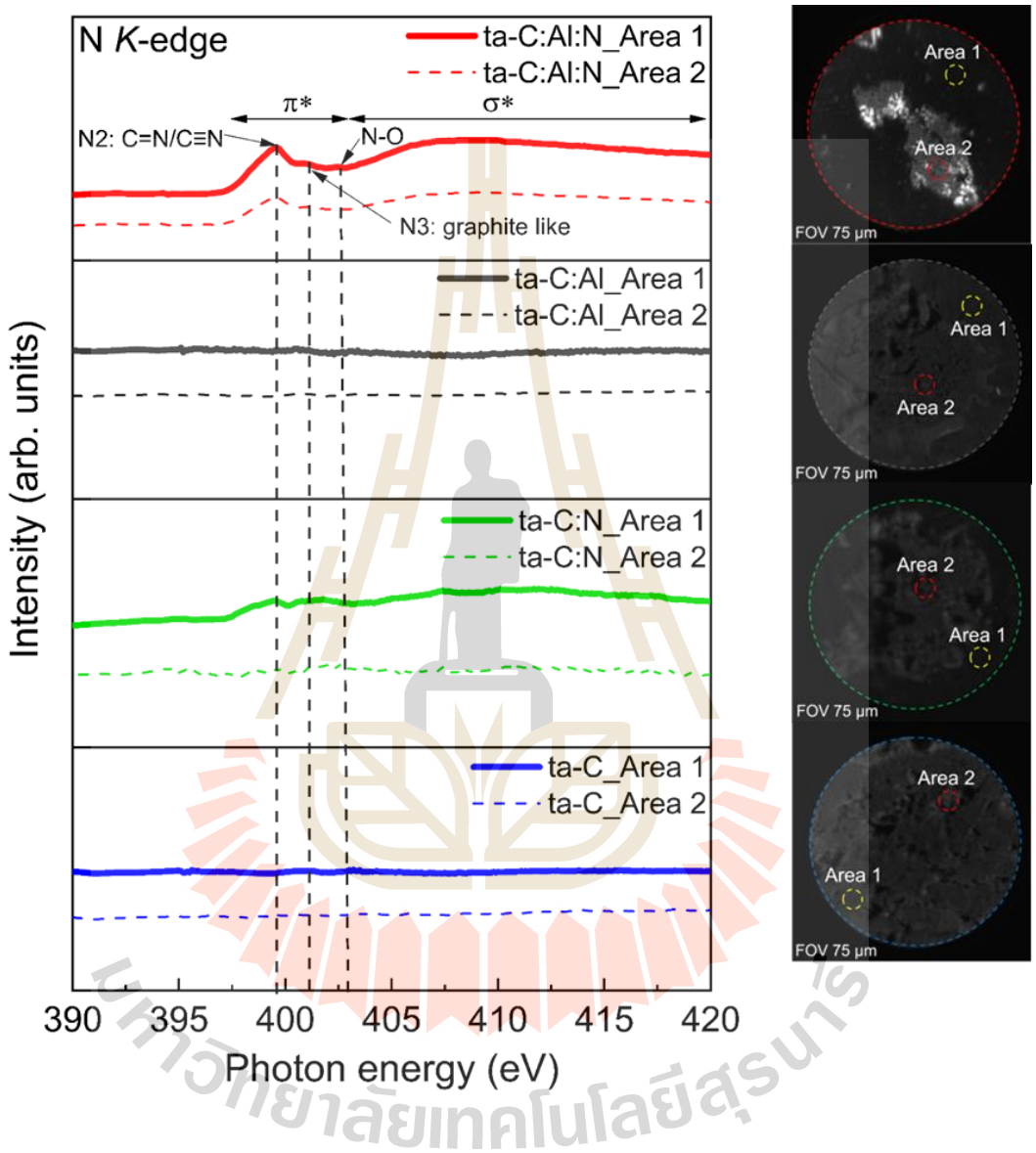


Figure 4.19 The N *K*–edge NEXAFS spectra generated for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N after the corrosion tests (Wongpanya *et al.*, 2022)

Following the corrosion tests, all the specimens' N *K*–edge NEXAFS spectra (**Figure 4.19**) were analyzed. The ta–C:Al:N specimen, which has N2, N3, and N—O peaks at around 399.5, 401.5–402.4, and 403.2 eV, respectively, demonstrates the

N *K*–edge NEXAFS spectral features. In the Area 1 spectral peak, the ta–C:N specimen contains a C=N bond and/or a C≡N bond, graphite–like molecules, and nitrogen molecules (Iyer and Maguire, 2011; Roy *et al.*, 2005). The spectrum is obscured and undetectable in Area 2 due to significant corrosion on the material. The N *K*–edge NEXAFS spectrum was not identified in the ta–C or ta–C:AI specimens, which is consistent with the absence of N—O before the corrosion tests in the elemental doped materials. The specimens may be exposed to air or natural contaminants after the corrosion test, which reacts with the coating layer. In circumstances when a post–test NEXAFS analysis is necessary, the surface cannot be cleaned using the sputtering technique before testing. This is because it prevents corrosion products or the corroded film layer from being removed, which may result in inaccurate results.

Fe (metal), Fe (II) (FeO and Fe_3O_4), and Fe (III) (Fe_2O_3, Fe_3O_4, and FeOOH), respectively, were found in the NEXAFS Fe $L_{3,2}$–edge spectra for all the DLC films at 708, 710.1, and 711 eV (Leveneur *et al.*, 2011; Everett *et al.*, 2014). Fe metal, Fe (II), and Fe (III) were detected in all the DLC layers following corrosion (III), except for ta–C:Al:N, which correlates to the XPS findings; the Fe (II) peak was much more intense than the Fe (III) peak, particularly for ta–C, ta–C:N, and ta–C:Al.

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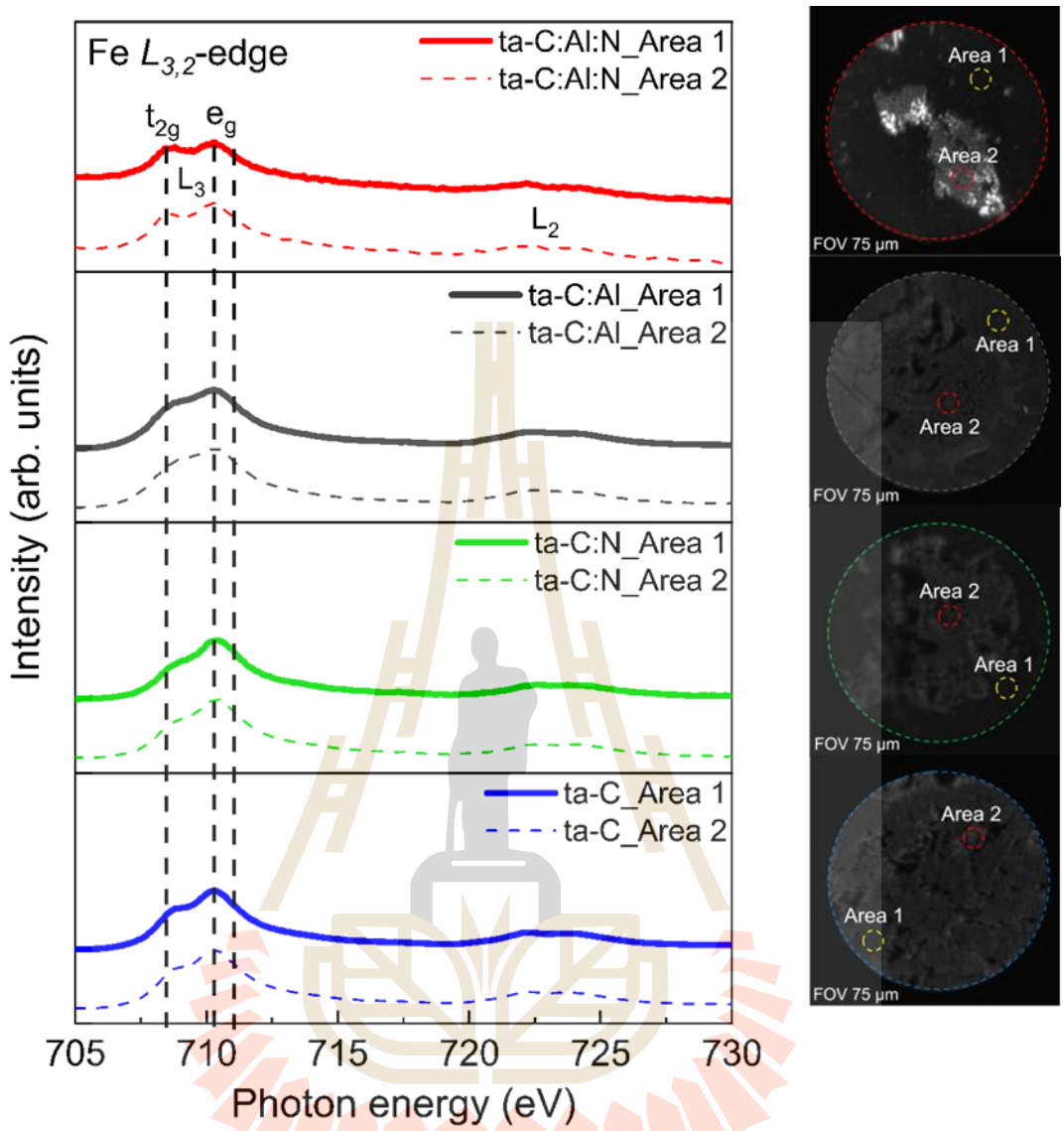


Figure 4.20 The Fe $L_{3,2}$–edge NEXAFS spectra generated for ta–C, ta–C:N, ta–C:Al, and ta–C:Al:N after the corrosion tests (Wongpanya *et al.*, 2022)

Following the corrosion tests, structural analysis using XPS and NEXAFS was performed, as shown, and the discussed results are presented section 4.2.4. When all the AISI 4140 steel specimens and specimens coated with the DLC film layer were evaluated for corrosion in 3.5 wt% NaCl solution, the surfaces were analyzed using SEM, as shown in **Figure 4.21**. Corrosion surface damage was observed to be greater in the AISI 4140 steel than in the DLC film layers. The appearances of the corrosion surfaces indicate that the corrosion behavior of AISI 4140 is general corrosion. For the DLC coating, the appearance of cracks in the film, delamination, and corrosion at certain spots may be due to a defect or droplet, including cracks in the film layer owing to the high film stress or the ability to have low adhesion between the DLC films and the substrate material. When the solution passes through the film layer, it causes severe corrosion with behavior comparable to crevice corrosion or localized corrosion. The DLC coatings and substrate materials have different chemical compositions that are not all equally resistant to corrosion, and it can be said that between these areas, there are different electrochemical potentials. Whereas the substrate material has a lower electrochemical potential than the DLC films and, thus, the substrate material loses its electrons, the DLC films act as an electron acceptor. This is known as galvanic corrosion. The severity of this form of corrosion is determined by the difference in electrochemical potential. The larger the difference, the greater the degree of corrosion. As a result, specimens with the DLC coating are prone to surface degradation, and there was such a severe loss of metal that some film sites ruptured and collapsed following corrosion, as shown in the SEM images, consistent with the research by Liu *et al*. (2006).

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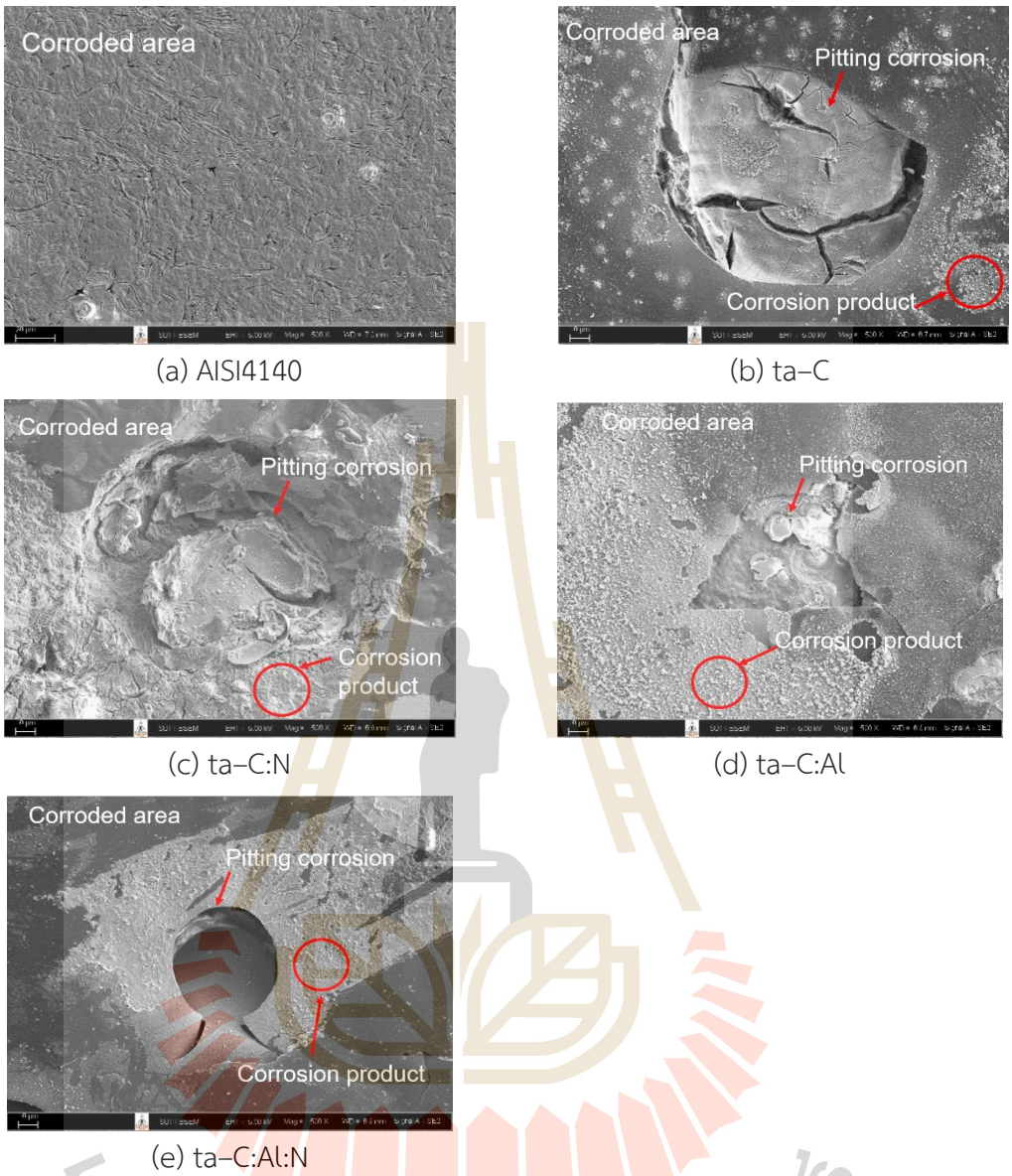


Figure 4.21 Surface appearance of specimens after corrosion testing: (a) AISI4140, (b) ta–C, (c) ta–C:N, (d) ta–C:Al, and (e) ta–C:Al:N, respectively, at 500X

For AISI 4140 steel contacted to a 3.5 wt% NaCl (pH ~6.6) solution, a significant amount of hydroxyl [OH^-] ion was dissolved as a consequence of the NaCl solution dissociating, resulting in surface corrosion. For the portion of the surface that comes into contact with the solution, corrosion will develop regularly across the surface. This is often seen in metals when a protective coating cannot develop quickly enough, resulting in extensive corrosion and significant surface damage. To begin, the

oxidation processes that result in the formation of iron ions during corrosion are shown in Equation (4.6) below. When the solution is exposed to air or includes oxygen and water vapor, it begins to decompose. When iron ions react quickly with [OH^-], Equation (4.7) below, ferrous hydroxide is formed and precipitates on the surface, as shown in Equation (4.8) below, and when ferrous hydroxide reacts with oxygen, ferric oxide or hematite compounds are formed. When the very stable oxide coating (Fe_2O_3) on the steel surface interacts with water, only iron rust in the form of Fe_2O_3 remains, which has a reddish–brown color, as in Equation (4.9) below. As a consequence of the dissolved oxygen in the solution forming water molecules, as shown in Equation (4.10) below, the corrosion process continues. All of these processes, starting with Equations (4.6) through (4.10), regulate the corrosion of AISI4140 steel (Datta *et al*., 2021).

$$Fe_{(s)} \longrightarrow Fe^{2+}_{(aq)} + 2e^- \quad (4.6)$$

$$O_2 + 2H_2O + 4e^- \longrightarrow 4OH^-_{(aq)} \quad (4.7)$$

$$Fe^{2+}_{(aq)} + 4OH^- \longrightarrow 2Fe(OH)_{2\,(s)} \quad (4.8)$$

$$2Fe(OH)_{2\,(s)} + (1/2)O_{2\,(g)} \longrightarrow Fe_2O_3{\cdot}3H_2O_{(s)} + H_2O_{(l)} \quad (4.9)$$

$$O_{2\,(g)} + 4H^+_{(aq)} + e^- \longrightarrow 2H_2O \quad (4.10)$$

Moreover, iron oxide deposits (FeOOH, Fe_2O_3, Fe_3O_4) on the substrate affect these these surface film formation processes. The cathodic and anodic reactions, Equations (4.6) and (4.7), may occur underneath the FeOOH and Fe_3O_4–covered specimens. The following reactions took place on the steel substrate while the FeOOH deposit was present (Kim and Kim, 2017). Increases in the FeOOH reduction process necessitate a higher concentration of Fe^{2+} ions, thereby enhancing the solubility of the anode described in Equation (4.6). Under deposition of FeOOH, these reactions may result in the production of Fe_3O_4, as shown in Equations (4.11) and (4.12):

$$2FeOOH + Fe^{2+}_{(aq)} \longrightarrow Fe_3O_4 + 2H^+ \quad (4.11)$$

$$Fe^{2+} + 8FeOOH + 2e^- \longrightarrow 3Fe_3O_4 + 4H_2O \quad (4.12)$$

Corrosion of the whole DLC film layer occurs when the film layer is dissolved and ionized in the electrolyte solution upon contact with the 3.5 wt% NaCl solution. The reaction produces electrons that flow through the film's lowest resistance area to the cathodic reaction zone. Thus, the most significant reactions occur when the liberated electrons reduce the dissolved oxygen, water molecules, and hydrogen ions in the electrolyte, where O^{2-} denotes oxygen in its reduced state as H_2O, OH^-, and/or Me–O (Khun *et al.*, 2009; Elam *et al.*, 2021). As a result, for the film electrochemical reaction, DLC follows Equations (4.13) to (4.18).

$$2H^+ + 2e^- \longrightarrow H_2 \quad (4.13)$$

$$2H_2O + 2e^- \longrightarrow H_{2(g)} + 2OH^- \quad (4.14)$$

$$2H_2O + O_2 + 4e^- \longrightarrow 4OH^- \quad (4.15)$$

$$C + 6OH^- \longrightarrow CO_3^{2-} + 3H_2O + 4e^- \quad (4.16)$$

$$C + (O^{2-}) \longrightarrow CO + 2e^- \quad (4.17)$$

$$CO + (O^{2-}) \longrightarrow CO_2 + 2e^- \quad (4.18)$$

Similarly, the reaction occurs in the nitrogen–doped DLC film. This is because nitrogen, doped in the film's layer, is capable of dissolving and forming a bond with the film's carbon. The dissolving and ionization of the film layer in the electrolyte solution are induced by the conversion of sp^3 to the sp^2 structure (Khun *et al.*, 2009), which indicates whether the film layer has degraded or generated

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graphitization during corrosion. When the aluminium–doped film layer in the DLC film comes into contact with a 3.5 wt% NaCl solution, both anodic and cathodic reaction corrosion of the aluminium occurs. This results in an increase in the solubility of the aluminium and a decrease in dissolved oxygen. Finally, the aluminium hydroxide, $Al(OH)_{3(ads)}$ (Singh *et al*., 2014), then develops a transformation to aluminium oxide as demonstrated in Equations (4.19) to (4.22):

$$Al_{(ads)} \longrightarrow Al^{3+} + 3e^{-} \tag{4.19}$$

$$(1/2)O_2 + 2H_2O + 3e^{-} \longrightarrow 3OH^{-} + (1/2)H_2 \tag{4.20}$$

$$Al^{3+} + 3OH^{-} \longrightarrow Al(OH)_{3\,(ads)} \tag{4.21}$$

$$2Al(OH)_{3\,(ads)} \longrightarrow Al_2O_3 \cdot 3H_2O \tag{4.22}$$

For the Al–doped and Al and N co–doped DLC, the corrosion resistance is provided by the Al_2O_3 that develops on the workpiece's surface. Because it is a very chemically inert compound in an aquatic environment, as long as oxygen is available, this Al_2O_3 oxide develops with an increased thickness. If a fault arises, this oxide will return to its initial condition. However, in a 3.5 wt% NaCl solution, breakdown of the passive film occurs, and repairs to it are hampered because of the strong environmental corrosion (Singh *et al*., 2014).

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CHAPTER 5

CONCLUSION AND SUGGESTIONS

5.1 Conclusion

As stated in Chapter 4, the qualities of the synthesized film were evaluated before and after the tests for mechanical properties, thermal stability, and corrosion resistance, which can be summarized in the thesis as follows:

5.1.1 The optimal conditions for all DLC films on the AISI4140 substrate by FCVA deposition are:

- V_{arc} of C is 800V and V_{arc} of Al is 400V.
- V_{bias} of the sample is -1000V.
- Duty cycle and Frequency are 0.003% and 6.0 Hz, respectively.
- Base pressure is 8.5×10^{-4} Pa.
- UHP N_2 flow rate is 2.5 SCCM for ta-C:N and ta-C:Al:N, respectively.

5.1.2 In the thermal stability test using in-situ NEXAFS spectroscopy, the heat resistance of Al-N co-doped film was up to 600°C because the sp^3 C–N and Al_2O_3 bonding in the film promoted the thermal stability of the film. The maximum temperature resistances of the Al-doped, N-doped, and pure DLC are RT, 280, and 400°C, respectively (the sp^2 fraction of up to 0.50).

5.1.3 The nanomechanical properties, adhesion strength, and corrosion resistance of all DLC films are:

5.1.3.1 The nanomechanical properties of the DLC films with N doping and Al–N co–doping dropped slightly when compared to the pure DLC, while the Al–doped films decreased considerably. Reduced *H* and *E* correspond with higher I_D/I_G, whereas L_a is related to an increase in the concentration of sp^2–hybridized carbon bonds and a decrease in sp^3/sp^2. The quantity of sp^3–hybridized carbon bonds in the film significantly affects the nanomechanical characteristics.

5.1.3.2 The adhesion strength of all DLC films, as the dopant concentration was raised, the elastic recovery of the DLC films decreased. When the

undoped DLC film (ta–C) is doped with Al and Al–N, a rising L_{c2} is seen. This decreases internal stress and increases the size of the graphite clusters at the sp^2 sites (L_a). This phenomenon results in a large proportion of sp^3–hybridized C–N bonds in ta–C:N and Al_2O_3 in ta–C:Al and ta–C:Al:N. These films (ta–C:Al:N > ta–C:N > ta–C:Al > ta–C) had CPRs of 12187.06, 9114.59, 8750.99, and 8697.89 mN^2, respectively, with ta–C:Al:N having the highest toughness and adhesion strength.

5.1.3.3 All DLC coatings improved corrosion resistance while decreasing i_{corr} and CR as compared to the AISI 4140 steel. The i_{corr} and CR values for all DLC films were identical. E_{corr} shifted from –443.31 to –442.69 mV for ta–C and ta–C:N, and –425.08 to –382.93 mV for ta–C:Al and ta–C:Al:N, respectively. DLC films with Al–doped and Al–N–co–doped are marginally more stable than pure DLC and DLC with N–doped. Due to the synergy of Al oxide and sp^3 C – N bonds in the DLC films (referred to in the XPS result), ta–C:Al and ta–C:Al:N are also exceptionally resistant to corrosion (the second and highest, respectively). The high R_p (3890.89 and 4237.02 cm^2) and high P_i (77.77 and 79.22 %), as well as the low P, demonstrate this ($2.09x10^{-4}$ and $3.49x10^{-5}$), respectively. Because of co–doping DLC, the DLC film additives, including Al and N, preserve both remarkable nanomechanical characteristics and great thermal stability. Along with its excellent corrosion resistance and strong adhesion strength, the Al–N co–doped DLC is very attractive and is ideal as an alternative for surface coating applications to be utilized in wear and tribological applications, particularly at high temperatures or in corrosive environments.

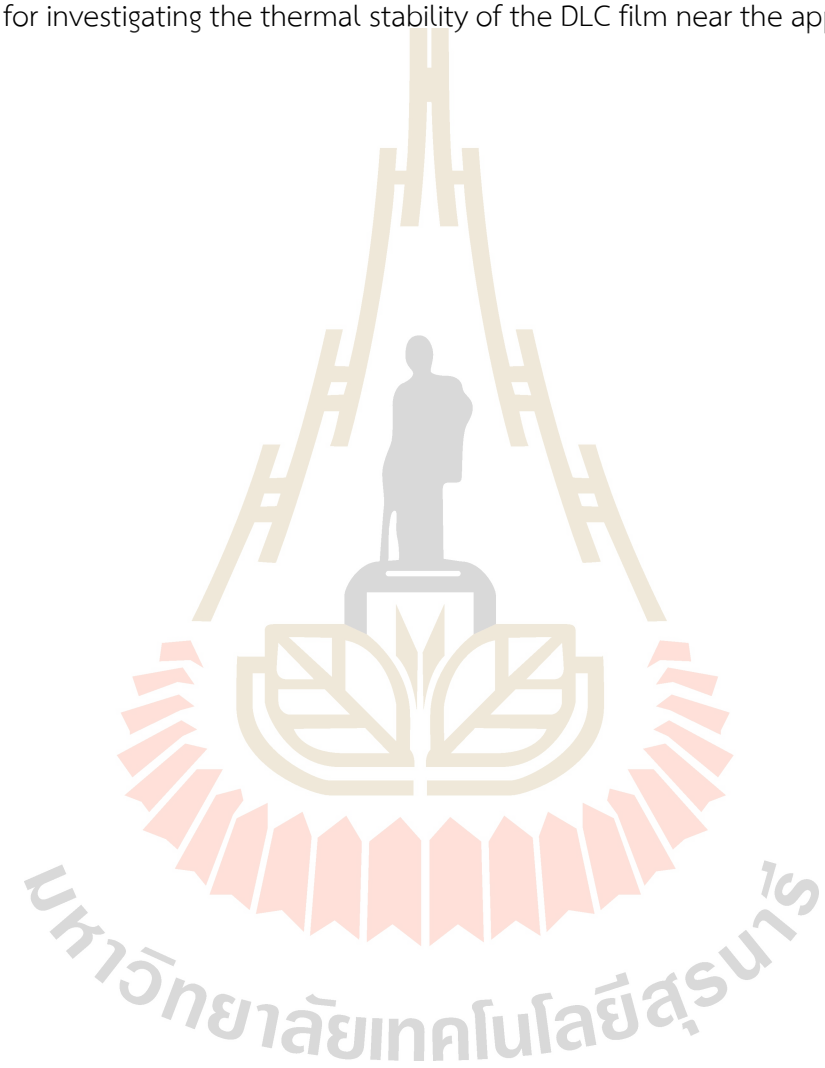
5.2 Suggestions

The nanoscale mechanical characteristics, film adhesion, oxidation resistance, and corrosion resistance of AISI 4140 steel coated with non–doped, N–doped, Al–doped, and co–doped Al–N diamond–like carbon films by the FCVA process should be investigated. As seen in the preceding chapter, this Ph.D. thesis includes research and experimentation. It is anticipated that the information gathered in this research will be beneficial and can contribute significantly to the advancement of knowledge useful for future development or practical application. As a result, more research should be conducted under that section on particular facets. As a result, the following

suggestions are given for further research:

5.2.1 Experiments should be conducted to determine the appropriate quantities of aluminium alloy and nitrogen and to investigate or measure the Al that may react with N to produce an AlN layer in the film layer.

5.2.2 The thermal annealing should be cyclically tested in the range of RT to 700 ℃ for investigating the thermal stability of the DLC film near the applied condition.



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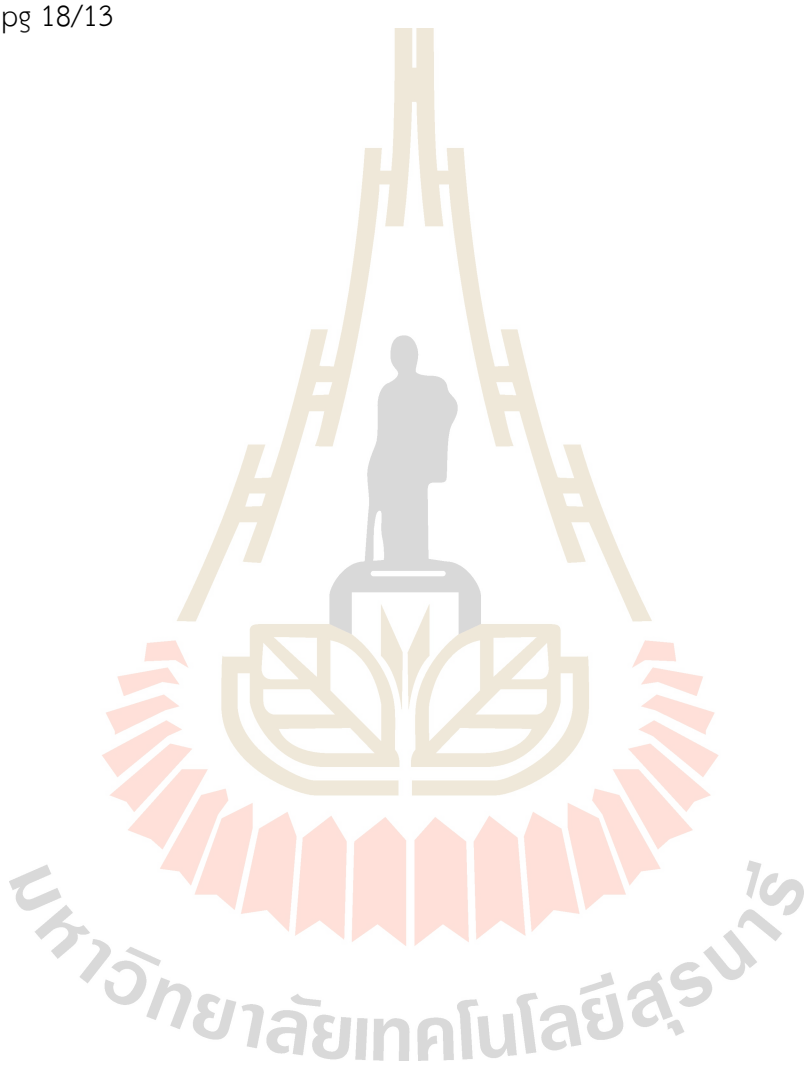
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APPENDIX A

THE XPS SPECTRA OF BEFORE AND AFTER CORROSION TESTING

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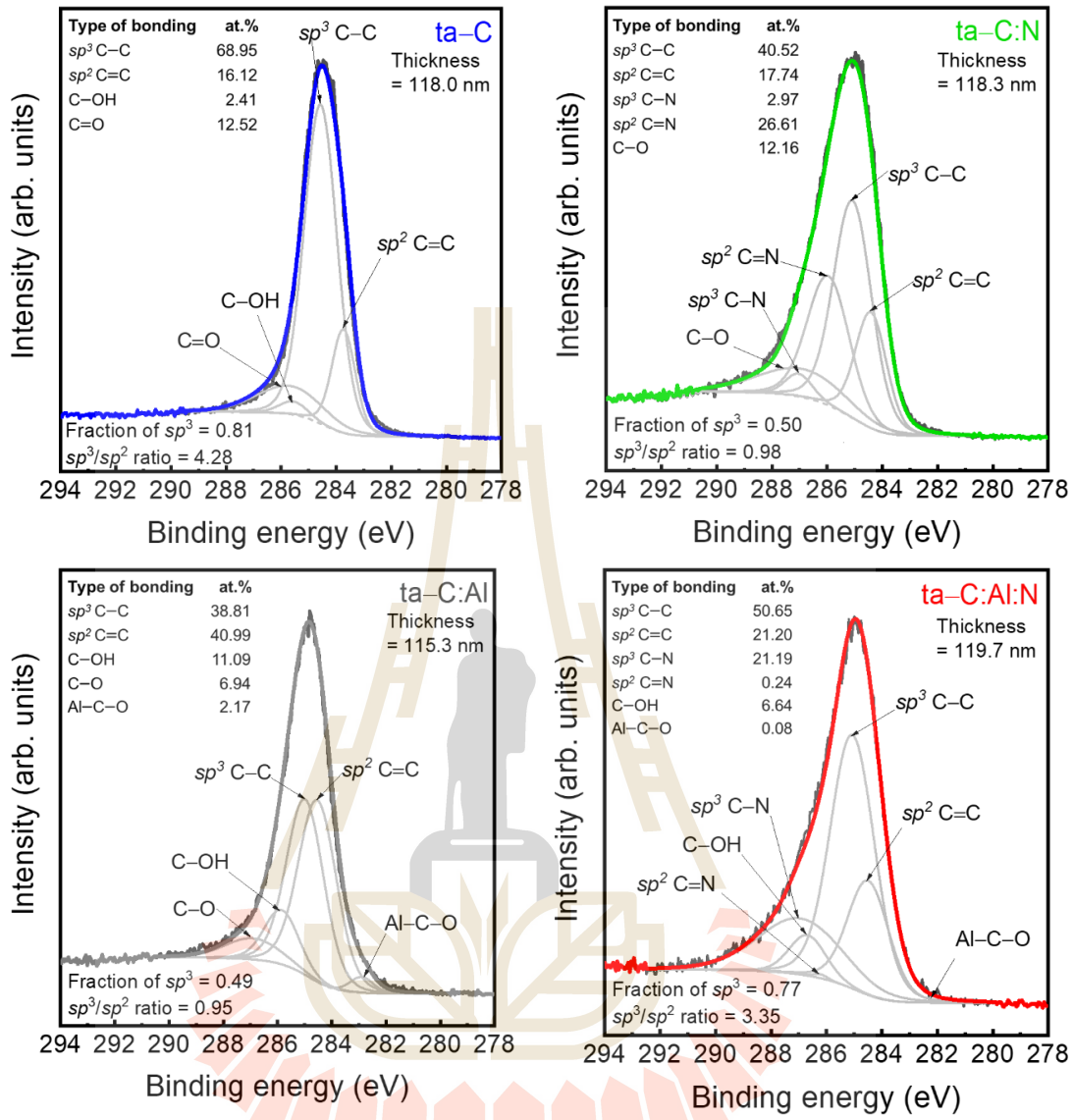


Figure A1. The C 1*s* XPS spectra and the corresponding deconvoluted Gaussian peaks of the films before the corrosion tests (Wongpanya *et al.*, 2022)

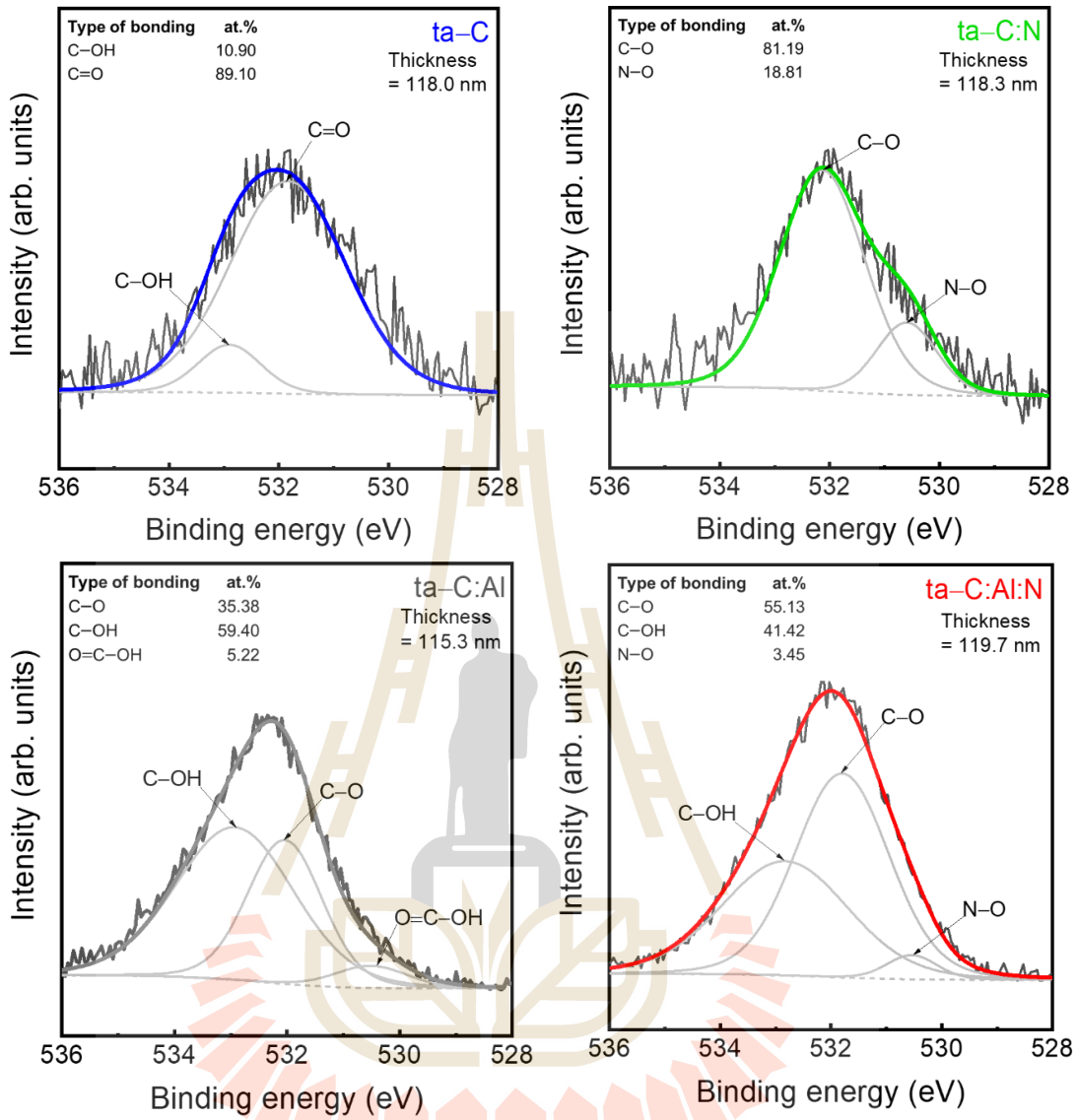


Figure A2. The O 1*s* XPS spectra and the corresponding deconvoluted Gaussian peaks of the films before the corrosion tests (Wongpanya *et al.*, 2022)

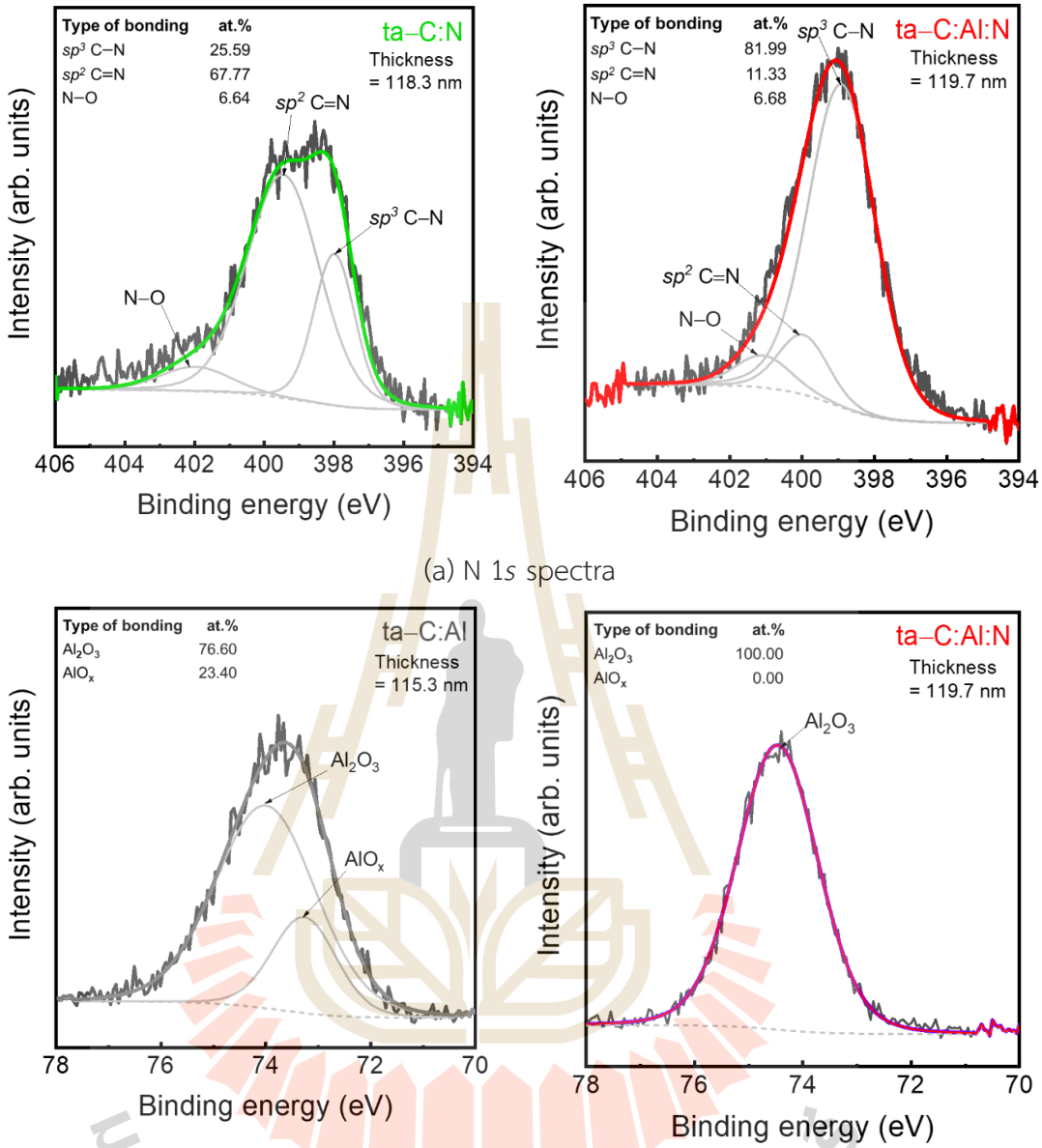


Figure A3. XPS spectra and the corresponding deconvoluted Gaussian peaks of the films before the corrosion tests: (a) N 1*s*, and (b) Al 2*p* (Wongpanya *et al.*, 2022)

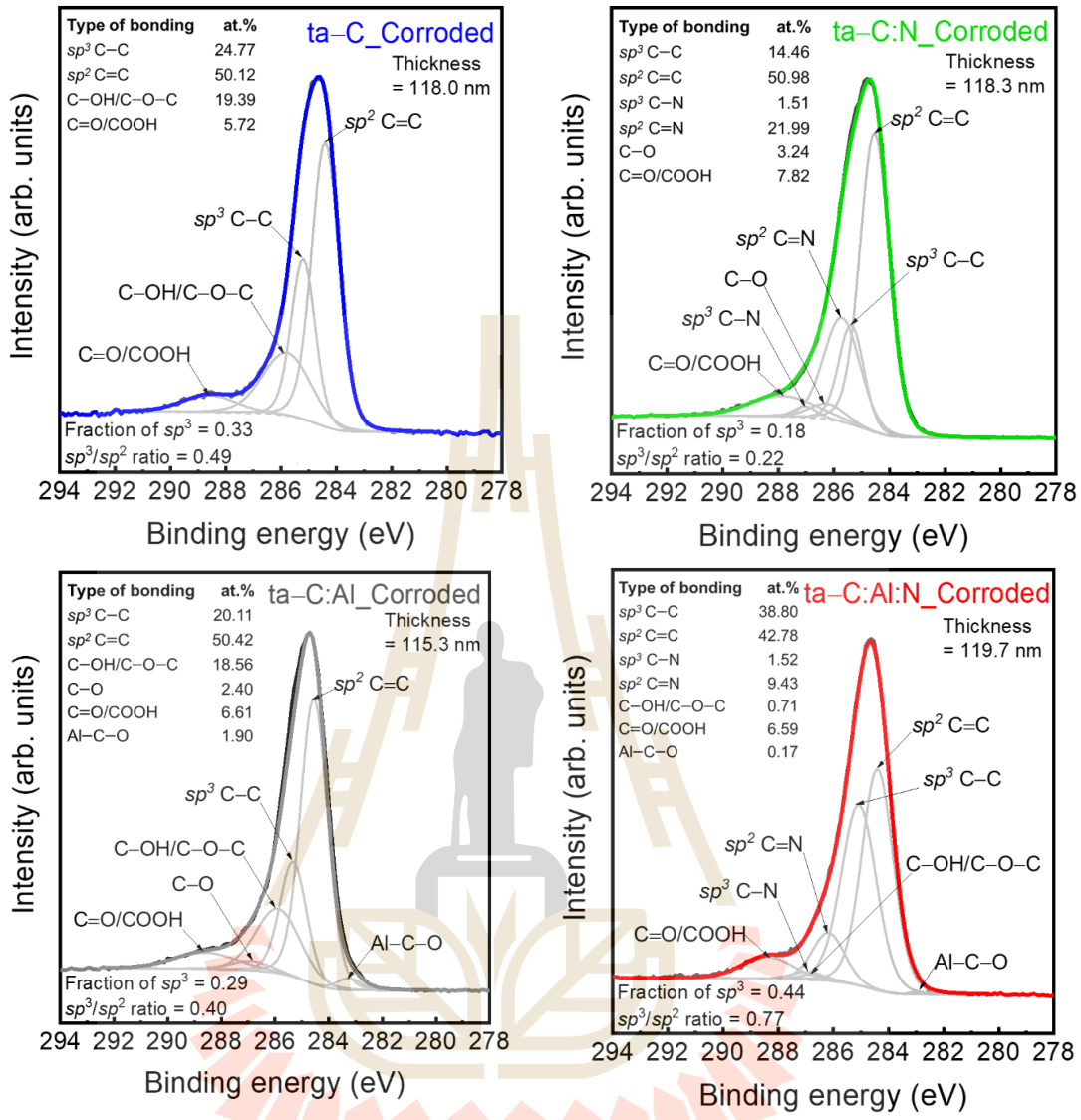


Figure A4. The C 1*s* XPS spectra and the corresponding deconvoluted Gaussian peaks of the films after the corrosion tests (Wongpanya *et al.*, 2022)

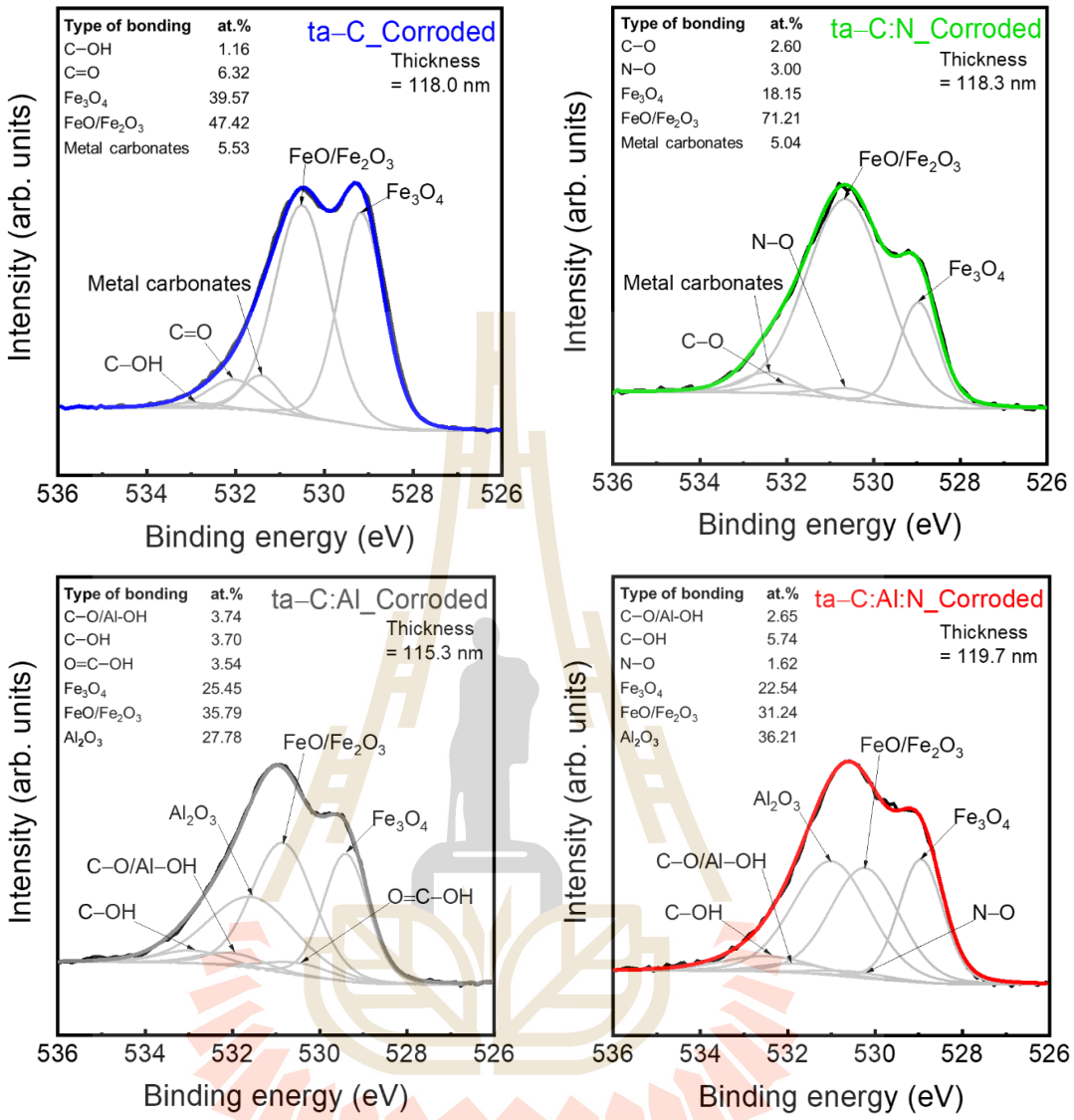


Figure A5. The O 1*s* XPS spectra and the corresponding deconvoluted Gaussian peaks of the films after the corrosion tests (Wongpanya *et al.*, 2022)

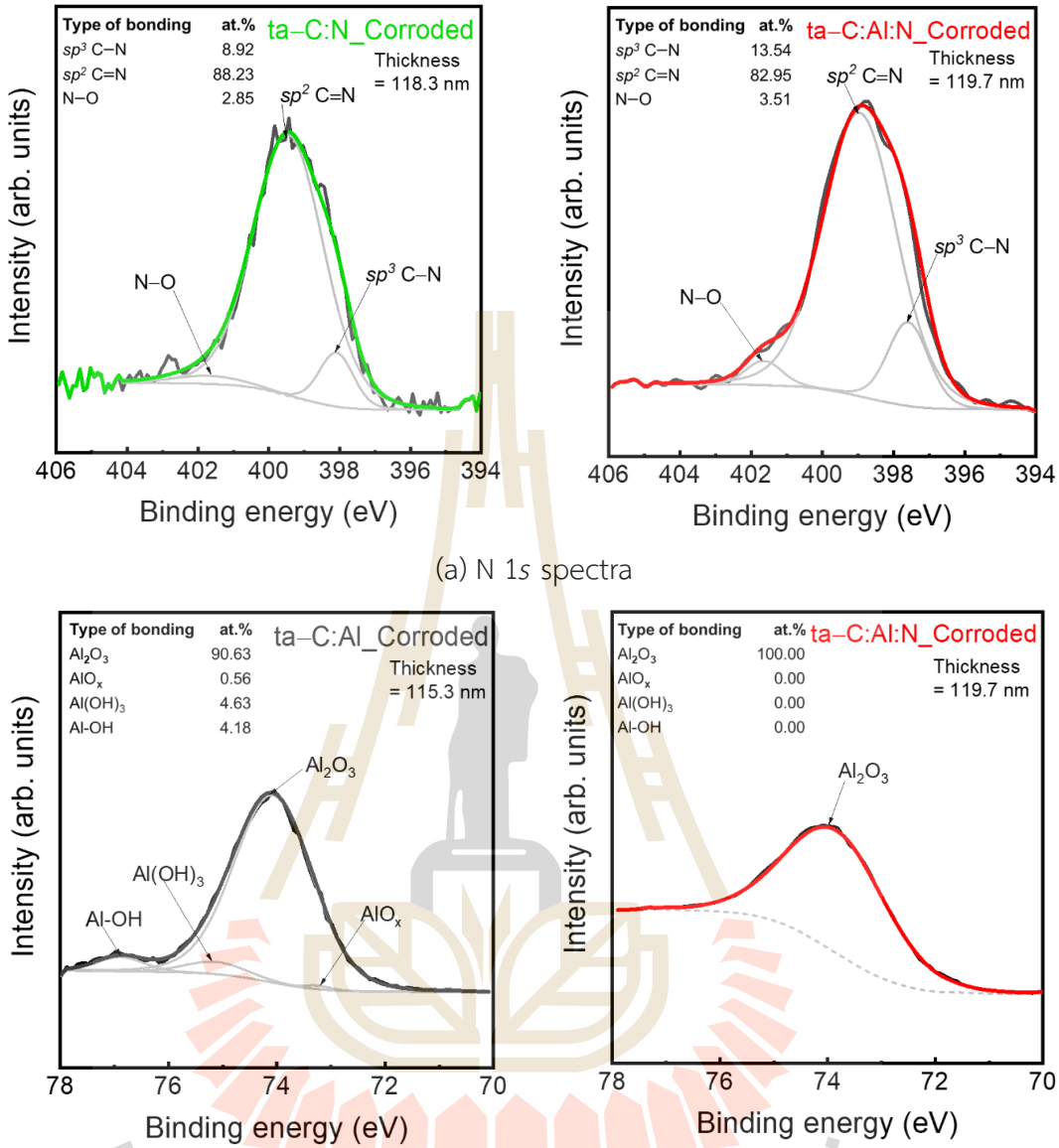


Figure A6. XPS spectra and the corresponding deconvoluted Gaussian peaks of the films after the corrosion tests: (a) N 1*s*, and (b) Al 2*p* (Wongpanya *et al.*, 2022)

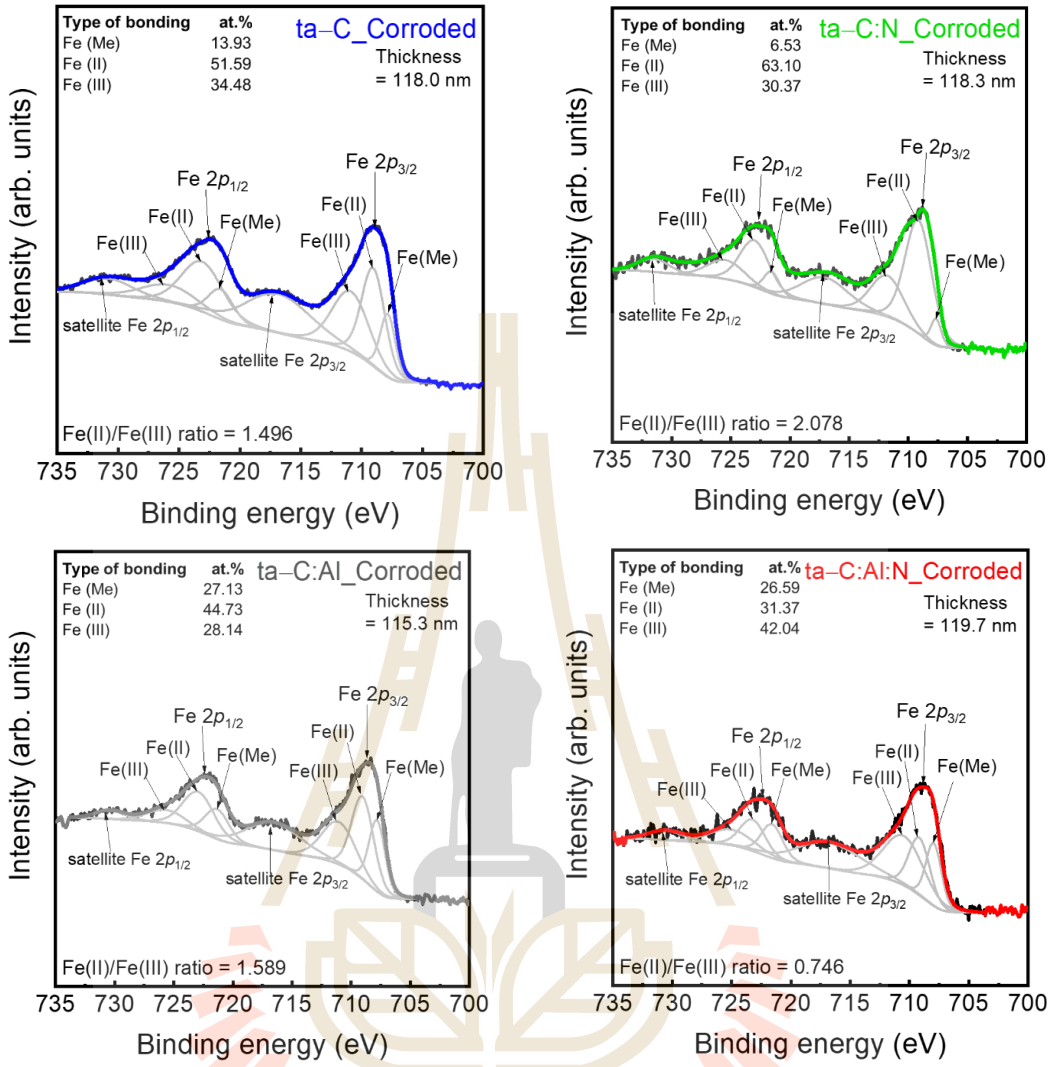


Figure A7. The Fe 2*p* XPS spectra and the corresponding deconvoluted Gaussian peaks of the films after the corrosion tests (Wongpanya *et al.*, 2022)

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APPENDIX B

PUBLICATION

มหาวิทยาลัยเทคโนโลยีสุรนารี

List Of Publication

Wongpanya, P., Silawong, P., & Photongkam, P. (2021). Nanomechanical properties and thermal stability of al–n-co-doped dlc films prepared by filtered cathodic vacuum arc deposition. **Surface and Coatings Technology**, 424, 127655. doi.org/10.1016/j.surfcoat.2021.127655

Wongpanya, P., Silawong, P., & Photongkam, P. (2022). Adhesion and corrosion of diamond–like carbon films with Al–N–co–doping prepared by filtered cathodic vacuum arc deposition, **Ceramics International**, 48, 20743-20759. doi.org/10.1016/j.ceramint.2022.04.055

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Wongpanya, P., Silawong, P., & Photongkam, P. (2021). Nanomechanical properties and thermal stability of al–n-co-doped dlc films prepared by filtered cathodic vacuum arc deposition. **Surface and Coatings Technology**, 424, 127655. doi.org/10.1016/j.surfcoat.2021.127655

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Nanomechanical properties and thermal stability of Al–N-co-doped DLC films prepared by filtered cathodic vacuum arc deposition

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ABSTRACT

Al and N were incorporated into diamond-like carbon (DLC) films deposited using a filtered cathodic vacuum arc on AISI 4140 low-alloy steel. The structure, nanomechanical properties, local bonding, and thermal stability of non-doped DLC (ta-C), Al- and N-doped (ta-C:Al and ta-C:N), and Al- and N-co-doped (ta-C:Al:N) films were thoroughly investigated. The thermal stability of the deposited films was measured using radiative heating and electron beam bombardment under a vacuum during thermal annealing. In-situ near-edge X-ray absorption fine structure spectroscopy was performed to characterize the surface nanostructures at different temperatures. ta-C:Al:N exhibited not only high hardness (49.04 GPa) and high (58.43%) elastic recovery (*ER*)—approximately equal to those of non-doped DLC films: 51.12 GPa and 60.06% *ER*, respectively)—but also higher thermal stability than ta-C at ~600 °C owing to the synergy of Al_2O_3 and sp^3 N-C bonds formed in the DLC films, as confirmed by X-ray photoelectron spectroscopy. ta-C:Al:N, therefore, is a suitable coating for wear and tribological applications, especially at high temperatures.

1. Introduction

AISI 4140 low-alloy carbon steel is widely used in engineering applications—especially in automotive parts—owing to its reasonable price, superior mechanical properties (strength, hardness, and ductility), and formability. The wear and corrosion resistance of AISI 4140 steel is enhanced by conventional thermal annealing and surface treatments such as quenching and tempering, carburizing, nitriding, nitrocarburizing, and plasma nitriding [1–4]. Automotive parts degrade mainly owing to exposure to humidity, chemical substances, friction, and temperature [2,5]. Although conventional thermal annealing and surface treatments have been developed continuously for four decades and have been extensively used to prevent steel-surface wear, corrosion, and oxidation [6–9], such treated steels might be unsuitable for application at high temperatures, which degrade mechanical properties and destabilize microstructures. To avoid such problems and enhance steel lifetimes, hard films such as CrN, TiC, TiN, TiCN, TiAlN, and diamond-like carbon (DLC) have been increasingly applied to machines, tools, and automobiles [10–14]. Owing to their outstanding mechanical and chemical properties including high hardness, low friction, wear resistance, chemical inertness, and thermal stability, DLC films are an attractive choice for engineering applications—especially automotive ones in which exposure to high temperatures, oxidation, corrosion, tribology, and wear all degrade metal surfaces. The prominent DLC mechanical and chemical properties originate from the amorphous DLC structure, which exhibits both diamond (sp^3 tetrahedral hybridized) and graphite (sp^2 trigonal hybridized) bonding [12–14]. The essential methods of synthesizing DLC films are ion deposition, sputtering, plasma deposition, pulsed laser deposition, and cathodic vacuum arc deposition [15–18].

Although cathodic vacuum arcs have been widely used to deposit DLC films, macroparticles usually form during arc deposition, thereby diminishing the quality of synthesized DLC films. A magnetic-filtered coil is usually employed to eliminate the macroparticles, and the resulting technique is known as filtered cathodic vacuum arc (FCVA) deposition [19–21], which can synthesize an sp^3-bond-rich DLC film in which 80–90% of the bonds are sp^3 tetrahedral hybridized [15,19–23]. However, the challenge facing DLC films is the high internal stress that increases with increasing film thickness. In addition, decreasing the DLC-film sp^3/sp^2 ratio at high temperatures, called graphitization, results in low hardness. To avoid degrading DLC properties, nonmetallic and metallic elements (including N, Si, Ti, Al, Cu, W, Cr, Ni, and Ag) have been incorporated into DLC structures to enhance adhesion,

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friction coefficient, corrosion resistance, and thermal stability properties; however, this practice also decreases the sp^3-tetrahedral-hybridized carbon content in DLC films because dopants increase the fraction of sp^2-hybridized carbon bonds/atoms [24–26]. Because each dopant affects the DLC-film bonding structure and properties differently, co-dopants—especially nitrogen (N) and aluminum (Al)—are attractive for rectifying both the high internal stress and low adhesion of DLC films [27–29]. Although nitrogen notably improves the adhesion of synthesized tetrahedral amorphous carbon (ta-C) DLC films by approximately 20–90%, it reduces the hardness by approximately 2–10% [27]. Aluminum, on the other hand, remarkably reduces residual stress and does not form Al_4C_3 in DLC films because Al atoms dissolve in the carbon-film matrix without bonding with C atoms [28]. In addition, synthesizing Al–N-co-doped DLC films [30] by direct current (DC)- and pulsed cathode arcing deposition at a high target current and low pulse frequency promotes the formation of C-N and sp^3-N–C bonds owing to the high N-atom and Al–N-bond contents in DLC films, thereby enhancing hardness and toughness.

To the best of our knowledge, there are no reports in the literature on the role of Al-N co-doping on the correlation between the thermal stability and the structure and hardness of DLC films. Elucidating the role of such co-doped elements may improve the predictability of DLC-film lifetime and performance to meet the requirements of high-performance protective coatings. Therefore, Al- and N-doped, Al–N-co-doped, and non-doped DLC films were synthesized on AISI 4140 steel using pulsed two-FCVA deposition to elucidate the correlation between the structure, mechanical properties, and thermal stability of the films. The geometric structure and thermal stability of the films were studied using in-situ near-edge X-ray absorption fine structure (NEXAFS) spectroscopy. The Al- and N-doped, Al–N-co-doped, and non-doped DLC films were investigated using radiative heating and electron beam bombardment under vacuum at room temperature and during thermal annealing to 700 °C. The cross-section and thickness of the DLC films were determined using field emission–scanning electron microscopy (FE–SEM) and focused ion-beam milling combined with scanning electron microscopy (FIB–SEM). Vital structural information including the I_G/I_D ratio, D and G peaks, full width at half maximum of the G peak (FWHM (G)), compressive residual stress (σ), and graphite cluster size of the sp^2 sites (L_a), was determined using Raman spectroscopy, while the dopant content and sp^3/sp^2 ratio were evaluated using X-ray photoelectron spectroscopy (XPS).

2. Experimental procedures

AISI 4140 steel was cut into 10 × 10-mm squares to prepare coated samples. All the samples were ground using silicon carbide paper of consecutively finer grits up to 1500, and the ground samples were ultrasonically rinsed with acetone and ethanol for 20 min to eliminate surface contamination and were then dried with N_2 gas (99.99% pure). Fig. 1 shows the schematic of the FCVA deposition system having two vacuum arc plasma sources. Each vacuum arc plasma source has its own macroparticle magnetic-filtered coil and is independently controlled

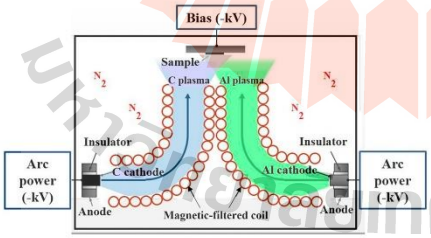


Fig. 1. The schematic of the FCVA deposition system.

using the arc power supply controller operating two sources concurrently. The precleaned substrates were loaded into an FCVA chamber to deposit the non-doped, doped, and co-doped DLC coatings, and the chamber was evacuated to a controlled base pressure of 8.0×10^{-4} Pa. A graphite cathode (99.99% pure) and an aluminum cathode (99.00% pure) with an ø8-mm rod were installed separately on each cathodic source. Targets and ceramic insulators were placed between the anode and cathode and marked with a graphite pencil to form a conduction path used to initiate the spot arc and generate the plasma arc discharge during DLC deposition. The source-generated plasma moved through the 90° curved magnetic-filter coil connected to the arc-system electrical supply during DLC deposition. The distance between the magnetic-filter coil outlet and substrate was 30 mm, and the deposition time was 30 min under all the conditions. The bias voltage (V_{bias}) of −1000 V was applied to drive the arc current with pulse repetition rates of 6.0 Hz and a duty cycle of 0.003% (the percentage of the ratio of the pulse duration to the total period of the waveform) for both the graphite and aluminum cathodes to maintain the balance between the cathode consumption and arc stability during deposition, as shown in Table 1. Both aluminum and graphite cathodes were arced for 5 min at V_{bias} of −1500 V prior to remove any surface contaminations of cathodes [31,32]. The substrate was bombarded with carbon ion at V_{bias} of −1500 V, which is higher than the bias used for the deposition process, to remove any surface oxides and create an active surface for DLC films. The film coating process had begun after vacuum pressure reduces to base pressure of 8.5×10^{-4} Pa. For N doping, ultrahigh purity (UHP) N_2 gas was continuously flowed into the chamber such that vacuum pressure raise from base pressure to 3×10^{-2} Pa and waits for 5 min to ensure N_2 gas flowing stably inside the chamber [27] before deposition process. The sample was set in deposited position (cross area between C and Al) on the jig (fixed), and applied V_{bias} directly. Table 1 shows the conditions for preparing non-doped DLC (ta-C), nitrogen-doped DLC (ta-C:N), aluminum-doped DLC (ta-C:Al), and aluminum- and nitrogen-co-doped DLC (ta-C:Al:N) films using FCVA deposition.

The bonding structures of the ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N films were investigated using a dispersive Raman microscope (SENTERRA; OPUS; BRUKER, Germany) operating in backscattering mode, and an Ar^+ laser (λ = 532 nm; power: 25 mW) was used as the excitation source. The focused-spot size and spectral resolution for the scanned Raman range (800–2000 cm^{-1}) were 3 μm^2 and 3 cm^{-1}, respectively. The Raman spectra were fitted to three Gaussian line shapes using OriginPro software, *V*ersion 2018. From the fitted Raman spectra, the positions of the D (disordered) and G (graphite) bands were indicated by peaks at approximately 1360 and 1540 cm^{-1}, respectively, and the full width at half maximum (FWHM) was used to calculate the D–G-band intensity ratio (I_D/I_G) [27,30,33–35]. The elemental composition of the DLC films was evaluated using XPS (PHI5000; VersaProbe™; ULVAC-PHI, Japan) operating with an Al K_α radiation source (1486.6 eV) under ultrahigh vacuum (UHV; ~10^{-7} Pa) at the SUT-NANOTEC-SLRI joint research facility, beamline 5.3: SUT-NANOTEC-SLRI XPS, SLRI, Nakhon Ratchasima, Thailand. Prior to analysis, the sample surfaces were sputtered with Ar^+ ions accelerated at 1000 V for 1 min to eliminate any natural oxides. The pass energy and scanning step were 46.95 and 0.1 eV, respectively, at a 100-μm spot. XPS spectra and CasaXPS software were used to quantitatively analyze the film bonding states, and elemental atomic concentrations were calculated using MultiPak Spectrum ESCA software. In addition, the thicknesses of DLC-film cross-sections were measured using FIB–SEM (AURIGA®; Carl Zeiss, Germany) operating at 50,000× magnification and FE–SEM operating at 5-kV acceleration. Surface roughness of the AISI 4140 substrate and all the DLC films was measured using Atomic Force Microscope (AFM) (Park Systems AFM XE-120, South Korea) operating at non-contact mode with 5 × 5 μm of area, and scan rate 0.3 Hz.

DLC-film hardness and elastic moduli were evaluated using nanoindentation testing with a NanoTest Instrument (Vantage; Micro Materials, UK) equipped with a Berkovich indenter under the maximum load,

Table 1
FCVA deposition conditions for ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N.

Sample	Pressure (Pa)		Voltage (V)			%Duty cycle		Frequency (Hz)		UHP N_2 gas	Time
	Base	N_2	$V_{arc\ C}$	$V_{arc\ Al}$	V_{bias}	C	Al	C	Al	N_2 flow rate (SCCM)[a]	(min)
ta C	8.5×10^{-4}	–	800	–	−1000	0.003	–	6.0	6.0	–	30
ta-C:N	8.5×10^{-4}	3×10^{-2}	800	–	−1000	0.003	–	6.0	6.0	2.5	30
ta-C:Al	8.5×10^{-4}	–	800	400	−1000	0.003	0.003	6.0	6.0	–	30
ta-C:Al:N	8.5×10^{-4}	3×10^{-2}	800	400	−1000	0.003	0.003	6.0	6.0	2.5	30

[a] SCCM denotes standard cubic centimeters per minute at standard temperature and pressure (STP).

according to the ASTM E2546-07 standard [36]. Nanoindentation technique is used to detect depth-sensing by a pendulum-based method and is an extensively reliable method for mechanical measuring amorphous carbon thin films. The specimens were measured ten repeated and choose for six-point average value to statistical reliability for the report. Each sample measurements were carried out using a Berkovich type of indenter, and the maximum penetration depth for the films was in the range of 10–15% of the film thickness to avoid the substrate effect [32]. Moreover, the maximum penetration depth of each film followed the ASTM E2546-07 standard [36]. Therefore, the nanomechanical properties in this study followed the international criteria, although their thickness was different. Loading and unloading curves were measured at the rate of 0.1 mN s^{-1} with a dwell time of 10 s.

ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N thermal stabilities were sequentially investigated using in-situ high-temperature NEXAFS spectroscopy in a UHV system from room temperature (RT) to 700 °C at 10 °C min^{-1} while holding the films for 20 min at each annealing temperature. The films were then cooled to 300 °C at each step, and the local bonding configuration was measured using in-situ NEXAFS spectroscopy coupled with spectroscopic photoemission and low-energy electron microscopy (SPELEEM; ELMITEC Elektronenmikroskopie GmbH, Germany) at beamline 3.2Ub: PEEM, SLRI, Nakhon Ratchasima, Thailand. The monochromatic photon energy of the beamline was operated in the range 40–1040 eV, in which synchrotron radiation was dispersed at 17° incident to the film surface under UHV (~3×10^{-8} Pa). NEXAFS spectra were measured in partial-electron-yield (PEY) mode by setting the bias to −20 kV, which is equal to the pass energy of the hemispherical energy analyzer. Therefore, only low-energy electrons (near the photoelectron threshold) were utilized as the NEXAFS intensity. NEXAFS C *K*-edge spectra were measured using photons in the range 270–350 eV and were scanned in 0.1-eV steps.

The absorption signals of all the DLC films were normalized using the NEXAFS intensity (in the same photon-energy range) of a flashed-Si wafer and highly oriented pyrolytic graphite (HOPG) as the reference material. The normalized C *K*-edge spectrum was deconvoluted using IGOR Pro 6.3 software to calculate the sp^2-bonding fraction of the films. The thermal stability of the non-doped, doped, and co-doped DLC films was evaluated based on the change in the sp^2-bonding fraction, and correlations between thermal stability and the other film properties were established.

3. Results and discussion

3.1. Structural analysis and film thickness

Raman spectroscopy, a well-known non-destructive analysis technique, is usually used to examine the bonding structure of amorphous carbon or DLC films [34,35,37–39]. Fig. 2 shows the Raman spectra of the non-doped, doped, and co-doped DLC films measured in the range 800–2000 cm^{-1}. The Raman spectra were fitted to the main Gaussian curves and were deconvoluted into G and D peaks and bands centered in the range ~ 1140–1260 cm^{-1} [40]. The G and D peaks and FWHM were used to calculate I_D/I_G and evaluate the content of hybridized carbon bonds, respectively. Usually, the D peak (i.e., breathing mode) at ~1360 cm^{-1} corresponds to aromatic-ring vibrations (i.e., the disordered structure in six-fold aromatic rings), and the G peak (i.e., stretching mode) at ~1540 cm^{-1} corresponds to the stretching of all the pairs of sp^2-hybridized carbon atoms in aromatic rings and to carbon-chain vibrations [31,41]. The bands centered in the range ~1140–1260 cm^{-1} were assigned to the *trans*-polyacetylene (*trans*-PA) structure and were associated with hydrogen atoms bonded with sp^2-hybridized carbon atoms in the chain [42,43]. In addition, the peak at ~1260 cm^{-1} was attributed to the nanocrystalline (NC) diamond structure [40], indicating sp^3-hybridized carbon and H contents. Nevertheless, D and G peaks can be detected in various ranges; for example, the D and G peaks were detected in ranges ~1350–1370 and ~1500–1650 cm^{-1}, respectively, for the DLC films in this study [27,33,34,37,44]. The G peaks for ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N were detected at ~1544.5, ~1552.5, ~1532.3, and ~1545.1 cm^{-1}, respectively, as listed in Table 2. Notably, doping noticeably changed the DLC-film structure, as indicated by the shifting G peak. The G peak shifted to higher wavenumbers for ta-C:N and ta-C:Al:N and a lower wavenumber when DLC was doped with Al (ta-C:Al). Extensive research has shown that G-peak shifting is related to changes in L_a and σ for DLC films [45,46]. The vital Raman parameters (i.e., G and D peaks, I_D/I_G, and FWHM (G)) were determined from the area under the G- and D-peak Gaussian curves, while σ and L_a were respectively estimated using the following equations [31,47–50]:

$$\frac{I_D}{I_G} = C'(\lambda) L_a^2, \quad (1)$$

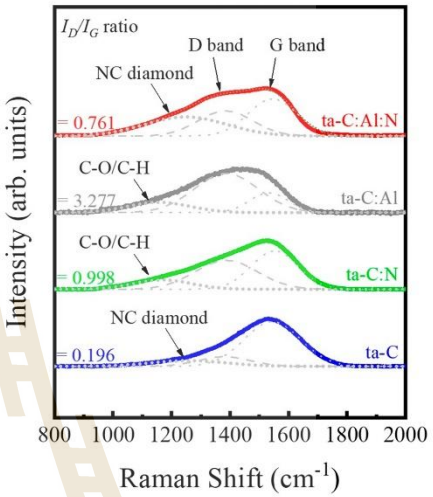


Fig. 2. Raman spectra of ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N.

Table 2
Vital parameters obtained from Raman analysis: D and G peaks, FWHM (D), FWHM (G), I_D/I_G ratio, L_a, and σ of ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N.

Sample	Raman analysis						
	G Peak (cm^{-1})	D Peak (cm^{-1})	FWHM of G peak (cm^{-1})	FWHM of D peak (cm^{-1})	I_D/I_G ratio	L_a (nm)	σ (GPa)
ta C	1544.54	1379.77	226.91	205.44	0.196	5.965	0.000
ta-C:N	1552.49	1386.85	189.17	250.05	0.998	13.469	1.339
ta-C:Al	1532.33	1387.15	156.16	257.53	3.277	24.409	−2.056
ta-C:Al:N	1545.14	1384.34	195.66	219.15	0.761	11.765	0.102

where $C'(514\ nm) \approx 0.0055$.

$$\sigma = 2G\left[\frac{1+\upsilon}{1-\upsilon}\right]\left[\frac{\Delta\omega}{\omega_0}\right], \quad (2)$$

where G is the shear modulus (70 GPa), υ is Poisson's ratio (≈0.3), Δω is the shift in the G-peak Raman wavenumber, and ω_0 is the Raman wavenumber of the DLC sample, which is the (not necessarily stress-free) reference material.

Table 2 lists the Raman parameters obtained for ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N, clearly indicating that doping had shifted the G peak to lower or higher wavenumbers, significantly increased I_D/I_G, and drastically decreased FWHM (G). The decrease in G corresponded to larger graphite clusters at sp^2-hybridized carbon sites because L_a (calculated using Eq. (1)) was consistent with those found in previous studies [31,34,48]. Remarkably, the L_a values of the N-doped/co-doped and Al-doped DLC films (i.e., ta-C:N/ta-C:Al:N and ta-C:Al) were double and approximately quintuple that of the non-doped DLC film, respectively. The increased L_a of the doped and co-doped DLC films depends on increased I_D/I_G and decreased FWHM (G) [45,51]. The increased I_D/I_G was mainly attributed to the increased sp^2-hybridized carbon content in the aromatic-ring structure, thereby reducing the sp^3-hybridized carbon content. The decreased I_D/I_G, on the other hand, was correlated with the sp^2-hybridized carbon-bonding cluster arranged in the chain structure [47]. These results indicate that high-L_a doped and co-doped DLC films (i.e., ta-C:N, ta-C:Al, and ta-C:Al:N) exhibited lower sp^3-hybridized carbon contents than non-doped DLC, indicating progressive transformation toward the graphitic sp^2-hybridized carbon structure in DLC films doped and co-doped with Al and N.

Raman spectroscopy is employed to quantify the internal stress of materials because stress–strain-dependent properties are directly related to atomic-vibration frequencies. Moreover, because the wavenumber obtained using Raman spectroscopy is proportional to vibrational frequencies, it was applied to estimate the internal stress of the DLC films. When the load was applied to DLC films, the constituent atoms reversibly changed. Therefore, the interatomic-force constants, which determine the atomic vibrational frequencies, also changed because they are related to the interatomic separation. For example, with increasing DLC-film tensile load, bond lengths increased and force constants and vibrational frequencies both decreased, and the opposites happened when the material was subjected to compressive loads [52–54]. The Raman spectra clearly showed that doping DLC films with only N or Al-N shifted the G peak to higher wavenumbers (~1552.49 and ~1545.14 cm^{-1}) while doping with only Al shifted the G peak to lower wavenumber (~1532.33 cm^{-1}). Relative to the internal compressive residual stress of DLC, those of ta-C:N, ta-C:Al, and ta-C:Al:N (calculated using Eq. (2)) were 1.339, −2.056, and 0.102 GPa, respectively. From the estimated σ, G peaks shifted to higher and lower wavenumbers, clearly indicating increased and decreased compressive stress in DLC films, respectively [52–54]. Furthermore, the XPS spectra presented in Section 3.3 indicate that increasing the compressive stress (σ) in ta-C:N and ta-C:Al:N induced the carbon-bonding structure to transition from sp^3- to sp^2-hybridized carbon less than decreasing compressive stress in ta-C:Al, in which the carbon-bonding structural transition from sp^3- to sp^2-hybridized carbon was crucial. These results are in good agreement with those published in previous studies [28,53]. The ta-C:Al G peak shifted toward the lower wavenumber might be affected by the Al-induced increased content of disordered graphite (i.e., sp^2-hybridized carbon) in the DLC structure and the low Al/aluminum oxide content generated and incorporated into the DLC-film matrix [28]. In addition, the Al crystal structure is face-centered cubic (FCC), which hinders carbide formation in DLC films, thereby allowing nanocrystal growth in the DLC matrix [51].

Fig. 3 shows a smooth and continuous amorphous film layer coated on the AISI 4140 surface. All the DLC-film cross-sections observed using FIB–FEM were in the range 100–250-nm thick, and the films are arranged from thickest to thinnest as follows: ta-C:N (230 nm) > ta-C (180.9 nm) > ta-C:Al:N (154.1 nm) > ta-C:Al (113.9 nm). Although the coating conditions (i.e., pressure, voltage, duty cycle, and time) were identical for all the films, as listed in Table 1, the film thicknesses were unequal because DLC-film thickness is regularly affected by the bonding structure and arrangement of carbon atoms in the DLC-film chain and aromatic rings and by dopant composition [27,31,44,55–57]. The thickness of all the films depends on the compressive residual stress generated during coating. Film thickness increased with increasing compressive residual stress in ta-C:N/ta-C:Al:N and film thickness decreased with decreasing compressive residual stress in ta-C:Al, as listed in Table 2 and shown in Fig. 3. DLC-film thickness increased not only with increasing compressive stress but also with the G peak shifting to a higher wavenumber, which is consistent with previous findings that film thickness was correlated with Raman spectral data [55].

The dopant-induced change in the DLC film thickness could be explained as follows. The ta-C:N film thickness could have increased because of reactive N atoms as an additional deposition element in the chamber. The high internal compressive stress of the ta-C:N film might have been due to the high N_2 plasma concentration during deposition [27,47]. In contrast, the ta-C:Al compressive stress and thickness were the lowest and thinnest, respectively, which may be because C and Al ions had collided during coating; subsequently, fewer C ions exhibited sufficient energy to coat and form sp^3-hybridized carbon bonds on the film layer and because Al does not combine with C to form aluminum carbide [28,51]. This plausible explanation is supported by the highest I_D/I_G and L_a and the lowest hardness values. Although the Al- and N-co-doped DLC film (ta-C:Al:N) was approximately 26 nm thinner than the non-doped DLC film (ta-C), the relative compressive stress of ta-C:Al:N was approximately 0.102 GPa, as compared with ta-C. This may have been due to the reduced collision rate between C and Al ions because the N_2 pressure had increased from the base to 3×10^{-2} Pa in the coating chamber during film growth and Al and N co-doping [47,58]. As previously described for ta-C:N, because N ions also promoted film deposition, the ta-C:Al:N film was slightly thinner than the non-doped DLC film.

Fig. 4 shows the surface roughness of AISI 4140 substrate (for both before and after polishing) and all the DLC films measured using AFM. There was no SiC from the SiC paper embedded on the surface as the substrate was cleaned properly. The surface roughness (Ra) of AISI 4140 was 8.8 nm, which is less than the roughness of the block standard according to the ASTM E2546-07 standard [36], mentioned that the reference blocks should be prepared in such a way that the test surface is as smooth as is possible. Moreover, an acceptable value of average surface roughness, Ra, for many applications is Ra ≤ 10 nm measured over a 10 μm trace. It might therefore say that the surface roughness of all samples in this study rarely affected nanomechanical properties. The surface roughness of all the samples was nearly the same (Ra 6.4–8.8

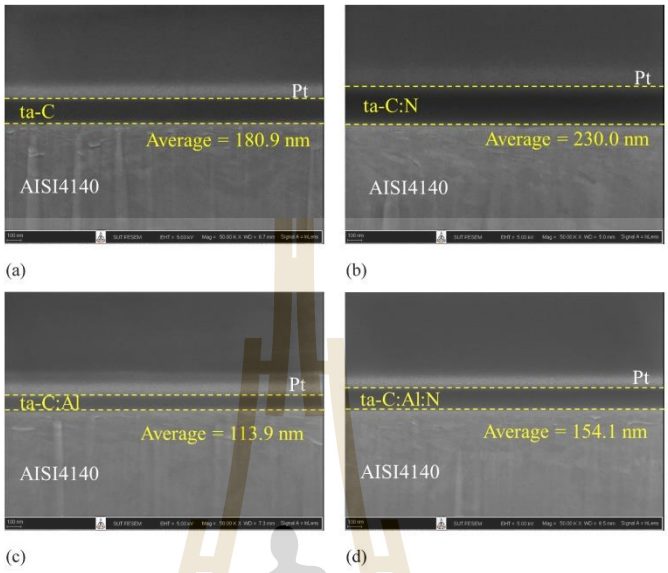


Fig. 3. FIB–SEM images of (a) ta-C, (b) ta-C:N, (c) ta-C:Al, and (d) ta-C:Al:N.

nm), and the roughness of DLC films (Ra) was 8.4, 8.0, 8.8, and 6.4 nm for ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N, respectively. Moreover, macroparticles were detected on ta-C, while they were found rarely on ta-C:N, ta-C:Al, and ta-C:Al:N. It meant that N and Al dopants remarkably decreased macroparticles on the DLC surface. The decrease in the macroparticles was due to the collision between the dopants and macroparticles. Then, the macroparticles were fallen and filtered by the copper filter coil.

3.2. Nanomechanical properties

Fig. 5 shows the load-displacement curves of all the DLC films. Non-smooth load-displacement curves (discontinuities) represented the high elastic recovery (*%ER*) owing to the elastic-to-plastic deformation transition, as described in [59], and plastic deformation bands often parallel to the indentation edges at the low-load indentations (applied in this study).

The nanomechanical properties of the DLC films—including hardness (*H*), elastic modulus (*E*), plastic index parameter (i.e., the ratio of hardness to elastic modulus, *H*/*E*), and elastic recovery (*%ER*)—were evaluated using nanoindentation testing. The elasticity of the DLC films was estimated using the elastic recovery (*%ER*) obtained from the load–displacement curves shown in Fig. 5 and was calculated using the following equation:

$$\%ER = \left(\frac{d_{max} - d_{res}}{d_{max}}\right) \times 100, \quad (3)$$

where d_{max} and d_{res} are the displacement at the maximum load and the residual displacement after load removal, respectively.

As listed in Table 3, the *H* and *E* of the ta-C:N, ta-C:Al, and ta-C:Al:N were 47.32 ± 1.91 and 210.51 ± 4.82, 38.84 ± 1.78 and 159.65 ± 3.94, and 49.04 ± 1.33 and 251.09 ± 6.57 GPa, respectively, and were lower than those of non-doped DLC (51.12 ± 1.08 and 302.29 ± 6.35 GPa, respectively). Lower *H* and *E* correspond to increased I_D/I_G and L_a attributed to increased sp^2-hybridized carbon bond content and decreased sp^3/sp^2, as confirmed by the XPS spectra (Section 3.3). Therefore, the nanomechanical properties showed that the DLC films exhibited increased graphitization and larger graphite clusters (L_a) with increasing dopant content. Moreover, the sp^3-hybridized carbon bond content significantly affected the mechanical properties of the DLC films, especially the ta-C film. The mechanical properties of the ta-C film (i.e., hardness, surface smoothness, atomic density, and Young's modulus) all degraded with decreasing sp^3-hybridized carbon bond content [27]. The *H* of the ta-C:Al:N was slightly lower than that of non-doped DLC possibly owing to the NC diamond phase [40] that had formed in the co-doped DLC film, as indicated by the peak at ~1248.17 cm^{-1} in Fig. 2. These results imply that doping the DLC film with Al and N improved the hardness of the DLC film. However, all the DLC films enhanced the hardness of the bare steel (AISI 4140) substrate, as verified by the increased hardness from 3.3 GPa [60] for bare steel (AISI 4140) to 38.84 ± 1.78, 47.32 ± 1.91, and 49.04 ± 1.33 GPa for ta-C:Al, ta-C:N, and ta-C:Al:N-coated 4140 steel, respectively. In addition, DLC nanomechanical properties (*H* and *E*) were above 38 and 150 GPa, respectively, compared with those of natural diamond (56–102 and 1050 GPa, respectively), thereby implying the deposition of high-quality DLC films. These values are consistent with others published in the literature [61,62]; therefore, the films could effectively protect the substrate surface from scratches and wear.

The elastic–plastic behavior and wear resistance of the DLC films were considered through *H*/*E* and *%ER* [61]. *H*/*E*, an important parameter that combines both properties, is used to rank materials in which surface layers intensively deform during service, which is the so-called elastic strain to failure. Therefore, DLC films exhibiting high *H*/*E* also exhibit high wear resistance [63], and such protective coatings might be suitable for application to automobile parts. The ta-C:N, ta-C:Al, and ta-C:Al:N films exhibited *H*/*E* values of 0.225 ± 0.010, 0.243 ± 0.013, and 0.195 ± 0.007, respectively, slightly higher than that of the

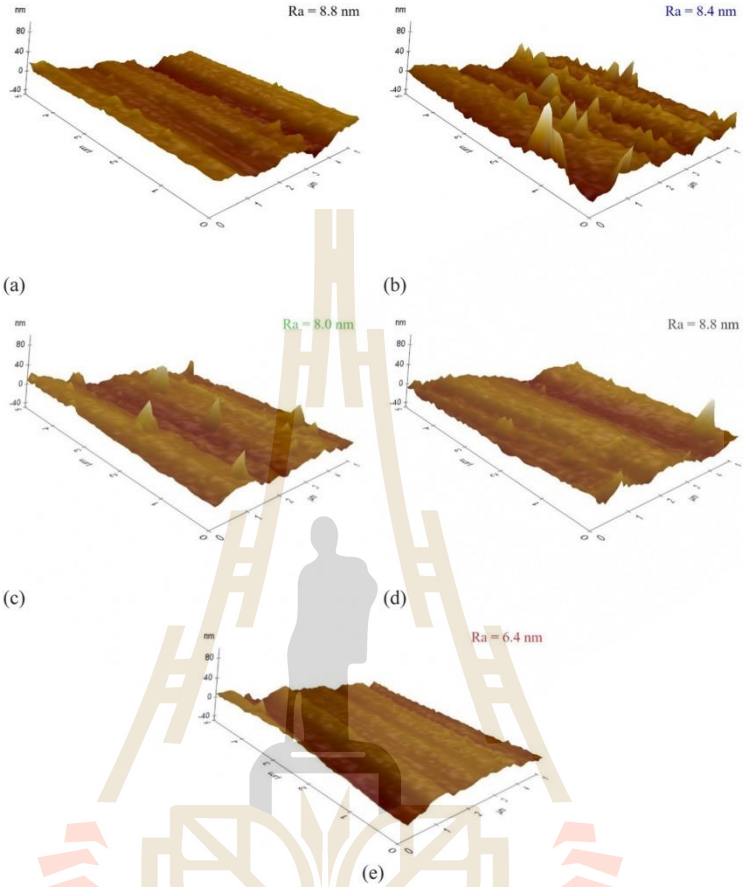


Fig. 4. AFM topographies of (a) AISI 4140, (b) ta-C, (c) ta-C:N, (d) ta-C:Al, and (e) ta-C:Al:N.

ta-C film (0.169 ± 0.005), as listed in Table 3, meaning that although Al and N doping might improve the elastic strain to failure, they also reduce DLC-film hardness. It is well known that typical hard and adherent DLC films exhibit high elasticity and recovery owing to the relaxation of the elastic strain within the DLC structure [64,65]. In addition, elastic recovery strongly depends on the sp^3-hybridized carbon bond content in the film [63]. Therefore, the elastic recovery of the DLC films decreased with increasing dopant content, as indicated by *%ER* data listed in Table 3. Similar to the trend in *H*, *%ER* is ranked in descending order as follows: ta-C > ta-C:Al:N > ta-C:N > ta-C:Al, corresponding to the sp^3-hybridized carbon bond content in the films, as confirmed by the XPS analysis in Section 3.3. Vital properties such as the local bonding structure and thermal stability are further discussed in subsequent sections to consider whether doping and co-doping are appropriate for DLC films applied as protective coatings for wear and tribological applications, especially for automobile parts.

3.3. Elemental composition and chemical bonding structure

The elemental composition and chemical bonding structure of ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N were quantified using XPS. Table 4 lists the elemental compositions of the films. Clearly, doping decreased the atomic concentration (at.%) of C from 90.01 for ta-C to 79.23, 78.20, and 58.83 for ta-C:N, ta-C:Al, and ta-C:Al:N, respectively, as listed in Table 4, and decreased the sp^3-hybridized C-C content of the DLC films, as shown in Fig. 6. The N content was approximately 11.21 and 14.12 at. % in ta-C:N and ta-C:Al:N, respectively, while the Al content was approximately 4.77 and 7.18 at.% in ta-C:Al and ta-C:Al:N, respectively. O content increased with increasing Al content possibly because O had adsorbed on or bonded with Al on the film surface to form an oxide layer when the films were exposed to air [29].

The chemical compositions and bonding states of the non-doped, doped, and co-doped DLC films were measured using XPS, and the essential C 1*s*, N 1*s*, and Al 2*p* peaks were detected in all the spectra, as

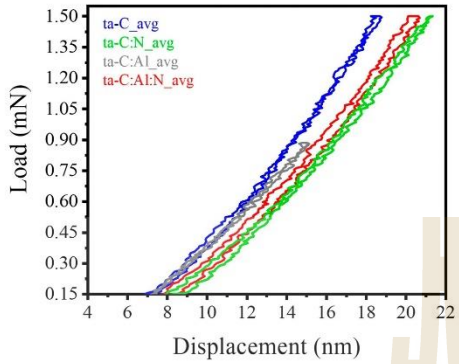


Fig. 5. Load–displacement curves of ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N.

Table 3
Mechanical properties of ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N.

Sample	Mechanical properties			
	Hardness, *H* (GPa)	Elastic modulus, *E* (GPa)	Plastic index parameter, *H/E*	Elastic recovery (%*ER*)
ta-C	51.12 ± 1.08	302.29 ± 6.35	0.169 ± 0.005	60.06 ± 1.93
ta-C:N	47.32 ± 1.91	210.51 ± 4.82	0.225 ± 0.010	57.92 ± 1.35
ta-C:Al	38.84 ± 1.78	159.65 ± 3.94	0.243 ± 0.013	50.47 ± 1.53
ta-C:Al:N	49.04 ± 1.33	251.09 ± 6.57	0.195 ± 0.007	58.43 ± 1.73

Table 4
ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N elemental compositions (at.%) quantitively measured using XPS.

Sample	Atomic Concentration[a] (at.%)			
	C 1*s*	N 1*s*	O 1*s*	Al 2*p*
ta-C	90.01	–	9.99	–
ta-C:N	79.23	11.21	9.56	–
ta-C:Al	78.20	–	17.03	4.77
ta-C:Al:N	58.83	14.12	19.87	7.18

[a] Atomic concentration was calculated using MultiPak Spectrum ESCA software.

shown in Figs. 6–8. The C 1*s* XPS spectra were deconvoluted into distinct Gaussian–Lorentzian peaks using Shirley backgrounds to estimate the percentage of sp^3-hybridized C-C bonds in the DLC films [56,66]. Fig. 6 shows peaks obtained for the deconvoluted C 1*s* spectra of ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N. In the deconvoluted spectrum for DLC, peaks corresponding to pure carbon–carbon bonds at 283.5 and 284.19 eV were assigned to C=C bonds (i.e., sp^2-hybridized carbon atoms) and C-C bonds (i.e., C sp^3-hybridized carbon atoms), while another peak in the binding energy range 286–288 eV was matched to C–OH, C-O, or C=O bonds, indicating bonding between the carbon and hydrogen atoms and air-exposure-induced environmental oxygen contamination in the local DLC-film bonding structure [15,31,39,47,48,67,68]. The deconvoluted C 1*s* peaks obtained for sp^3-hybridized C-C and sp^2-hybridized C=C bonds were slightly shifted because double bonds are slightly shorter than single ones; therefore, the charge density (around the C atom) moved closer to the carbon nucleus and the valence electrons contracted in the sp^2-hybridized C=C bonds, thereby decreasing the binding energy of the C 1*s* core level [15]. In the deconvoluted spectra for ta-C:N, ta-C:Al, and ta-C:Al:N, the deconvoluted C 1*s* peaks obtained for sp^2-hybridized C=C bonds (at 284.54, 284.38, and 284.42 eV for ta-C:N, ta-C:Al, and ta-C:Al:N, respectively) and sp^3-hybridized C-C bonds (at 284.92, 284.80, and 285.02 eV for ta-C:N, ta-C:Al, and ta-C:Al:N, respectively) were shifted to binding energies higher than those of their counterpart peaks in the deconvoluted spectrum for DLC, and all the peak positions corresponded almost exactly to those previously reported in the literature [15,29,69]. The percentage of sp^3-hybridized C-C bonds in the DLC films decreased remarkably from 68.01% for ta-C to 40.20 and 38.58% for ta-C:N and ta-C:Al, respectively, because the DLC films had been doped with only one element. In contrast, the Al and N co-dopant synergy was obvious; that is, the percentage of sp^3-hybridized C-C bonds only slightly decreased compared to that in the single-doped films, from 68.01 to 50.41% for ta-C and ta-C:Al:N, respectively (Fig. 6). These results indicated that the percentage of sp^3-hybridized C-C bonds decreased with increasing alloying contents. Furthermore, the decreased percentage of sp^3-hybridized C-C bonds corresponded to reduced hardness (*H*) in the doped and co-doped DLC films (i.e., ta-C:N, ta-C:Al, and ta-C:Al:N), as listed in Table 3. Although the deconvoluted spectra obtained for ta-C:N and ta-C:Al:N exhibited high-resolution deconvoluted C 1*s* peaks in ranges 285.50–286.54 and 285.20–287.45 eV (corresponding to sp^2-hybridized C=N and sp^3-hybridized C-N bonds, respectively), the spectra did not exhibit any peaks corresponding to *sp*-hybridized C≡N bonds (i.e., nitrile groups) at 286.70 eV [38,39,66,70]. When DLC films are doped with N during coating, N significantly forms various bonds with local carbon atoms to generate an amorphous structure consisting of pyridine (sp^2-hybridized C=N bonds), urotropine (sp^3-hybridized C-N bonds), and nitrile groups (*sp*-hybridized C≡N bonds) [29,38,39,66,71]. Therefore, the sp^3 and (sp^2 + sp^3) C-bond ratios changed from 0.81 for ta-C to 0.49, 0.48, and 0.77 for ta-C:N, ta-C:Al, and ta-C:Al:N, respectively. The C 1*s* spectra showed that the fraction of sp^3-hybridized C atoms decreased with increasing N and Al contents, corresponding to decreased *H* (Table 3). Furthermore, the decreased relative fraction of sp^3-bonded C and N atoms corresponded to more and larger sp^2-bonded clusters (L_a) [72] and increasing I_D/I_G, as listed in Table 2. The XPS results showed good agreement with the Raman analysis (Section 3.1) and hardness tests (Section 3.2).

Likewise, the deconvoluted N 1*s* spectra for ta-C:N and ta-C:Al:N, shown in Fig. 7, exhibited three peaks in ranges 397.50–399.40, 399.10–400.60, and 401.5–402.9 eV corresponding to sp^3-hybridized N-C, sp^2-hybridized N=C, and N-O bonds, respectively [29,39,66]. These peaks are consistent with organic nitrogen-containing polymers pyridine (which exhibits sp^2-hybridized C=N bonds and C 1*s* and N 1*s* peaks at 285.50 and 400.16 eV, respectively) and urotropine (which exhibits sp^3-hybridized C-N bonds and C 1*s* and N 1*s* peaks at 286.9 and 399.40 eV, respectively) [66]. In ta-C:N and ta-C:Al:N, N atoms are mainly bonded to sp^2- and sp^3-hybridized carbon atoms (i.e., N-C and N-C bonds), respectively, because the relative fraction of sp^3-bonded N and C atoms: (sp^3-hybridized N-C bonds)/(sp^3-hybridized N-C bonds + sp^2-hybridized N-C bonds) changed from 0.28 to 0.89, as shown in Fig. 7. More sp^2-hybridized N-C bonds in DLC films, especially ta-C:N, significantly reduced the relative fraction of sp^3-bonded N and C atoms because N doping reduced the number of dangling bonds in the aromatic ring [39]. In addition, the weak peak at 282.2 eV in the C 1*s* spectra for ta-C:Al and ta-C:Al:N corresponded to Al–O–C bonds, which might be due to air-exposure-induced contamination and oxygen [73].

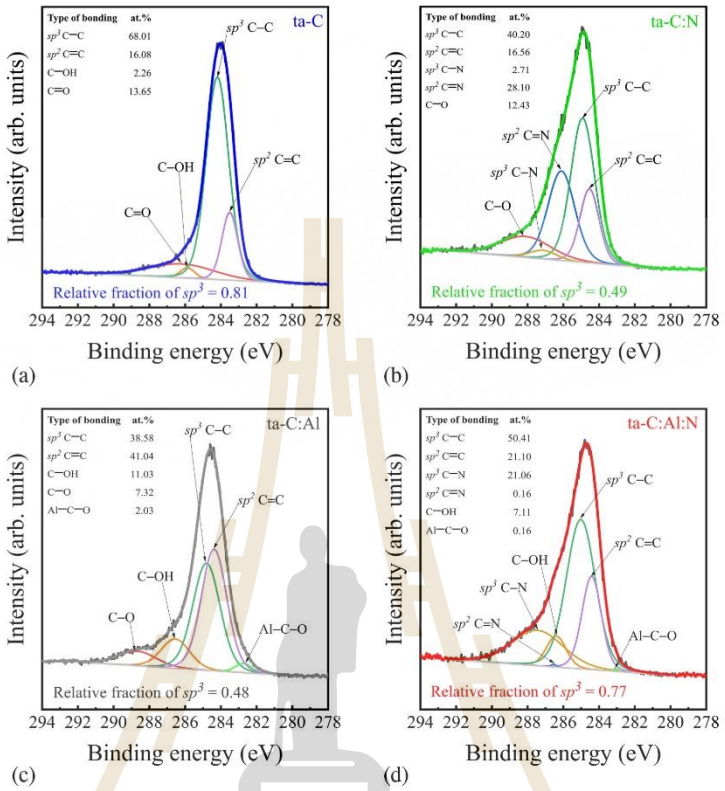


Fig. 6. C 1s XPS spectra and corresponding deconvoluted Gaussian peaks of (a) ta-C, (b) ta-C:N, (c) ta-C:Al, and (d) ta-C:Al:N.

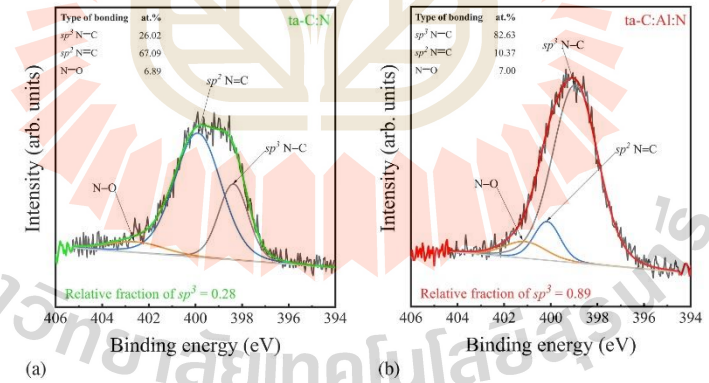


Fig. 7. N 1s XPS spectra and corresponding deconvoluted Gaussian peaks of (a) ta-C:N and (b) ta-C:Al:N.

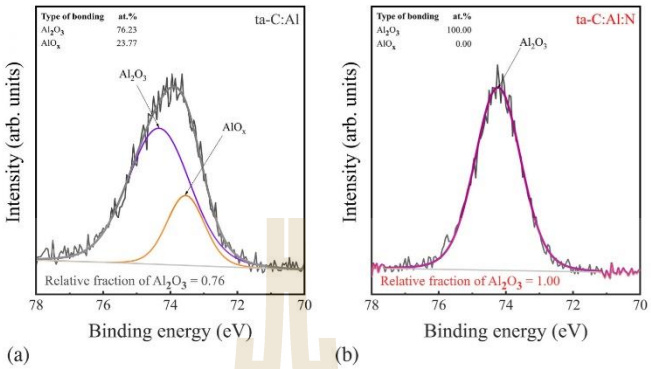


Fig. 8. Al 2*p* XPS spectra and corresponding deconvoluted Gaussian peaks of (a) ta-C:Al and (b) ta-C:Al:N.

Fig. 8 shows the peaks in the deconvoluted Al 2*p* spectra for ta-C:Al and ta-C:Al:N. In the spectrum for ta-C:Al, peaks at 73.54 and 74.24 eV were assigned to AlO_x and Al_2O_3, respectively, while the spectrum for ta-C:Al:N exhibited only one peak at 74.24 eV. The relative fraction of Al_2O_3: $Al_2O_3/(Al_2O_3 + AlO_x)$ was 0.76 and 1.00 for ta-C:Al and ta-C:Al:N, respectively, as shown in Fig. 8. Noticeably, the most stable aluminum oxide (Al_2O_3) [74] was present in ta-C:Al:N, whereas aluminum suboxides (AlO_x) coexisted with Al_2O_3 in ta-C:Al [29,73,75]. Al_2O_3 has been widely used to manufacture machining tools and solar cells and in other high-temperature applications because of its excellent properties including wear resistance, thermal stability, and corrosion resistance [76,77]. However, doping DLC with only Al degraded the compressive stress (σ) and hardness (*H*), which are vital properties for tribological applications such as adhesion and wear resistance, owing to the presence of significantly fewer sp^3-hybridized C-C bonds (without any sp^3-hybridized N-C bonds) in the films, as reported in a previous study [27]. This result suggested that single-doping DLC films with only a low aluminum content (e.g., 4.77 at.% in this experiment) decreased hardness and degraded the mechanical properties. In contrast, the synergy between Al and N in ta-C:Al:N maintained σ and *H*—both necessary for adhesion and wear resistance—which might be because N atoms mainly formed sp^3-hybridized N-C bonds associated with Al_2O_3 in ta-C:Al:N, except for ta-C:Al, which does not contain any sp^3-hybridized N-C bonds but does contain a mixture of AlO_x and Al_2O_3. Therefore, altering the DLC-film bonding structures, especially carbon–carbon bonds, and the thermal stability changes when DLC films are co-doped with Al and N will be further investigated in Section 3.4.

3.4. Thermal stability

The local atomic structures of ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N were evaluated using in-situ high-temperature NEXAFS spectroscopy to assess the thermal stability of DLC films at RT and thermally annealed in the range 200–700 °C in 100 °C increments. Fig. 9 shows the C *K*-edge NEXAFS spectrum generated for ta-C:Al:N at RT. Multiple peaks were obtained by subtracting and deconvoluting the spectrum. Evidently, the pre-edge resonance at ~285.4 eV was assigned to transitions from C 1*s* to the unoccupied π^* state of the sp^2-hybridized C=C site, including the contribution of the *sp*-hybridized C≡C site if present [32,78,79]. For the high-energy edge, the broadband region between 288 and 335 eV originated from overlapping C 1*s* transitions to unoccupied σ^* states at *sp*-, sp^2-, and sp^3-hybridized sites in the DLC films [78]. The intermediate region distinguished between the π^* and σ^* states at ~285.1, 285.9, 286.3, 287.6, 287.7, 288.5, 289.6, and 293.7 eV corresponded to

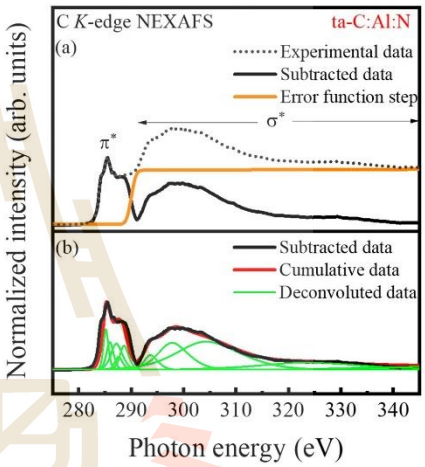


Fig. 9. In-situ high-temperature NEXAFS C *K*-edge spectrum generated for ta-C:Al:N (a) prior to data subtraction (where error function step was applied to fit edge jumping at ionization potential, as indicated in orange) and (b) after data subtraction (where spectrum was deconvoluted into multiple Gaussian peaks).

transitions between the following states: C 1*s* → π^* (C=C), π^* (C=N), π^* (C=OH), σ^* (C-H), σ^* (C-N), π^* (C=O) or π^* (C≡C), σ^* (C-C), and σ^* (C=C), respectively [80,81]. Other high resonances detected at ~297.8 and ~ 304.3 eV were attributed to C 1*s* transitions to the σ^* (C-O) and σ^* (C≡C) states, respectively [78,81]. Because hydrogen was absent during FCVA deposition, σ^* (C-H) states were related to the hydrogen saturation of the surface-carbon dangling bonds (i.e., nonpaired electrons), while carbon oxidized owing to air exposure was assigned to π^* (C=O) states [78,80,81].

To evaluate the sp^2-hybridized bond content in a sample, the peak area corresponding to the C 1*s* → π^* transition at ~285.4 eV must be normalized with C 1*s* → σ^* transitions in the range 288–335 eV. The sp^2-hybridized bond fraction can then be calculated using the following equation [78,79,82]:

$$f_{sp^2} = \frac{I^{\pi^*}_{sam} / I^{total}_{sam}}{I^{\pi^*}_{ref} / I^{total}_{ref}}, \quad (4)$$

where "π^*" denotes the position of the C $1s \rightarrow \pi^*$ transitions (i.e., C=C bonds), "total" assigns integration areas calculated under the spectrum to binding energies in the range 288–335 eV, and "sam" and "ref" define deconvoluted peaks for a sample thin film and a reference sample (highly oriented pyrolytic graphite (HOPG)), respectively.

Fig. 10 shows the in-situ C *K*-edge NEXAFS spectra for ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N at RT and thermally annealed up to 700 °C. The chemical bonding configuration exhibited slight heterogeneities, as indicated by the spectral features, meaning that the atomic bonding structure changed gently when the dopant content (Al and N) was low. At RT, the sp^2-hybridized bond fractions of the ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N films were 0.34, 0.39, 0.55, and 0.36, respectively, as shown in Figs. 10 and 11. Doping with only N or Al clearly induced the formation of graphitic (i.e., sp^2-hybridized) bonds (called "graphitization"), as indicated by the sp^2-hybridized bond fractions, while co-doping with both Al and N only slightly induced graphitization. The relative sp^2-hybridized bond fraction increased with increasing annealing temperature because graphitization transformed sp^3-hybridized (σ*) states into sp^2-hybridized (π*) ones in the amorphous carbon film, thereby resulting in fewer-carbon dangling bonds [83]. Remarkably, the NEXAFS spectra of ta-C:N, ta-C, and ta-C:Al showed that sp^3-hybridized (σ*) *states* had significantly transformed into sp^2-hybridized (π*) ones in the amorphous carbon films, thereby increasing the relative sp^2-hybridized bond fraction to 1.00 (i.e., 100% sp^2-hybridized bond content) at 400, 500, and 600 °C, respectively, which is consistent with findings in previous studies [84–86]. In contrast, the relative sp^2-hybridized bond fraction in ta-C:Al:N increased gradually from 0.36 at RT to 0.39 at 300 °C, which was only slightly different from the change in the relative sp^2-hybridized bond ratio in ta-C (i.e., from 0.34 to 0.40) in the same temperature range. Although the relative sp^2-hybridized bond fraction of ta-C:Al:N rose abruptly from 0.43 to 0.56 from 400 to 700 °C, the carbon remained amorphous in the ta-C:Al:N film, implying that ta-C:Al:N graphitized more slowly and at a higher annealing temperature than

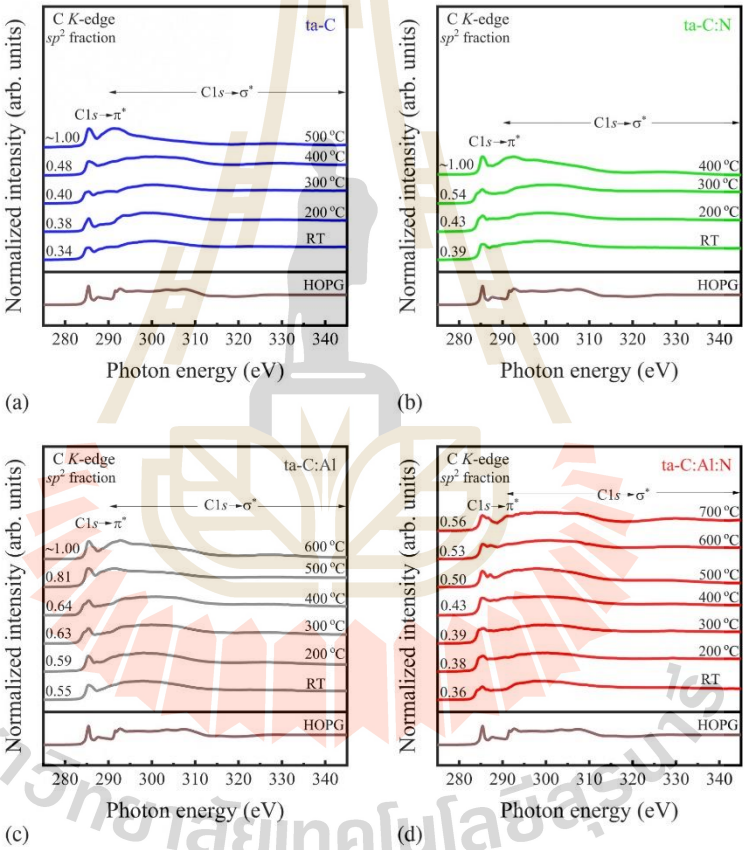


Fig. 10. C *K*-edge NEXAFS spectra generated for (a) ta-C, (b) ta-C:N, (c) ta-C:Al, and (d) ta-C:Al:N at room temperature (RT) and thermally annealed to graphitization temperature.

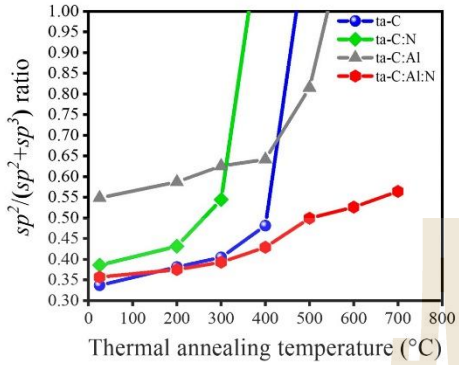


Fig. 11. ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N sp^2-hybridized bond fractions plotted as functions of thermal annealing temperature from room temperature (RT) to graphitization temperature.

ta-C:N, ta-C, and ta-C:Al, as shown in Fig. 11. The high thermal stability of ta-C:Al:N might be due to the synergistic formation of stable oxide (Al_2O_3) and nitride (i.e., sp^3-hybridized) N-C bonds, as confirmed by the XPS results shown in Figs. 7 and 8, respectively, which significantly slowed graphitization in amorphous ta-C:Al:N during in-situ high-temperature annealing, thereby stabilizing the DLC structure [29,30,87].

4. Conclusions

Al-doped (ta-C:Al), N-doped (ta-C:N), Al-N co-doped (ta-C:Al:N), and non-doped (ta-C) DLC films were synthesized on AISI 4140 steel using FCVA deposition, and their nanomechanical properties and thermal stability were thoroughly investigated. Raman analysis showed that compressive stress/thickness increased with increasing N and Al—N contents (ta-C:N and ta-C:Al:N) and decreased with increasing Al content (ta-C:Al). Nanomechanical properties including hardness, elastic modulus, and elastic recovery (%*ER*), all decreased significantly in ta-C:Al, except in ta-C:N and ta-C:Al:N —which exhibited relatively high hardness (47.32 and 49.04 GPa) and high *ER* (57.92 and 58.43%) compared to ta-C (51.12 GPa and 60.06%), respectively. Moreover, based on sp^2-hybridized carbon bonding fraction, not more than 0.50, ta-C:Al:N exhibited outstanding thermal stability up to ~600 °C compared to ta-C:Al, ta-C:N, and ta-C tolerating the maximum temperature up to ~RT, ~280, and ~ 400 °C, respectively, as determined using in-situ high-temperature NEXAFS spectroscopy. The ta-C:Al:N thermal stability was enhanced by the formation of Al_2O_3 and sp^3-hybridized N-C bonds, as confirmed using X-ray photoelectron spectroscopy (XPS). Therefore, because co-doping DLC films with Al and N maintained both outstanding nanomechanical properties and high thermal stability, ta-C:Al:N was the preferred candidate for wear and tribological applications, particularly at high temperatures.

CRediT authorship contribution statement

Pornwasa Wongpanya: Conceptualization, Methodology, Validation, Formal analysis, Writing – original draft, Writing – review & editing, Supervision, Project administration, Resources, Funding acquisition. **Praphaphon Silawong:** Formal analysis, Investigation, Visualization, Writing – original draft. **Pat Photongkam:** Conceptualization, Writing – review & editing, Supervision.

Declaration of competing interest

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

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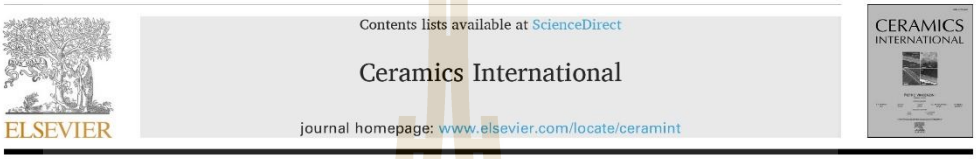
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Adhesion and corrosion of Al–N doped diamond-like carbon films synthesized by filtered cathodic vacuum arc deposition

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ABSTRACT

Diamond-like carbon (DLC) films (thickness: ~118 nm) doped with Al and N on AISI 4140 steel were synthesized using a filtered cathodic vacuum arc technique. The adhesion and corrosion of the ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N films were examined in terms of structure and bonding. X-ray reflectivity, X-ray photoelectron spectroscopy (XPS), and Raman spectroscopy revealed that the Al-doped and Al and N co-doped films had lower densities and internal stresses than the other films, as indicated by their higher I_D/I_G ratios and graphite cluster size (L_a) and lower sp^3 relative fractions. All DLC films exhibited improved corrosion resistance as compared to AISI 4140, as indicated by their decreased corrosion rate and increased corrosion potential and polarization resistance. The corrosion resistances of ta-C:Al:N and ta-C:Al films were high owing to the combined effect of sp^3 C–N and Al_2O_3, as confirmed by near-edge X-ray absorption fine structure spectroscopy and XPS. All doped DLC films exhibited improved adhesion performance compared to the ta-C film owing to their improved lubrication performance (increased sp^3-hybridized C–N bonds) and improved toughness (formation of Al_2O_3).

1. Introduction

Diamond-like carbon (DLC) films have attracted tremendous attention for various engineering applications, including automobiles, electronic devices, tools, and machines, owing to their predominant properties, such as corrosion resistance, wear resistance, low friction, high hardness, and high adhesion [1–6]. These qualities originate from the amorphous DLC structure, which comprises sp^3 tetrahedral and sp^2 trigonal hybridized bonds in diamond and graphite, respectively. DLC films can be synthesized using different techniques, such as plasma-enhanced chemical vapor deposition, magnetron sputtering deposition, pulsed laser deposition, and filtered cathodic vacuum arc (FCVA) deposition [6–8]. As a plasma-based method, FCVA deposition can synthesize hydrogen-free tetrahedral amorphous (ta-C) DLC films with a high sp^3 tetrahedral hybridization fraction (high-quality DLC films) and can reduce the number of macroparticles through the magnetic field coil in the coating system [9–14]. Although DLC films have excellent properties, they exhibit high internal residual stress (σ), which is thickness-dependent and causes cracking, debonding, or delamination from the substrate. Doping with elements (Al, Cr, Si, Ti, Cu, N, Ag, Ni, and W) and utilizing multilayers have been extensively employed to reduce the residual stress of DLC films and improve their adhesion, corrosion resistance, thermal stability, and biocompatibility. However, these methods increase the sp^2-hybridized carbon atoms in DLC films [15–19]. Al and N are promising dopants for improving the adhesion and stress of DLC films [20–22]. Each dopant has a distinct effect on the films. For example, nitrogen significantly improves the adhesion but decreases the hardness of ta-C DLC films. Al notably reduces the stress and does not induce carbide (Al_4C_3) in the films [21]. The combination of Al–N dopants remarkably improves the mechanical properties of DLC films [19,22] by forming C–N and sp^3-N–C/sp^3-C–N bonds.

Previous studies on the effect of doping, particularly Al–N co-doping, on DLC film qualities only focused on the tribological or mechanical properties without assessing the effects of dopants on the corrosion properties of DLC films [20–22]. In addition to the tribological and mechanical properties (e.g., hardness, wear resistance, and high-temperature resistance), the corrosion and adhesion resistance are important to fulfill the engineering application requirements of protective DLC films, which are exposed to friction, corrosive environments, temperature, and humidity during operation.

To date, there are no comprehensive studies on the corrosion behavior related directly to the structure and the adhesion of DLC films

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doped with Al and N. Elucidating this correlation and linking it to a previous study [19], which reported the high-temperature resistance and mechanical properties of the films doped with Al and N on AISI 4140 steel, may improve the lifetime and performance evaluation of DLC films. Pulsed two-FCVA deposition was used in this study to coat pure and doped DLC films with Al and N on AISI 4140 under the coating conditions presented in a previous study [19] (except for the coating time) to describe the structure, adhesion, and corrosion properties of the DLC films. The coating time was varied to obtain the same thickness for all films. This is because the carbon atom arrangement and bonding structure in the DLC film depend significantly on the dopants, although the coating parameters, such as the bias voltage, base pressure, time, and duty cycle, are similar [20,23–25]. The densities (ρ) and thicknesses (t) of the DLC films were determined using X-ray reflectivity (XRR) [23] and field-emission scanning electron microscopy (FE-SEM), respectively. Structural characteristics, such as D and G peaks and their full width at half maximum (FWHM), I_D/I_G ratio, graphite cluster size (L_a), and residual stress (σ) were evaluated by Raman spectroscopy. Prior to the corrosion tests, X-ray photoelectron spectroscopy (XPS) was employed to determine the sp^3/sp^2 ratio, elemental composition, and bonding type of the films. The corrosion behaviors of the AISI 4140 substrate and the pure and Al–N doped DLC films were determined using linear polarization. The corroded DLC-film surfaces were analyzed using near-edge X-ray absorption fine structure (NEXAFS) spectroscopy by means of X-ray photoemission electron microscopy (X-PEEM) and XPS. The film adhesion was analyzed by conducting nanoscratch tests during the movement of the platform. Scratch tracks of the DLC films were examined using SEM with a digital capture system.

2. Experimental procedures

2.1. Film deposition

Two types of substrates, *p*-type (100)-oriented Si and AISI 4140 steel, were cut into 10 mm × 10 mm specimens for the DLC coating. The DLC films coated on Si were subjected to density (ρ) and thickness (t) measurements and then deposited on AISI 4140 steel to investigate their elemental composition, bonding structure, and corrosion and adhesion performance. Before coating, the steel substrates were ground using SiC paper with successive fine grits up to 1500 grit and were then cleaned with ethanol and acetone for 20 min to remove contaminants. Subsequently, they were dried with N_2 gas before being placed in an FCVA chamber. Two vacuum arc plasma sources were designed for use in the FCVA deposition system (Fig. 1). The controlled pressure in the FCVA system was reduced to ~8.0×10^{-4} Pa using a turbomolecular pump prior to coating. The cathodic sources for DLC film deposition were a graphite cathode and an aluminum cathode with an 8 mm diameter rod. The DLC film coating parameters are listed in Table 1. The deposition time was varied to achieve DLC films with a thickness of ~118 nm (Fig. 2). The detailed procedure was explained in a previous study [19].

2.2. Bonding structures, residual stress, and elementary compositions of the DLC films

Raman microscopy (SENTERRA; OPUS; BRUKER, Germany) was used to investigate the bonding structures of the DLC films, which were operated in the backscattering mode with an Ar^+ laser (excitation source: wavelength of 532 nm with a power of 25 mW) [19]. Each film surface was scanned over a wavenumber range of 800–2000 cm^{-1} with a focal spot size of 3 μm^2 and a spectral resolution of 3 cm^{-1}. OriginPro software, Version 2018, was used to fit the Raman spectra into three Gaussian lines. The fitted Raman peaks at 1360 (D-disordered) and 1540 (G-graphite) cm^{-1} and the FWHM of the D and G peaks were used to determine the D–G band intensity ratios (I_D/I_G) of the films [19,20,26]. In addition, σ and L_a of the films were estimated using their I_D/I_G ratios and the shift in the Raman wavenumbers, particularly the G-peak (Δω),

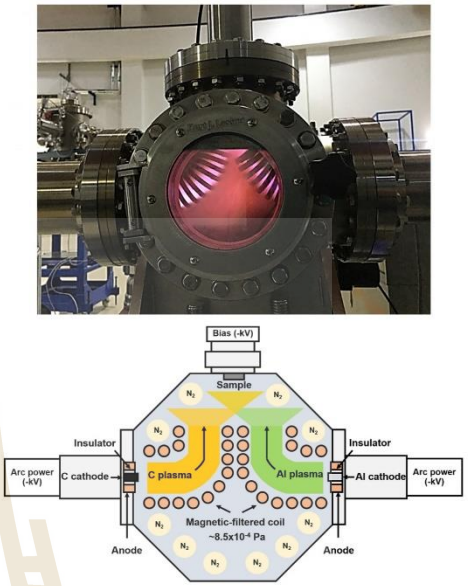


Fig. 1. FCVA deposition system used for the films.

respectively. The equations, including the values of the vital parameters, have been explained in detail in the previous studies [19,23,27–29].

XPS (Kratos AXIS Ultra DLD instrument, Manchester, England) was used to assess the elemental compositions and bonding types of the DLC films using an Al-Kα radiation source at the Chulalongkorn University (Petroleum and Petrochemical College) in Thailand. Prior to XPS analysis, the surface oxides and contaminants were removed by bombarding the surface of the DLC films for 1 min with high-velocity Ar^+ ions accelerated at 1,000 V. A spot size of 0.1 mm was used for the XPS measurements with a pass energy of 46.95 eV and a scanning step of 0.1 eV. The calibration reference for all binding energies was the C *1s* peak at 285 eV. During the measurements, the pressure was maintained below ~5×10^{-5} Pa. The C *1s*, N *1s*, O *1s*, and Al *2p* bonding states and binding energies of the films were quantitatively analyzed from their XPS profiles using the CasaXPS software, and the elemental compositions (at.%) of the films were determined using electron spectroscopy for

Table 1
Coating parameters for the FCVA deposition of the films.

Coating parameters	Preferences
Coating materials (Targets)	Graphite (C) and Aluminum (Al) cathodes
Arc potential applied to cathodes (V_{arc})	400 and 800 V for Al and C
Base pressure	8.5×10^{-4} Pa
Base pressure for N doping	3.0×10^{-2} Pa
UHP N_2 flow rate	2.5 SCCM[a]
Bias voltage applied to cathodes (V_{bias})	1000 V
Duty cycle	0.003%
Frequency	6.0 Hz
Coating time	19, 15, 30, and 22 min for ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N, respectively

[a] SCCM denotes standard cubic centimeters per minute at standard temperature and pressure.

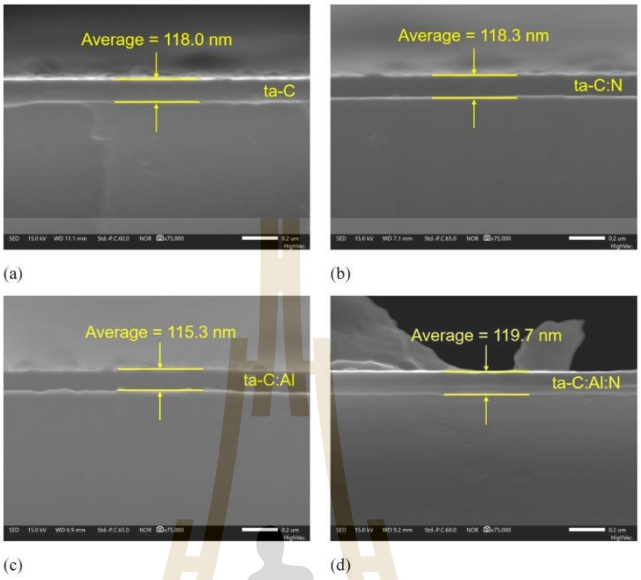


Fig. 2. Thickness of the films.

chemical analysis (ESCA) software: MultiPak Spectrum [19].

The bonding configurations of the films were characterized at the Synchrotron Light Research Institute (BL3.2Ub: PEEM), Nakhon Ratchasima, Thailand, using NEXAFS spectroscopy and spectroscopic photoemission and low-energy electron microscopy (SPELEEM) under UHV ($\sim 3 \times 10^{-8}$ Pa). The beamline monochromatic photon energy was varied from 40 to 1040 eV with an incidence angle of 17° to the film and a linear horizontal polarization. The C *K*-edge and O *K*-edge NEXAFS spectra of the films were obtained by scanning photons over the 270–350 eV and 525–555 eV regions, respectively, in increments of 0.1 eV. The graphitic structures of the films were analyzed and compared with those of highly oriented pyrolytic graphite (HOPG, reference materials) using NEXAFS measurements. In addition, the sp^2-hybridized bond fraction, which is related to the film characteristics, was determined from the C *K*-edge NEXAFS spectra. An essential equation for quantitatively calculating the sp^2-hybridized bond fraction was demonstrated in a recent study [19].

2.3. Thickness, surface roughness, and density of the DLC films

The thicknesses of the DLC films were determined using FE-SEM (JEOL, JSM-IT300HR, Japan) at 75,000 × magnification and an acceleration of 15 kV. The surfaces of the DLC films subjected to the corrosion tests were examined using FE-SEM (AURIGA®; Carl Zeiss, Germany) at an acceleration of 5,000 V. Fig. 3 depicts the surface roughness (Ra) values of all samples, which were determined using an atomic force microscope (AFM) (Park Systems AFM XE-120, South Korea).

The ρ values of the DLC films were calculated using XRR and high-resolution X-ray diffraction (HRXRD) (D8 Advance Bruker, Germany) with a Cu Kα radiation source at a wavelength of 1.541 Å, voltage of 40,000 V, and current of 0.04 A [23,30]. XRR measurements were performed by changing the angle from 0.0 to 3.0° with a scanning step of 0.005°. The DLC film surface was irradiated with X-rays at the grazing angle of incidence. Then, the total reflection occurred at a critical angle (θc), depending on the electronic density of the material [23,30]. The XRR profiles of the DLC films were simulated using Leptos 7.1 software according to Parratt's theory [31]. The θc and interference fringe calculated from the XRR results (reflectivity profiles) were used to determine the electron density of the films. Thus, the ρ values of DLC films can be determined at low angles [23,32,33].

2.4. Corrosion of the DLC films

An Autolab PGSTAT 128 N (Metrohm AG®, Switzerland) with an Ag/AgCl (3 M, KCl) reference electrode, a graphite counter electrode, and the AISI 4140 steel and the DLC films as the working electrodes were used to perform corrosion tests in a 3.5 wt% NaCl solution (pH = ~6.6) at 27 ± 0.5 °C [17,34,35]. The open-circuit potential (OCP) was stabilized by soaking the samples in a NaCl solution for 20 min before starting the tests at a scan rate of 1 mV s^{-1}. This approach significantly reduces the time required for testing and has been widely applied in previous studies [18,36]. The exposure area was fixed at 0.19625 cm^2, and the measurement was performed over a potential range of −150 mV (below the OCP, the cathodic region) to +300 mV (above the OCP, the anodic region) [17].

The important corrosion parameters, that is, the corrosion current density (i_{corr}), corrosion potential (E_{corr}), polarization resistance (R_p), and anodic and cathodic Tafel constants (b_a and b_c, respectively) of the samples, were determined from the acquired polarization curves. Herein, i_{corr} was used to calculate the corrosion rate (*CR*), whereas b_a and b_c were used to determine R_p according to ASTM G102-89 and ASTM G59-97, respectively [37,38]. The density (ρ) values of each film (g cm^{-3}), which were determined from the XRR and HRXRD results and used for calculating *CR*, were 2.52, 2.22, 2.17, and 2.32 g cm^{-3} for ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N, respectively, while the ρ value of the AISI 4140 was 7.85 g cm^{-3}. In addition, the porosity (*P*) and protective

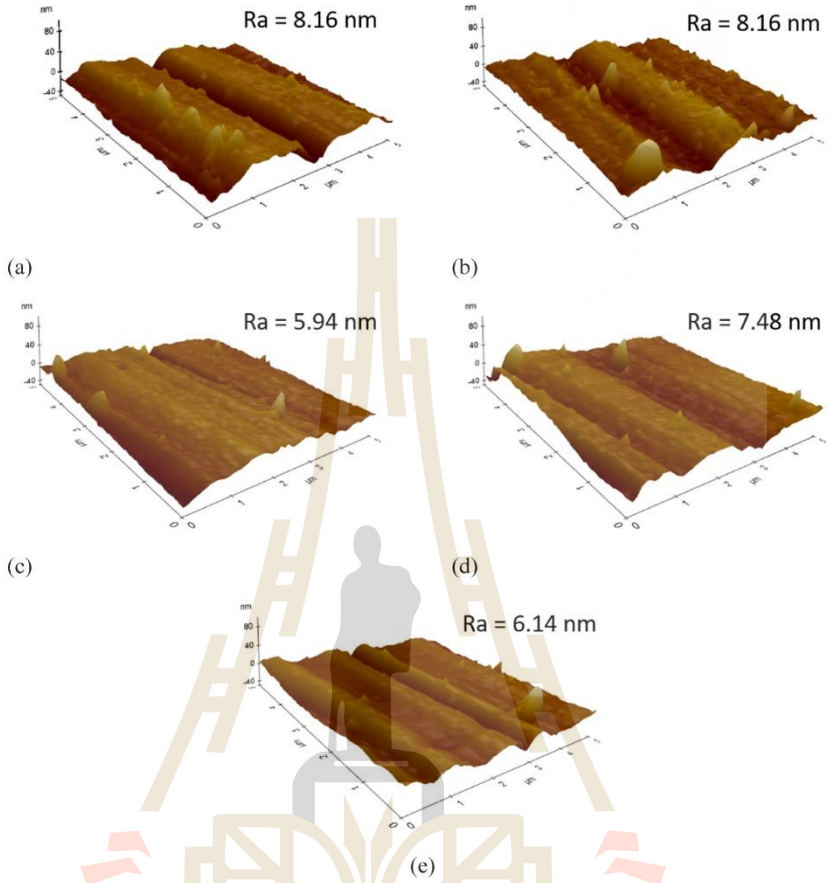


Fig. 3. Surface roughness of the steel substrates and films: (a) AISI 4140, (b) ta-C, (c) ta-C:N, (d) ta-C:Al, and (e) ta-C:Al:N films.

efficiency (P_i), which affect the corrosion resistance of DLC films, were calculated. Related equations have been extensively explained in previous studies [17,39–41].

2.5. Adhesion of the DLC films

Nanoscratch tests were used to evaluate the adhesion of the films during the movement of the platform. Acoustic emission and friction were observed during the scratch test at a temperature of 27 ± 0.5 °C and relative humidity of ~50%. Each DLC film was scratch-tested three times using a conical diamond tip with a 90° angle and 5 μm final radius. A pre-scratching procedure is necessary to eliminate the effects of instrument bending surface topography, slope, and roughness [42,43]. During the scratch process, three sequential scans were performed at a trajectory of 12.30 μm s^{-1} across a scan length of 5000 μm: (i) an initial scan at 0.50 mN with a constant load, (ii) a scratch scan at a loading rate of 1.0 mN s^{-1}; the load was increased after every 10 μm to the maximum load of 400 mN, and (iii) the final scan at a constant load of 0.50 mN over the scratched track. In addition, to avoid the thermal side effect, which causes degradation (graphitization) of the DLC films, an extremely low speed was maintained. Finally, scratch tracks were examined using SEM and a digital capture system.

3. Results and discussion

3.1. Structure, residual stress, elementary composition, and bonding type of the DLC films

As the most popular non-destructive technique, Raman spectroscopy was extensively employed to characterize the bonding structure (D and G peaks and their FWHM, I_D/I_G ratio, and L_a) and residual stress (σ) of the DLC films [26,44,45]. Fig. 4 shows the Raman spectra of the DLC films measured over the wavenumber range of 800–2000 cm^{-1}. Their Raman spectra could be deconvoluted into two peaks: (i) the D peak at 1360 cm^{-1} corresponding to the disordered structure of the six-fold aromatic rings, known as the breathing mode or aromatic ring vibrations,

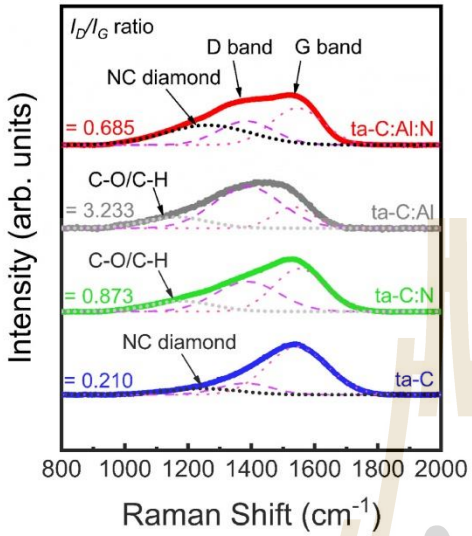


Fig. 4. Raman spectra of the films.

and (ii) the G peak at 1540 cm^{-1} corresponding to the vibrations in the carbon chain and aromatic ring, as well as the other bands at 1140–1260 cm^{-1} corresponding to the sp^2-hybridized carbon, sp^3-hybridized carbon, and hydrogen content [46–49]. Table 2 summarizes the Raman spectroscopy results. Evidently, the G peaks of the pure (ta-C), N-doped (ta-C:N), Al-doped (ta-C:Al), and Al-N-doped (ta-C:Al:N) DLC films were observed at ~1544.18, ~1551.26, ~1532.97, and ~1544.93 cm^{-1}, respectively, which is consistent with previously reported results [19]. Compared to the G peak of ta-C, those of ta-C:N and ta-C:Al:N shifted to higher wavenumbers, whereas that of ta-C:Al shifted to a lower wavenumber. The decrease in the film thickness from ~180 [19] to ~118 nm slightly impacted the I_D/I_G ratio, L_a, and σ, as shown in Table 3. Doping with N, Al, or Al–N significantly increased the I_D/I_G ratio and rapidly decreased the FWHM (G) of the ta-C film, indicating the presence of larger graphite clusters (L_a) at the sp^2-hybridized carbon sites [23,26]. The increased I_D/I_G ratio of the doped films was due to the increased sp^2-hybridized carbon content of their aromatic ring structures, which resulted in decreased sp^3-hybridized carbon content. Raman spectroscopy results showed that all the dopants transformed the structure of the ta-C film into a graphitic sp^2-hybridized carbon structure and decreased its sp^3-hybridized carbon content. The internal compressive stress of a material is related to its atomic vibration frequency, which is proportional to the wavenumber obtained from its Raman spectrum. The Raman results (wavenumbers) were used to calculate the compressive stress (σ) of the DLC films [50–52]. The σ values of the ta-C:N, ta-C:Al, and ta-C:Al:N films were 1.193, -1.886, and 0.127 GPa, respectively, corresponding to the G peak shifting to higher (increase in σ) or lower (decrease in σ) wavenumbers compared to that of the ta-C film [50–52]. The σ of the DLC films notably impacted the sp^3 to sp^2 transformation of the carbon-bonding structure [21,51]. The sp^3 to sp^2 transformation of the carbon bonding structure in the high-σ DLC films (ta-C:N and ta-C:Al:N) was less significant than that in the low-σ DLC film (ta-C:Al), as indicated by the sp^3-hybridized C–C percentage and relative sp^3 fraction (Fig. 5(a)). These results are consistent with those previously reported [19,21,51].

XPS analysis was used to quantify the elemental compositions (Table 3), chemical bonding types, and sp^3 contents (sp^3/sp^2 ratio and relative sp^3 fraction) of the DLC films (Fig. 5). The ta-C:N and ta-C:Al:N films contained approximately 11.46 and 13.99 at.% N, respectively. The Al contents of the ta-C:Al and ta-C:Al:N films were approximately 5.05 and 7.59 at.%, respectively; O readily formed oxide with Al. Therefore, the atomic concentration (at.%) of O increased as the Al doping amount increased [22]. All films exhibited peaks corresponding to Al, C, and N (main components), along with O peaks (present as oxides and impurities). The C *1s*, O *1s*, N *1s*, and Al *2p* peaks of the films were deconvoluted into clear Gaussian–Lorentzian peaks using Shirley backgrounds to quantify the bonds (at.%) in the films [19,53]. The deconvoluted C *1s* profiles of all the DLC films exhibited peaks at ~283.50–284.54, 284.19–285.02, 285.50–286.54, 285.20–287.45, and 286–288 eV, corresponding to the C=C (sp^2-hybridized carbon atoms), C–C (sp^3-hybridized carbon atoms), sp^2-hybridized C=N, sp^3-hybridized C–N, and C–OH, C–O, or C=O bonds, respectively. No *sp*-hybridized C≡N bonds (286.70 eV) were detected [19,22,23,44,45,53–57]. The weak peak at ~282.2 eV for the ta-C:Al and ta-C:Al:N films corresponded to the Al–O–C bond, indicating that the exposure of these films to air caused contamination [58]. The C content (at.%), sp^3-hybridized C–C content, sp^3/sp^2 ratio, and relative of sp^3 fraction of the ta-C film decreased after Al, N, and Al–N doping. Unlike the single-doped films (40.52% and 38.81% for ta-C:N and ta-C:Al, respectively), the Al–N co-doped film (50.65%) exhibited a slightly reduced sp^3-hybridized C–C bond percentage compared to the ta-C film (68.95%). A smaller relative sp^3 fraction corresponds to larger sp^2-bonded clusters (L_a) [59] and I_D/I_G ratios, as shown in Table 2. The deconvoluted O *1s* spectra exhibited peaks at ~532.0–533.4 eV, consistent with the C–O, C–OH, and C=O bonds, owing to the reaction between O and C on the film surface; a peak was also observed at ~530.50 eV, corresponding to the N–O and O=C–OH bonds on the DLC film surface [17,60]. The deconvoluted N *1s* spectra of the ta-C:N and ta-C:Al:N films exhibited peaks at ~397.50–399.40, 399.10–400.60, and 401.5–402.9 eV, corresponding to the sp^3-hybridized C–N, sp^2-hybridized C=N, and N–O bonds, respectively [22,45,53]. The ta-C:Al:N film exhibited more

Table 3
Elemental compositions and densities of the films, as measured using XPS and XRR, respectively.

Sample	Concentration (at.%)				Density (ρ)
	C *1s*	O *1s*	N *1s*	Al *2p*	g cm^{-3}
ta-C	90.65	9.35	–	–	2.52
ta-C:N	79.57	8.97	11.46	–	2.22
ta-C:Al	78.23	16.72	–	5.05	2.17
ta-C:Al:N	58.76	19.67	13.99	7.59	2.32

Table 2
Raman analysis results of the films.

Sample	Results						
	D Peak (cm^{-1})	G Peak (cm^{-1})	FWHM of D peak (cm^{-1})	FWHM of G peak (cm^{-1})	I_D/I_G ratio	L_a (nm)	σ (GPa)
ta-C	1379.58	1544.18	196.61	223.94	0.210	6.185	0.000
ta-C:N	1389.18	1551.26	236.43	189.52	0.873	12.601	1.193
ta-C:Al	1387.53	1532.97	249.93	151.65	3.233	24.246	-1.886
ta C:Al:N	1383.84	1544.93	205.09	193.93	0.685	11.159	0.127

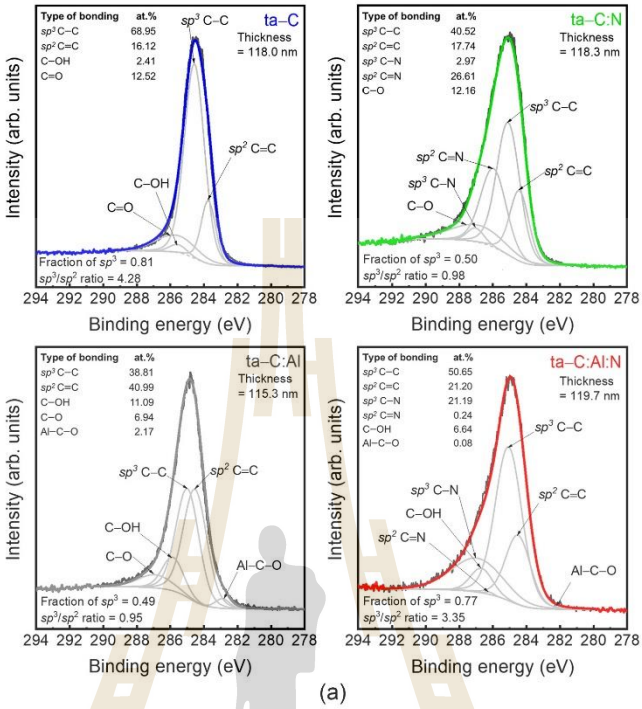


Fig. 5. XPS profiles and deconvoluted Gaussian peaks of the films before the corrosion tests: (a) C *1s*, (b) O *1s*, (c) N *1s*, and (d) Al *2p*.

sp^3-hybridized C–N bonds than the ta-C:N film. In addition, the sp^2-hybridized C=N bonds in the ta-C:N film notably reduced the sp^3-bonded N and C fractions [19]. The deconvoluted Al *2p* spectrum exhibited two peaks at ~73.54 and ~74.24 eV, corresponding to AlO_x and Al_2O_3, respectively. A previous study demonstrated that the combination of Al_2O_3 with sp^3-hybridized C–N bonds remarkably inhibited the thermal degradation (graphitization) of DLC films [19].

Fig. 6 depicts the NEXAFS spectra used to analyze the local atomic structures and sp^2 fractions of the DLC films. The NEXAFS intensity of clean Si(001) was used to normalize the C *K*-edge NEXAFS spectra of all the DLC films. The normalized C *K*-edge NEXAFS spectra of all the films are shown in Fig. 6(a). Two energy edges were observed: (i) one at ~285.4 eV, corresponding to excitations from C *1s* to the empty π* state of the sp^2-hybridized C=C and *sp*-hybridized C≡C sites, and (ii) the other at ~288–335 eV, related to the C *1s* transport to the empty σ* states at the *sp*-, sp^2-, and sp^3-hybridized sites in the films [17,19,61,62]. The middle area between the π* and σ* states corresponded to the excitations of the following states: C *1s*→π* (C=C), π* (C=N), π* (C=OH), σ* (C–H), σ* (C–N), π* (C=O) or π* (C≡C), σ* (C–C), and σ* (C=C) at ~285.1, 285.9, 286.3, 287.6, 287.7, 288.5, 289.6, and 293.7 eV, respectively [19,63,64]. However, the peaks at ~297.8 and ~304.3 eV corresponded to the C *1s* transitions to the σ* (C–O) and σ* (C≡C) states, respectively [61,64]. The sp^2 fractions of the ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N films were 0.345, 0.394, 0.538, and 0.348, respectively, as shown in Fig. 6(a). Notably, single dopants (N or Al) enhanced the graphitization of the ta-C film, as indicated by the increased sp^2 fraction after N or Al doping. Conversely, Al–N co-doping slightly induced graphitization in the film, which correlates with the XPS results in Fig. 5(a). Fig. 6(b) shows the O *K*-edge NEXAFS spectra, indicating the occurrence of film surface oxidation. Two peak regions were detected: (i) at ~531.2 eV defined as the O *1s*→π* excitations from the carbonyl and carboxyl groups of the O atoms double-bonded to the C atoms (C=O), and (ii) at ~533.6, ~536.0, and ~540.0 eV corresponding to O *1s*→π* (C–O), σ* –OH, and the excitation of the O *1s* to the σ* C–O and C=O states, respectively [18,65,66]. A broad peak was observed at ~540.0 eV, corresponding to Al_2O_3 combined with C=O. This peak was more significant in Al-doped DLC films than in non-Al-doped DLC films [67]. In addition, the C=O (~531.2 eV) peak intensity of the Al-doped DLC films was lower than that of the non-Al-doped DLC films. The N *K*-edge was only detected for the N-doped DLC films, indicating that N was successfully added to these DLC films. The sharp π* peak split into four distinct peaks at ~398.40 (N1), 399.50 (N2), 401.50 (N3), and 403.5 eV (N–O) corresponding to the sp^3-hybridized C–N, sp^2-hybridized C=N, substitutional nitrogen in the hexagonal graphitic structure, and N–O, respectively [68,69]. The ta-C:N film showed three peaks: N2 and N3 at ~399.50 and 401.50 eV with moderate intensities and N1 at ~398.40 eV with low intensity. In contrast, the ta-C:Al:N film exhibited N1 and N2 peaks with high and moderate intensities, respectively. No N3 peak was detected for this film, which could be attributed to the fact that N bonded with C to form substantial amounts of N1 (81.99 at.% of sp^3-hybridized C–N, as indicated by the XPS results) and N2 (11.33 at.% of sp^2-hybridized C=N). The NEXAFS results were consistent with the XPS results.

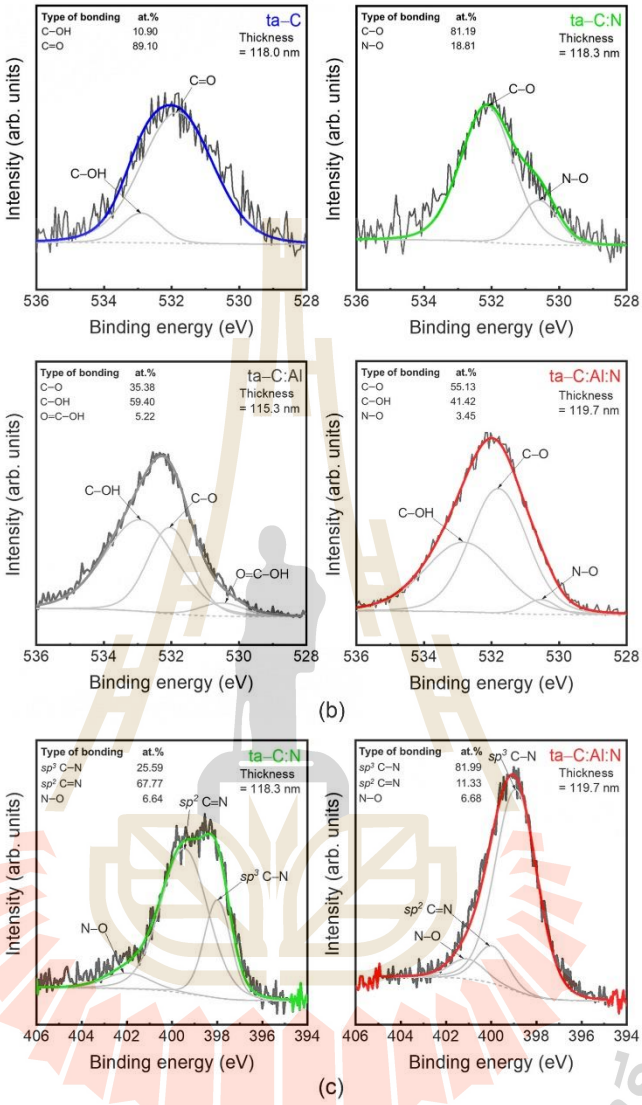
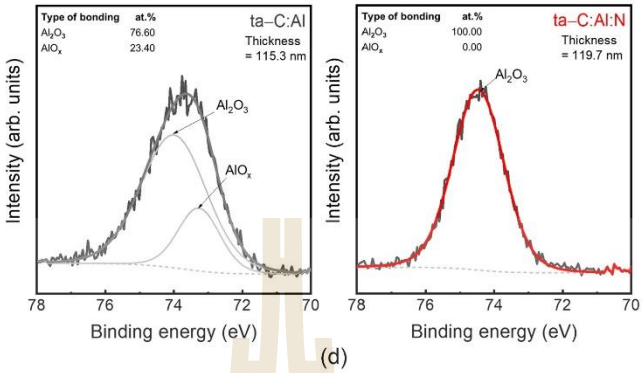


Fig. 5. (*continued*).

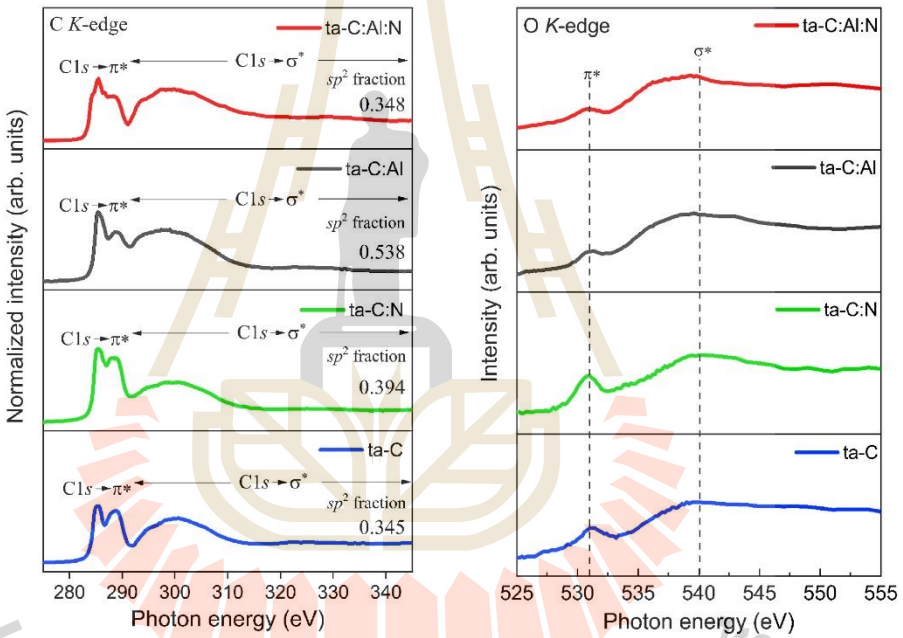
3.2. *Thickness, roughness, and density of the DLC films*

The thickness of the ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N films (Fig. 2) were 118.0, 118.3, 115.3, and 119.7 nm, respectively, and the corresponding deposition times were 19, 15, 30, and 22 min. Although the DLC film deposition times were different, the pressure, bias voltage, and duty cycle (coating parameters) were the same because the carbon atom arrangement in the DLC film chains and aromatic rings were affected by the doping element and bonding structure of the films [19,20,23,25]. In addition, the thickness of the DLC films depended on their σ. For example, the thickness increased as σ increased in the case of ta-C:N and ta-C:Al:N and decreased as σ decreased in the case of ta-C:Al. The ta-C:N



(d)

Fig. 5. (*continued*).

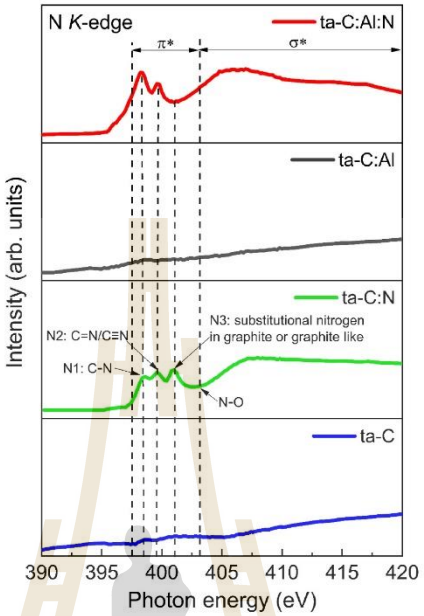


(a). (b).

Fig. 6. NEXAFS spectra of the films before the corrosion tests: (a) C *K*-edge, (b) O *K*-edge, and (c) N *K*-edge.

film reached the desired thickness in the shortest deposition time owing to the presence of high-energy N atoms at an appropriate flow rate [20]. The ta-C:Al film took more time to attain the same thickness because of the collision of Al and C ions during the coating, which resulted in the coating of fewer C ions and carbon bond formation in the film [19,21].

The surface roughness (R_a) value of the substrate (before DLC coating) was 8.16 nm, whereas those of the ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N DLC films were 8.16, 5.94, 7.48, and 6.14 nm, respectively (Fig. 3). The surface of the substrate was clean. Macroparticles were only observed on ta-C; they were rarely found on the other samples.



(c).

Fig. 6. (*continued*).

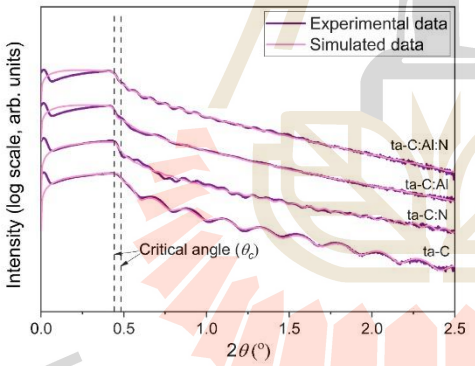


Fig. 7. XRR profiles of the films.

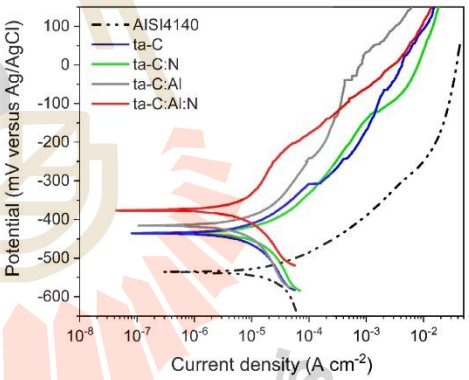


Fig. 8. Potentiodynamic polarization curves of the steel substrates and films in a 3.5 wt% NaCl solution.

Fig. 7 shows the XRR results at different incident angles (0.0–2.5°) and a scanning step of 0.005°. The violet and pink curves represent the experimental and simulated XRR results, respectively. The ρ values of ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N films were 2.52, 2.22, 2.17, and 2.32 g cm^{-3}, respectively, as estimated by the equation presented in previous reports [23,32,33]. The density decreased with the addition of the dopants. This decrease corresponded to an increase in the I_D/I_G ratio and L_a as well as a decrease in the relative sp^3 fraction (Table 2 and Fig. 5(a)) [23].

3.3. Corrosion performance of the DLC films

Fig. 8 depicts the polarization curves of the samples subjected to corrosion testing in a 3.5 wt% NaCl solution. The essential corrosion parameters of the films, including b_a, b_c, E_{corr}, i_{corr}, E_{pit}, i_p, R_p, CR, P, and P_i, were calculated and are presented in Table 4. Three distinct zones

Table 4
Corrosion test results for the samples tested electrochemically in a 3.5 wt% NaCl solution.

Sample	E_{corr} (mV)	i_{corr} (μA cm^{-2})	b_a (mV dec^{-1})	b_c (mV dec^{-1})	E_{pit} (mV)	i_p (μA cm^{-2})	R_p (Ω cm^2)	CR (mm yr^{-1})	P	P_i (%)
AISI 4140	-547.44	10.30	40.38	53.13	–	–	967.20	1.22×10^{-1}	–	–
ta-C	-443.31	2.39	44.76	46.79	-310.06	46.50	4156.17	1.01×10^{-4}	1.09×10^{-3}	76.79
ta-C:N	-442.69	4.54	39.53	43.47	-126.66	354.00	1980.11	2.14×10^{-4}	1.09×10^{-3}	55.92
ta-C:Al	-425.08	2.29	39.80	42.36	-44.23	184.00	3890.89	1.28×10^{-4}	2.09×10^{-4}	77.77
ta C:Al:N	382.93	2.14	43.12	40.49	201.13	22.20	4237.02	1.17×10^{-4}	3.49×10^{-5}	79.22

(active, passive, and transpassive) were observed in the polarization curves of the DLC-coated steels. The bare 4140 steel exhibited no passive region and no pitting resistance, indicating a lower corrosion resistance than that of the DLC-coated steels. Their E_{corr} and i_{corr} values correlated with the previously reported results for steel [34,35]. The DLC films remarkably strengthened the corrosion resistance of the AISI 4140 steel, as indicated by the decrease in i_{corr} and CR, as well as the increase in E_{corr}, E_{pit}, and R_p (as compared to those of the 4140 steel). The CR and i_{corr} of all DLC films were in the same range and were three orders of magnitude lower than those of 4140 steel. However, the Al-doped and Al-N codoped DLC films were more steady than the pure and N-doped DLC films, as indicated by their more positive E_{corr} values (-443.31, -442.69, -425.08, and -382.93 mV for ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N, respectively). The R_p values of the DLC films were 2–5 orders of magnitude higher than those of 4140 steel. These large R_p values indicated the outstanding corrosion resistance confirmed by the linear potentiodynamic polarization test [35,39,70,71]. The porosity (P) of the films degrades the protective efficiency (P_i) of the films, as shown in Table 4 [17,35,39]. The ta-C:N and ta-C films exhibited a high P value of 1.09×10^{-3}, whereas the ta-C:Al and ta-C:Al:N films exhibited low P values of 2.09×10^{-4} and 3.49×10^{-5}, respectively, corresponding to the increase in P_i values for ta-C:Al and ta-C:Al:N. The ta-C:Al:N film exhibited the best corrosion resistance among all DLC films investigated, followed by the ta-C:Al film. The high corrosion resistance of the ta-C:Al and ta-C:Al:N films can be attributed to their high R_p (3890.89 and 4237.02 Ω cm^2), high P_i (77.77 and 79.22%), and low P (2.09×10^{-4} and 3.49×10^{-5}) caused by the synergy between the Al oxide and sp^3 C–N bonds. The Al oxide functioned as a barrier against the catastrophe caused by aggressive surroundings [17,19,21,22]. These values (high R_p, high P_i, and low P for the ta-C:Al and ta-C:Al:N films) were consistent with those of previous reports [17,35,39,70,71]; the films reduced the corrosion of the steel substrate by inhibiting corrosive ions in the solution from attacking the substrate.

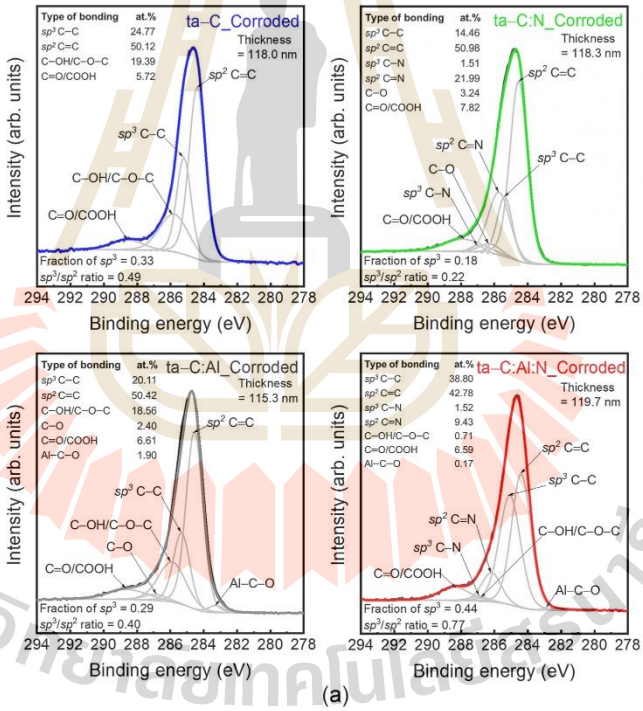


Fig. 9. XPS profiles and deconvoluted Gaussian peaks of the films after the corrosion tests: (a) C *1s*, (b) O *1s*, (c) N *1s*, (d) Al *2p*, and (e) Fe *2p*.

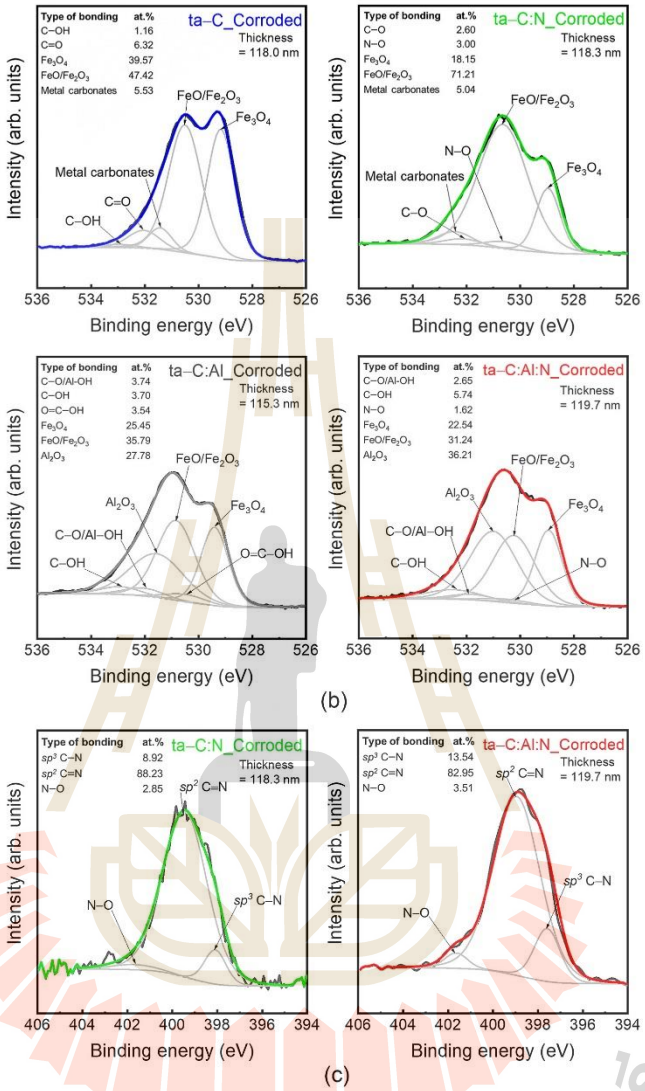


Fig. 9. (*continued*).

3.4. Structural analysis after the corrosion tests

Following the corrosion tests, the bonding structures of the DLC films were examined by XPS and NEXAFS spectroscopy. In addition to C, N, and Al as the main elements and O as the contaminant, Fe was also detected owing to the corrosion of the metal substrate. This demonstrates that the films degraded after the corrosion test. The sp^3-hybridized C–C bond percentage, sp^3/sp^2 ratio, and relative sp^3 fraction of all the DLC films decreased significantly owing to their corrosion, as indicated by their C *1s* profiles (Fig. 9). The corrosion reaction transformed the sp^3-hybridized C–C bonds into sp^2-hybridized C=C bonds [18,72]. The decrease in the sp^3-hybridized C–C bond percentage of the Al-N co-doped, Al-doped, and N-doped DLC films (11.85, 18.70, and 26.06 at.%, respectively) was less than that in the sp^3-hybridized C–C

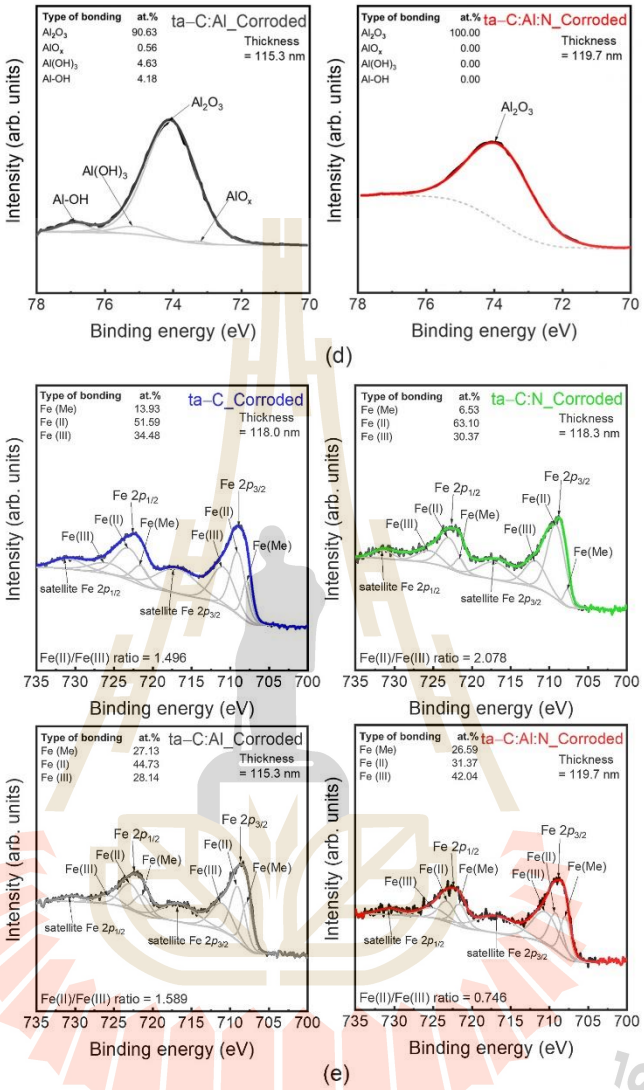


Fig. 9. (*continued*).

bond percentage of the pure DLC film (44.18 at.%). This indicated that Al and N inhibited the degradation of the films [17,18]. The suppressed graphitization of all the doped DLC films can be attributed to nitride (sp^3-hybridized C–N) and aluminum oxide (Al_2O_3), as indicated by the changes in the N *1s* and Al *2p* profiles (Figs. 5 and 9, respectively). For example, considerable sp^3-hybridized C–N combined with Al_2O_3 (81.99 and 100 at.%, respectively (Fig. 5)) in ta-C:Al:N before the corrosion test. The sp^3-hybridized C–N transformed into sp^2-hybridized C=N combined with Al_2O_3 (82.95 and 100 at.%, respectively (Fig. 9)) after the corrosion reaction, indicating that the sp^3-hybridized C–N bonds were consumed during the corrosion. Therefore, graphitization (degradation) of the sp^3-hybridized C–C bond was inhibited. The ta-C:Al and ta-C:N films also exhibited degradation because of the presence of a mixture of Al_2O_3 and AlO_x (76.60 and 23.40 at.%, respectively, Fig. 5

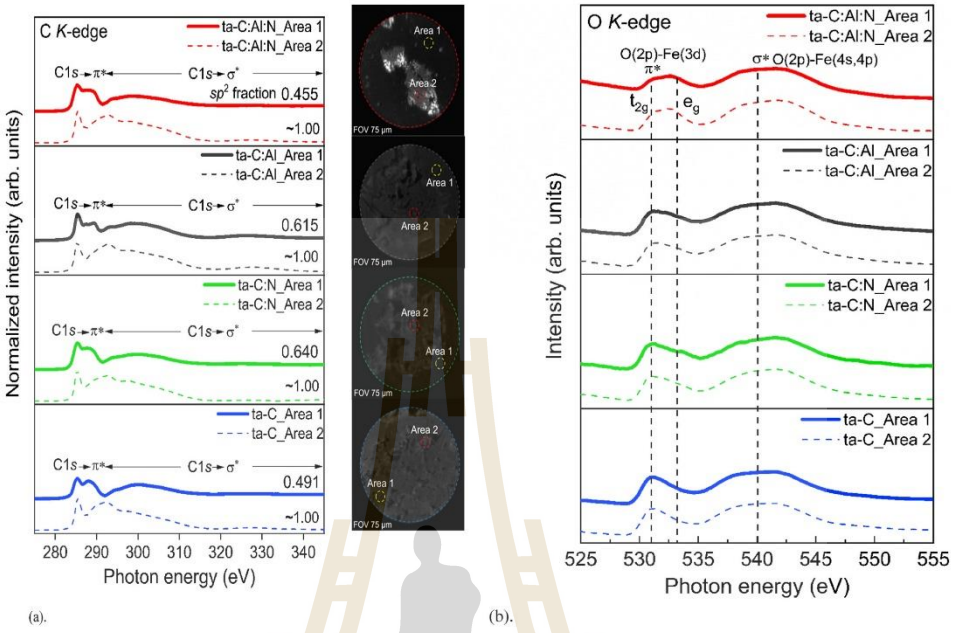
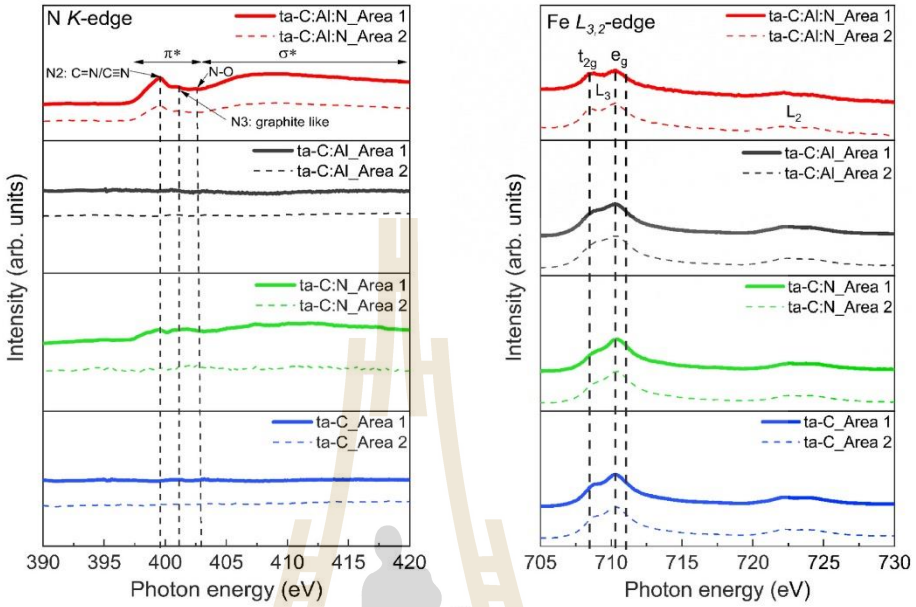


Fig. 10. NEXAFS spectra of the films after the corrosion tests: (a) C *K*-edge, (b) O *K*-edge, (c) N *K*-edge, and (d) Fe $L_{3,2}$-edge.

(d)) and the low sp^3-hybridized C–N content (25.59 at.%, Fig. 5(c)), respectively. However, their degradation was higher than that of ta-C:Al:N because the sp^3-hybridized C–C content was lower than that of ta-C:Al:N (20.11, 14.46, and 38.80 at.% for ta-C:Al, ta-C:N, and ta-C:Al:N, respectively, Fig. 9(a)). Therefore, the contribution of various factors to the corrosion resistance of the NaCl solution decreased in the following order: sp^3-hybridized C–N bonds + Al_2O_3 > Al_2O_3 > sp^3-hybridized C–N, as confirmed by the slow decrease in the sp^3-hybridized C–C bond percentage for ta-C:Al:N, ta-C:Al, and ta-C:N. The synergistic effect of the sp^3-hybridized C–N bonds and Al_2O_3 contributed the most to improving the corrosion resistance of the DLC films in the corrosive solution. This effect also inhibits the graphitization (degradation) of DLC films at high temperatures [19]. Al_2O_3 also inhibits the corrosion of DLC films in aqueous solutions (in this work). However, previous reports reveal that Al_2O_3 alone cannot inhibit the graphitization (degradation) of DLC films at high temperatures [19]. Only the sp^3-hybridized C–N bonds reduced the graphitization of the films at high temperatures. However, their contribution to the corrosion resistance of the films was insignificant in this investigation.

The degradation of the DLC films was confirmed by Fe *2p* XPS results (Fig. 9(e)). Peaks corresponding to Fe (metal) and Fe compounds, including Fe(II) (FeO and Fe_3O_4), Fe(III) (Fe_2O_3 and Fe_3O_4), and Fe(III) (FeOOH), were observed at ~707.0, 709.6, 710.8, and 711.8 eV, respectively [73–75]. All DLC films degraded until the metal substrate (Fe) was detected. The oxidation of Fe to Fe^{2+} ions resulted in the formation of Fe(II) oxides. In corrosive environments enriched with oxygen and water, Fe(II) oxides were further oxidized to Fe(III) oxides [76]. Fe(II) and Fe(III) compounds were detected in all films, but with varying concentrations. The Fe(II)/Fe(III) ratio was used to evaluate the stability of Fe-oxide films, and the following trend was observed: ta-C:Al:N < ta-C < ta-C:Al < ta-C:N. More stable Fe oxides led to higher degradation of the film. In addition, to confirm the reaction between O and C or metals (Al and Fe in this study) after corrosion, O *1s* XPS profiles of the films were obtained after the corrosion test. In addition to the peaks at ~530.50 eV and ~532.0–533.4 eV (corresponding to N–O/O=C–OH and C–O, C–OH, and C=O, respectively, prior to corrosion) [17,60], a peak corresponding to Al/Fe oxides (O^{2-}) was detected at ~530.3 eV [17,18,74,77,78].

After corrosion, changes in the structural bonding of the DLC films in different regions, including the mildly (Area 1) and severely (Area 2) corroded zones, were examined using X-PEEM and NEXAFS spectroscopy (Fig. 10). The NEXAFS C *K*-edge spectra for Areas 1 and 2 revealed distinct features, as shown in Fig. 10(a). In Area 2, the peaks at ~285.4 and 292.0 eV may be attributed to the excitation of the C *1s* electrons to the empty π^* and σ^* states at the sp^2-hybridized site [17,18,64], corresponding to the increased sp^2-hybridized bond fraction of all the films (before corrosion, Fig. 6(a)). The bond fractions increased from 0.345, 0.394, 0.538, and 0.348 to ~1.00 for ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N, respectively, owing to their severe corrosion. These transitions, particularly that at ~ 292.0 eV, could not be observed in Area 1. This can be attributed to the slight increase in the sp^2 fractions of ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N to 0.491, 0.640, 0.615, and 0.455, respectively, owing to mild corrosion. These results indicated graphitization (degradation) of the films after corrosion testing and were consistent with the XPS results. The NEXAFS O *K*-edge spectra of Areas 1 and 2 for the DLC films subjected to corrosion testing were homologous with those of the films prior to corrosion testing. However, additional strong peaks were observed at ~533 and 540.0 eV, corresponding to the hybridization of O



(c). (d).

Fig. 10. (*continued*).

2p with *3d* and *4s* and *4p* metals, respectively, as well as the O 1*s*→σ* (C–O and C=O) transformations (~540.0 eV) [79–81], indicating deterioration of the films and the evolution of Fe oxides after the corrosion reaction. sp^3-hybridized C–N was hardly observed in the corroded areas of the ta-C:N and ta-C:Al:N films; however, sp^2-hybridized C=N was still observed, indicating that the sp^3-hybridized C–N bonds significantly degraded and transformed owing to the corrosion, as shown in Fig. 10(c). These results correlated with the XPS results obtained after the corrosion test and confirmed that the sp^3-hybridized C–N bonds transformed into sp^2-hybridized C=N bonds during corrosion. The NEXAFS Fe $L_{3,2}$-edge spectra of all DLC films exhibited peaks at ~708, 710.1, and 711 eV, corresponding to Fe (metal), Fe(II) (FeO and Fe_3O_4), and Fe(III) (Fe_2O_3, Fe_3O_4, and FeOOH), respectively [82,83]. All DLC films subjected to corrosion testing contained Fe, Fe(II), and Fe(III). The Fe(II) peak was slightly stronger than the Fe(III) peak, particularly for ta-C, ta-C:N, and ta-C:Al. This was consistent with the XPS results.

3.5. Adhesion analysis

Fig. 11 displays the scratch test results and SEM images of the films subjected to the scratch test. These results were used to assess the adhesion failures of the films. Two distinct stages of critical load (L_c) were observed. In the first stage (L_{c1}), the applied load caused the first failure of the DLC films, such as plastic deformation, edge cracks, and fine cracks. In the second stage (L_{c2}), the applied critical normal load caused adhesion failure, including the first delamination and transverse cracking of the DLC films [17,43]. The L_{c1} values of the ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N films were 126.57, 87.75, 65.16, and 99.60 mN. The L_{c1} values of the films decreased in the following order: ta-C > ta-C:Al:N > ta-C:N > ta-C:Al. The L_{c1} values of the DLC films doped with Al and N in this study are consistent with the hardness (*H*), elastic recovery (*%ER*), and elastic modulus (*E*) of the DLC films reported previously [19]. The *H* values of the ta-C, ta-C:Al:N, ta-C:N, and ta-C:Al films were 51.12, 49.04, 47.32, and 38.84 GPa, respectively, and their corresponding *%ER* values were 60.06, 58.43, 57.92, and 50.47. In addition, the *E* values for the ta-C, ta-C:Al:N, ta-C:N, and ta-C:Al films were 302.29, 251.09, 210.51, and 159.65 GPa, respectively [19]. The ta-C film exhibited the highest L_{c1} value, as indicated by its high *H*, *%ER*, and *E* values, which can be attributed to its high sp^3 content and elastic strain relaxation. Thus, the ta-C film was able to recover without deformation and exhibited a higher cohesive strength (L_{c1}) than other DLC films [84,85]. However, the trend of the L_{c2} values was dissimilar to that of the L_{c1} values of the films, and their values decreased in the following order: ta-C:Al:N > ta-C:Al > ta-C > ta-C:N. Al and Al-N co-doping increased the L_{c2} of the ta-C film by decreasing its internal stress (σ) and friction coefficient [58] and increasing its graphite cluster size (L_a) and sp^3-hybridized C–N content (only for ta-C:Al:N) [22,58]. In contrast, ta-C:N exhibited the lowest L_{c2} owing to its high σ. This indicated that the adhesion failure resistance of the films was not directly attributed to *E* and *H* [17,86,87]. It is necessary to consider other parameters to estimate the performance of a protective coating that is intensively deformed during service (elastic strain to failure to indicate wear resistance). The plastic index parameter (*H*/*E*) was primarily considered [17,19,87], and their values were 0.169, 0.225, 0.243, and 0.195 for the ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N films, respectively [19]. DLC films doped with Al, N, or Al–N exhibited higher *H*/*E* values than the pure DLC film. Hence, all dopants seemingly enhanced the adhesion failure resistance of the DLC films. In addition to *H*/*E*, the toughness combining both the elastic-plastic behavior and wear resistance of DLC films should be dependent on the scratch crack propagation resistance (CPRs) and is determined using Eq. (1) [22]:

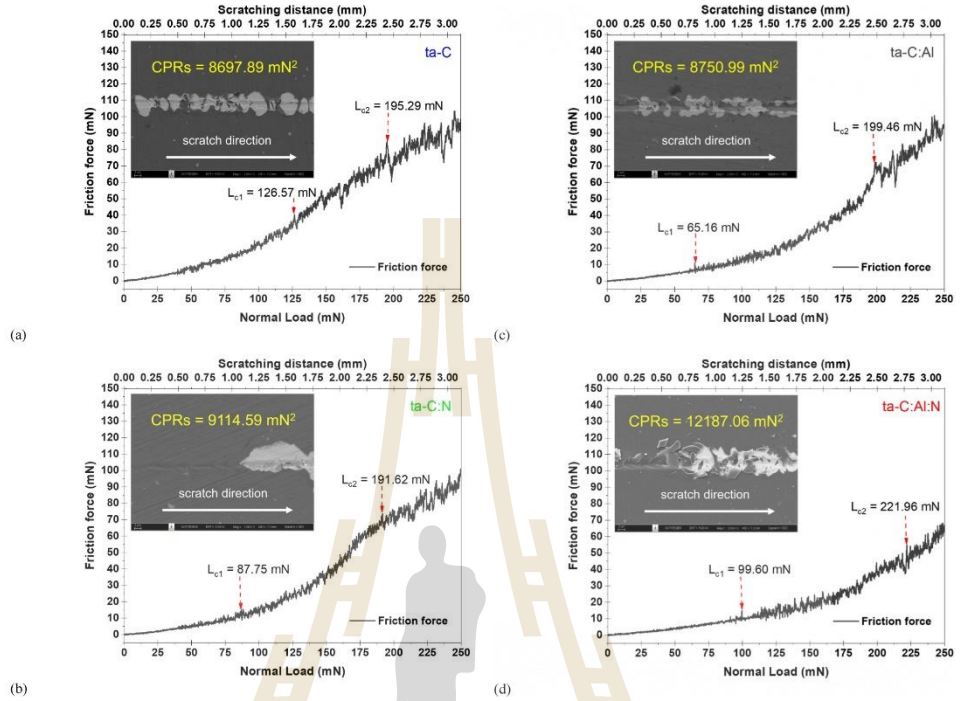


Fig. 11. Scratch curves and SEM images of the scratch tracks at L_{c1} and L_{c2} for the films.

$$CPRs = L_{c1} \times (L_{c2} - L_{c1}) \quad (1)$$

The CPRs of the DLC films decreased in the following order: ta-C:Al:N > ta-C:N > ta-C:Al > ta-C. The dopants improved the scratch crack propagation resistance of the ta-C film, and the ta-C:Al:N film exhibited the highest CPRs. The insets in Fig. 11(a)–(d) show SEM images of the scratch tracks for the DLC films at L_{c2}, which were severely damaged and torn from the substrate, indicating a decrease in their adhesion strength. The ta-C:N and ta-C films exhibited brittle fracture, and the ta-C film exhibited cracks and splits along the scratch-track sides. The wear tracks were deeper and broader for ta-C:Al and ta-C:Al:N, indicating deformation and complete delamination of the films. However, the increased adhesion strength of the N-doped, Al-doped, and Al-N co-doped DLC films compared to that of the ta-C film can be attributed to the reduction in their residual stress, as indicated by the Raman spectroscopy results (Table 2). The residual stress of DLC films is directly related to the elastic energy stored in them. Therefore, the higher the residual stress of the film, the higher the elastic energy stored within. This high elastic energy causes the film to separate from the substrate. If the adhesion energy between the DLC film and steel substrate is insufficient, the coated film will delaminate [17]. In addition, the improved lubrication performance or friction-reducing characteristics of the doped DLC films can be attributed to the increase in their sp^3-hybridized C–N content or the formation of Al_2O_3 (significantly improved toughness compared to ta-C) [20,56,58].

4. Conclusions

ta-C, ta-C:N, ta-C:Al, and ta-C:Al:N films with controlled thicknesses of ~118 nm were coated on AISI 4140 steel using FCVA deposition. The corrosion resistance and adhesion performance were studied. Doping reduced the density of the ta-C films, as indicated by the XRR results. This decreased density corresponded to an increase in the I_D/I_G ratio and L_a (Raman spectroscopy results), as well as a decrease in the relative sp^3 fraction (XPS results). The corrosion performance of the DLC film-coated steels was superior to that of the bare AISI 4140 steel, as indicated by the increase in E_{corr}, E_{pit}, and R_p and the decrease in i_{corr} and CR. The ta-C:Al:N film exhibited the highest corrosion resistance, followed by the ta-C:Al film. The ta-C:Al:N and ta-C:Al films exhibited high R_p (4237.02 and 3890.89 Ω cm^2), high P_i (79.22 and 77.77%), and low P (3.49×10^{-5} and 2.09×10^{-4}) owing to the synergy between the Al oxides and sp^3 C–N bonds. However, the adhesion performances of the films (indicated by the CPRs) decreased in the following order: ta-C:Al:N > ta-C:N > ta-C:Al > ta-C. The doped DLC films exhibited better adhesion performance than the ta-C film because of their increased sp^3-hybridized C–N bond fraction or the formation of Al_2O_3. The ta-C:Al:N film exhibited outstanding corrosion resistance and high adhesion strength, along with the enormous potential for application as a corrosion-and wear-resistant material.

Declaration of competing interest

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

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มหาวิทยาลัยเทคโนโลยีสุรนารี

BIOGRAPHY

Acting Sub. Lt. Praphaphon Silawong was born on October 20, 1983, in Bangkok, Thailand. She obtained a Bachelor's Degree in Metallurgical Engineering from the Institute of Engineering at Suranaree University of Technology (SUT). Upon graduating, she commenced her employment with Thai Parkerizing Co., Ltd. from 2006 to 2008. She subsequently pursued her studies at the Institute of Engineering, Suranaree University of Technology, earning her Master's Degree in Metallurgical Engineering from 2008 to 2011. While pursuing her Master's degree, she was honored with two accolades: the Outstanding Research Award in the Fundamentals of Mining and Materials Engineering at the 8th Annual Engineering Conference (PEC 8), and the Outstanding Thai Parkerizing Research Award 2010 at the Student Level at the 4th Thailand Metallurgical Conference (TMET4). Upon obtaining her Master's degree, she rejoined the company. Thai Parkerizing Co., Ltd. was affiliated with the Thai Technical Centre division for over five years, after which she resumed her pursuit of a Ph.D. She obtained the One Research One Grant (OROG No. 8/2559) from Suranaree University of Technology and an external grant from Rajamangala University of Technology Isan, Khon Kaen Campus for her Ph.D. studies. Furthermore, she held the position of research assistant at BL3.2Ub: PEEM at the Synchrotron Light Research Institute (SLRI) during her academic pursuits, where she acquired and honed her expertise in vacuum systems, FCVA systems, and synchrotron analytical procedures. She persisted in her investigation of the incorporation of Al–N atoms into DLC frameworks and has authored publications in Surface and Coatings Technology and Ceramics International, both indexed in the ISI Web of Science database.

She obtained her Ph.D. in 2022. She possesses expertise in the creation of two-pulse FCVA systems and in the deposition and characterization of carbon-based materials, including amorphous DLC films. Her current study is the application of DLC films as protective coatings for thermal stability and corrosion resistance. She possesses a profound interest in the examination and synthesis of the characteristics of gas-doped and metal- doped DLC films.